

Optoelectronic properties of hexagonal boron nitride

Guillaume Cassabois

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Submitted on 17 Sep 2019

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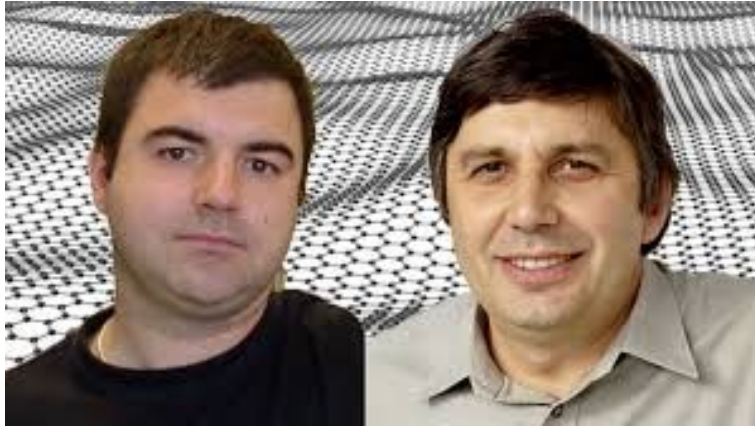
Optoelectronic properties of hexagonal boron nitride

G. Cassabois

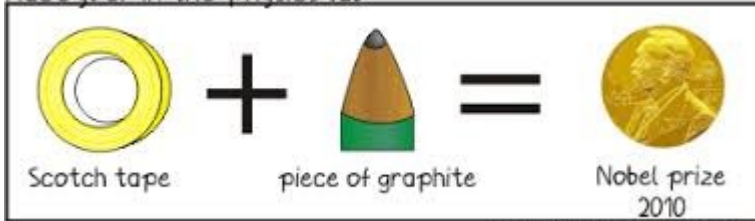
*Laboratoire Charles Coulomb
CNRS / Université de Montpellier
Montpellier, France*



Beyond graphene



MacGyver in the physics lab



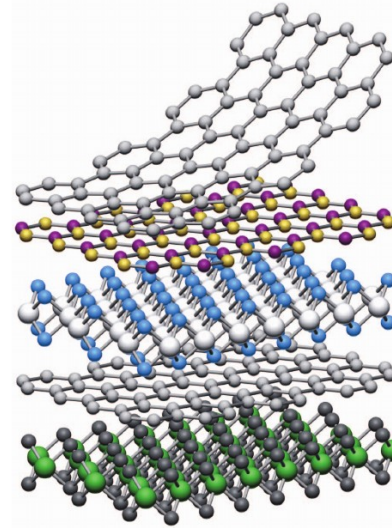
Scotch tape

piece of graphite

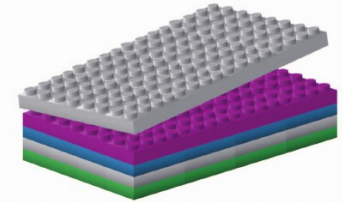
Nobel prize
2010

www.strippedsience.com

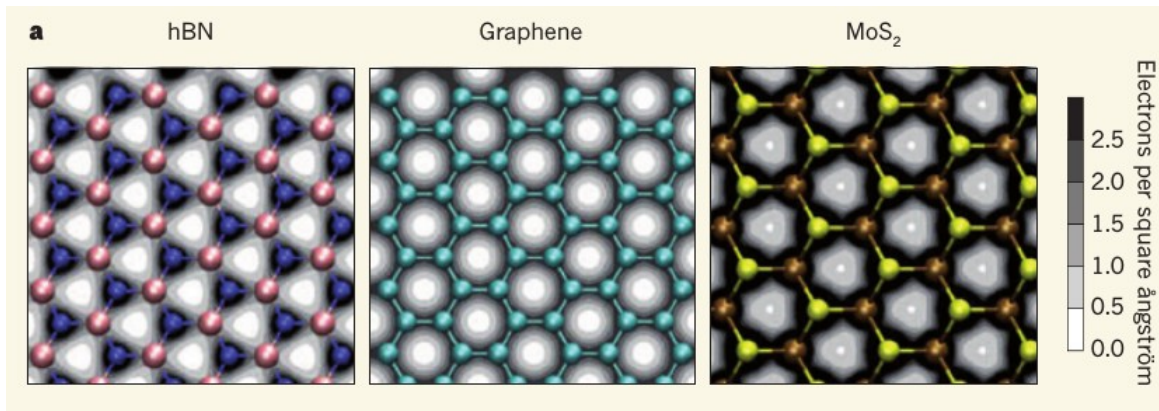
Van der Waals heterostructures



	Graphene	
	hBN	
	MoS ₂	
	WSe ₂	
	Fluorographene	

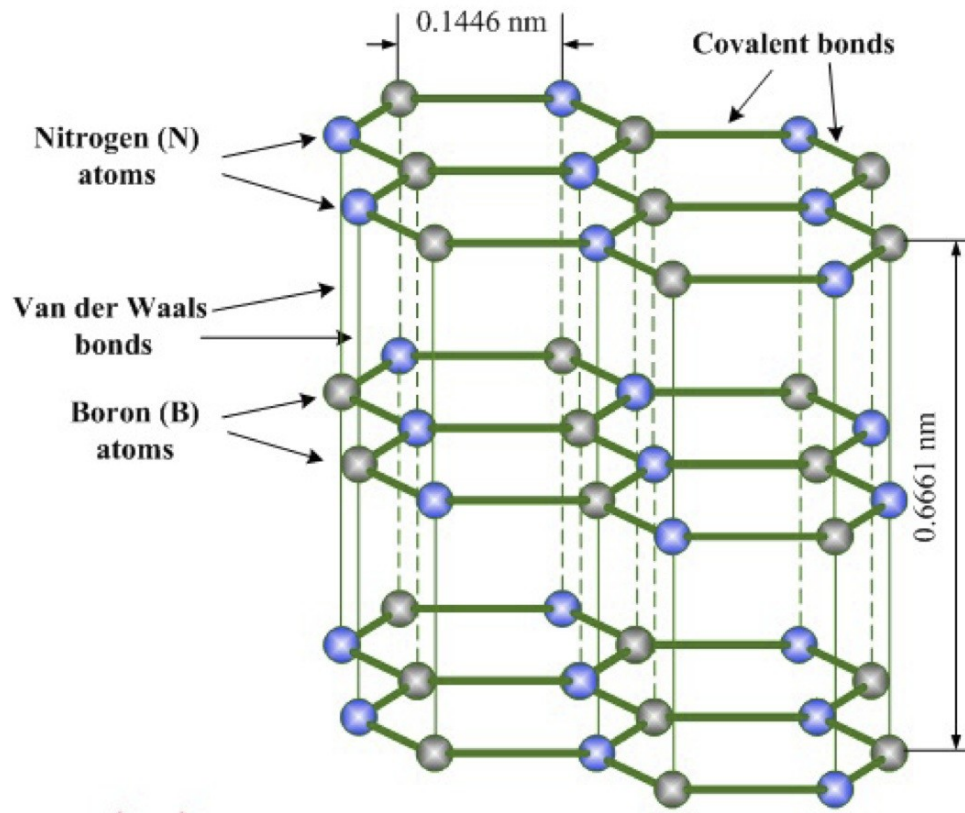


Geim, Nature **499**, 419 (2013)



“White graphite”

Hexagonal boron nitride structure



hBN in the industry

SAINT-GOBAIN



BORON NITRIDE

POWDERS

MACHINABLE CERAMICS

COATINGS

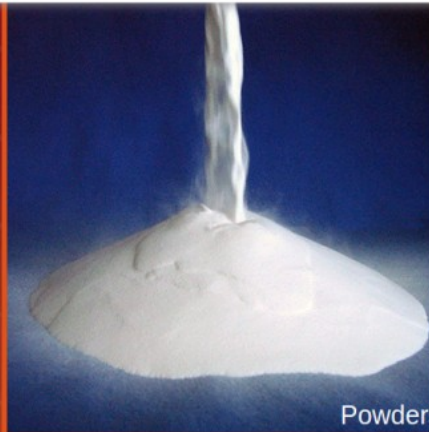
PDS PRODUCTS

MARKETS

RESOURCE CENTER

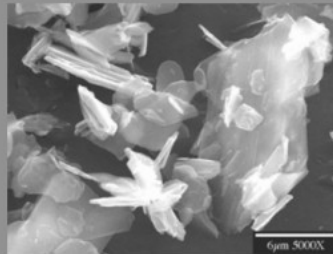
Saint-Gobain Boron Nitride

A global leader in the development and production of Boron Nitride solutions with a focus on technical support and innovation.



Powders

Boron Nitride Products



The ideal material solution.

Saint-Gobain Ceramic Materials Boron Nitride products is a renowned leader in producing a full spectrum of Boron Nitride material solutions for a variety of industries, including [aerospace](#), [automotive](#), [ceramic manufacturing](#), [electronics](#), [semiconductors](#), [metal working](#) and [cosmetics](#).

Boron Nitride products are manufactured as [powders](#), [solid finished components and blanks](#), [aqueous coatings](#), as well as [solid source dopants](#). Custom end use products are a specialty of ours, including custom solid shapes, powder formulations and others. We can work with you from initial development to final implementation of your application, and at any step in between.

hBN in the industry

SAINT-GOBAIN



BORON NITRIDE

POWDERS

MACHINABLE CERAMICS

COATINGS

PDS PRODUCTS

MARKETS

RESOURCE CENTER

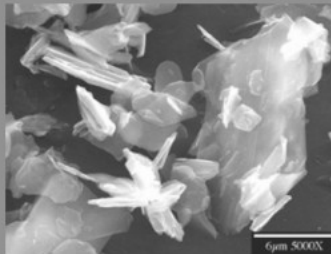
Saint-Gobain Boron Nitride

A global leader in the development and production of Boron Nitride solutions with a focus on technical support and innovation.



Machinable Ceramics

Boron Nitride Products



The ideal material solution.

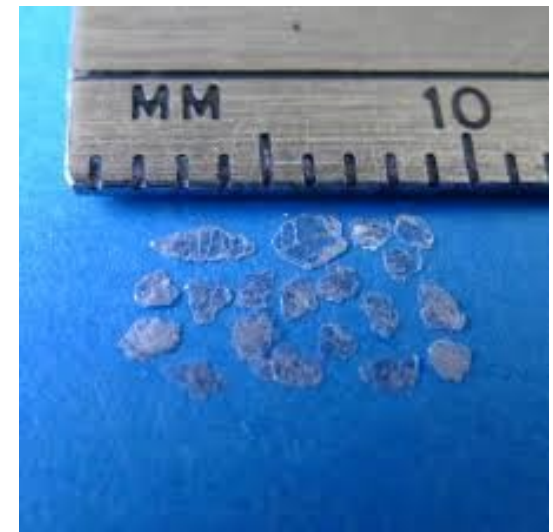
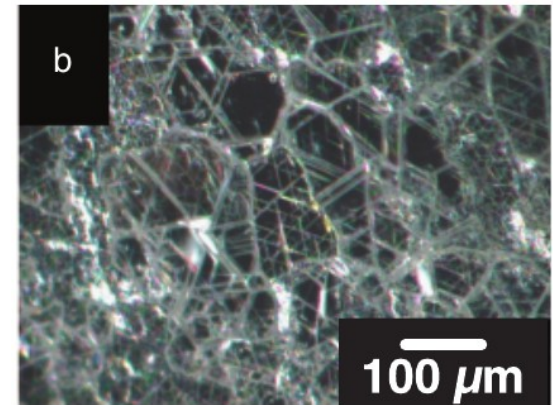
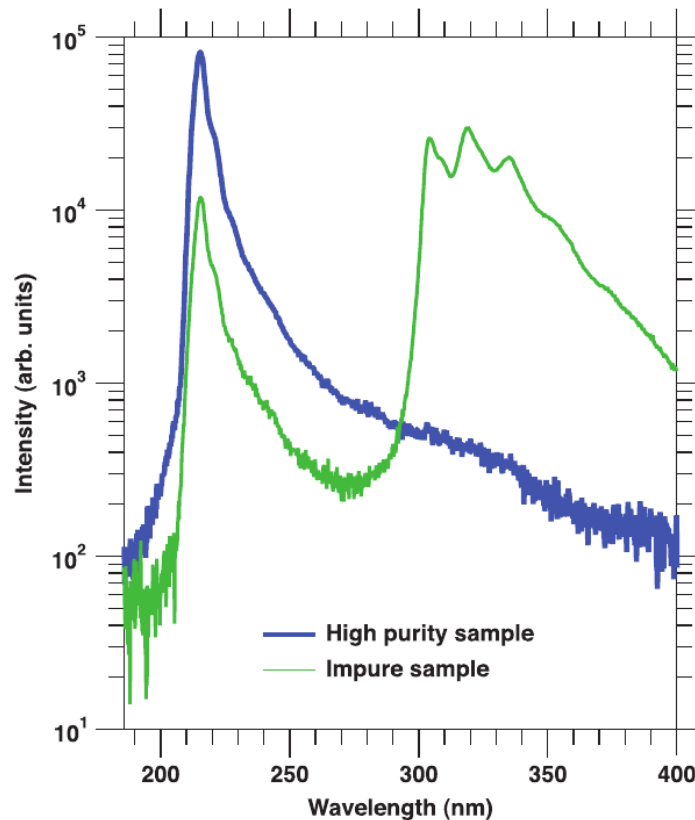
Saint-Gobain Ceramic Materials Boron Nitride products is a renowned leader in producing a full spectrum of Boron Nitride material solutions for a variety of industries, including [aerospace](#), [automotive](#), [ceramic manufacturing](#), [electronics](#), [semiconductors](#), [metal working](#) and [cosmetics](#).

Boron Nitride products are manufactured as [powders](#), [solid finished components and blanks](#), [aqueous coatings](#), as well as [solid source dopants](#). Custom end use products are a specialty of ours, including custom solid shapes, powder formulations and others. We can work with you from initial development to final implementation of your application, and at any step in between.



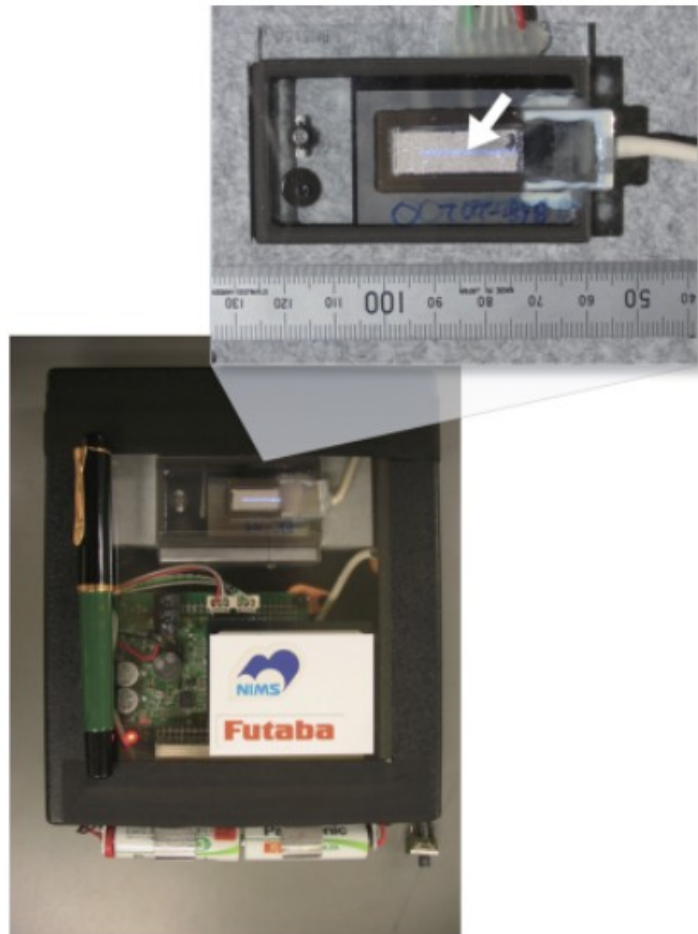
From the industry ... back into the lab !

2004-breakthrough by Watanabe & Taniguchi
(Nat. Mat. 3, 404, 2004)

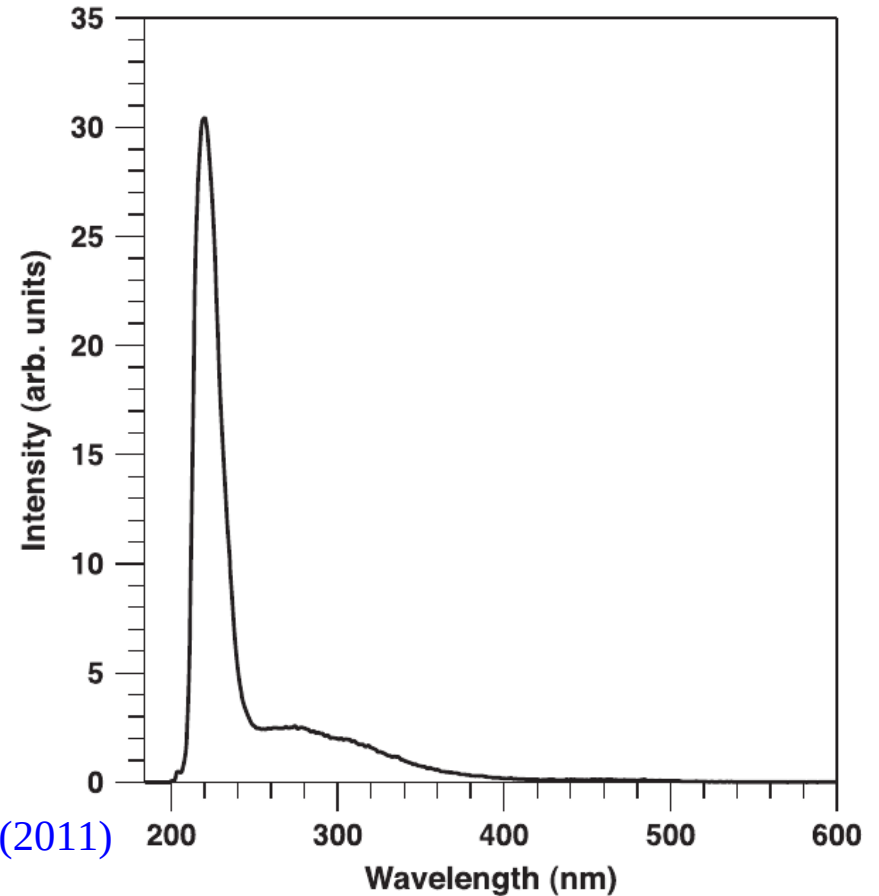


Watanabe, Int. J. Appl. Ceram. Technol. 8, 977 (2011)

hBN for Deep-UV light emission



Field-emitter Deep-UV device

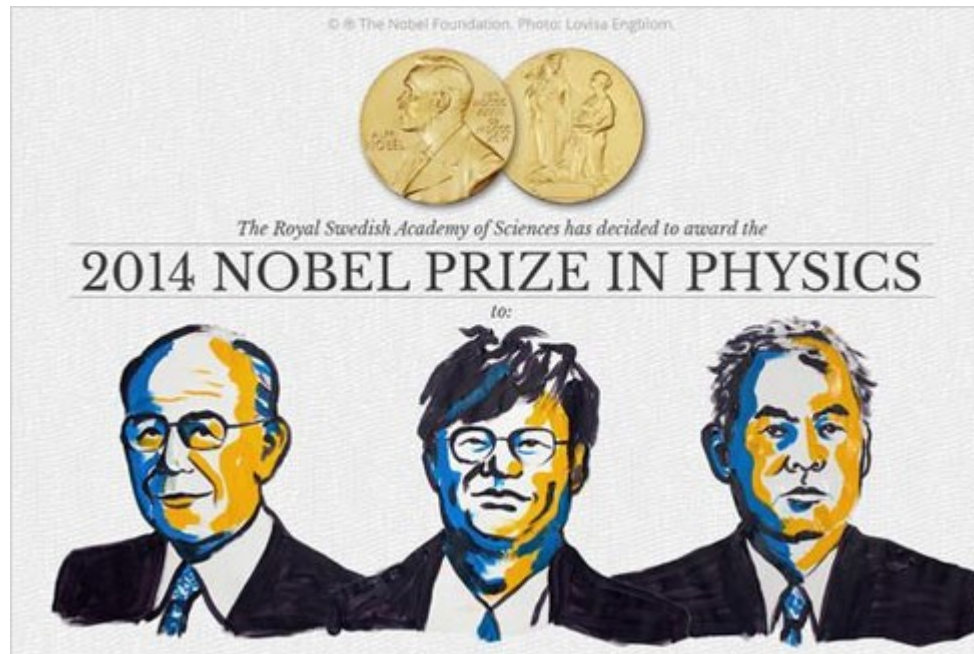


Watanabe, *Int. J. Appl. Ceram. Technol.* **8**, 977 (2011)

Watanabe, *Nat. Phot.* **3**, 591 (2009)

hBN: also a nitride semiconductor !

- Famous members of the family : GaN and AlN



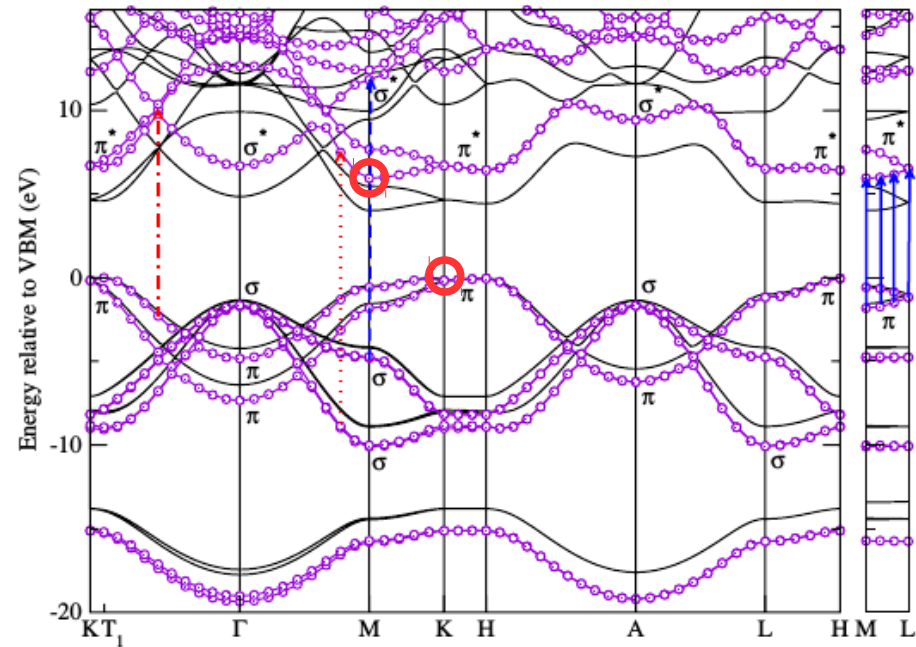
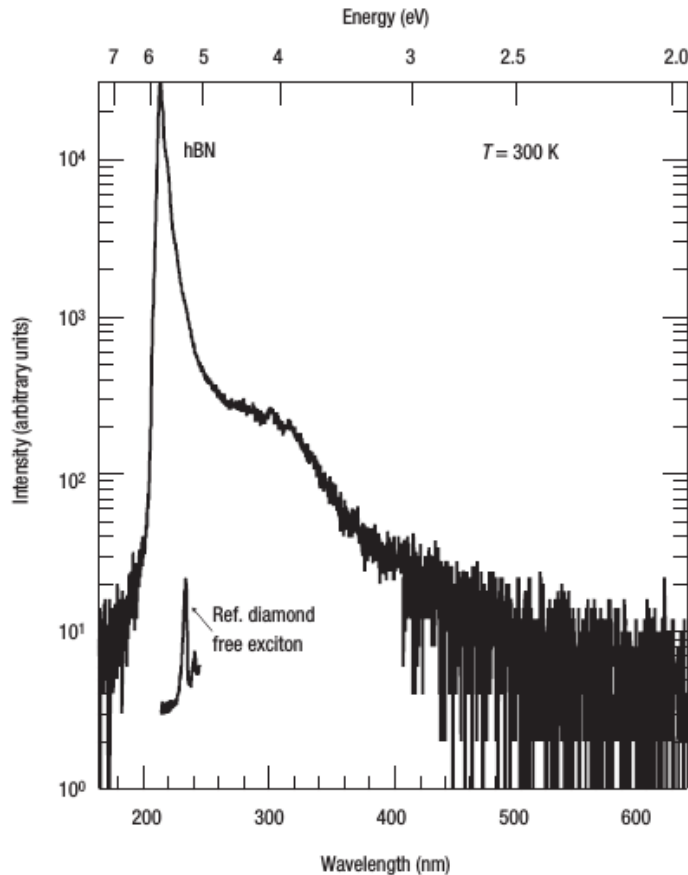
- hBN : a newcomer in the nitride industry for deep UV devices

The (old) controversy of the bandgap nature

Direct
(optical spectroscopy)

OR ?

Indirect
(theoretical calculations)



- ◆ Conduction band min @ M
- ◆ Valence band max @ K

Watanabe, Nat. Mat. **3**, 404 (2004)

Arnaud, PRL **96**, 026402 (2006)

ONLY bulk hBN
TODAY

ONLY bulk hBN TODAY

For monolayer hBN

Sergei NOVIKOV
(We-5i)

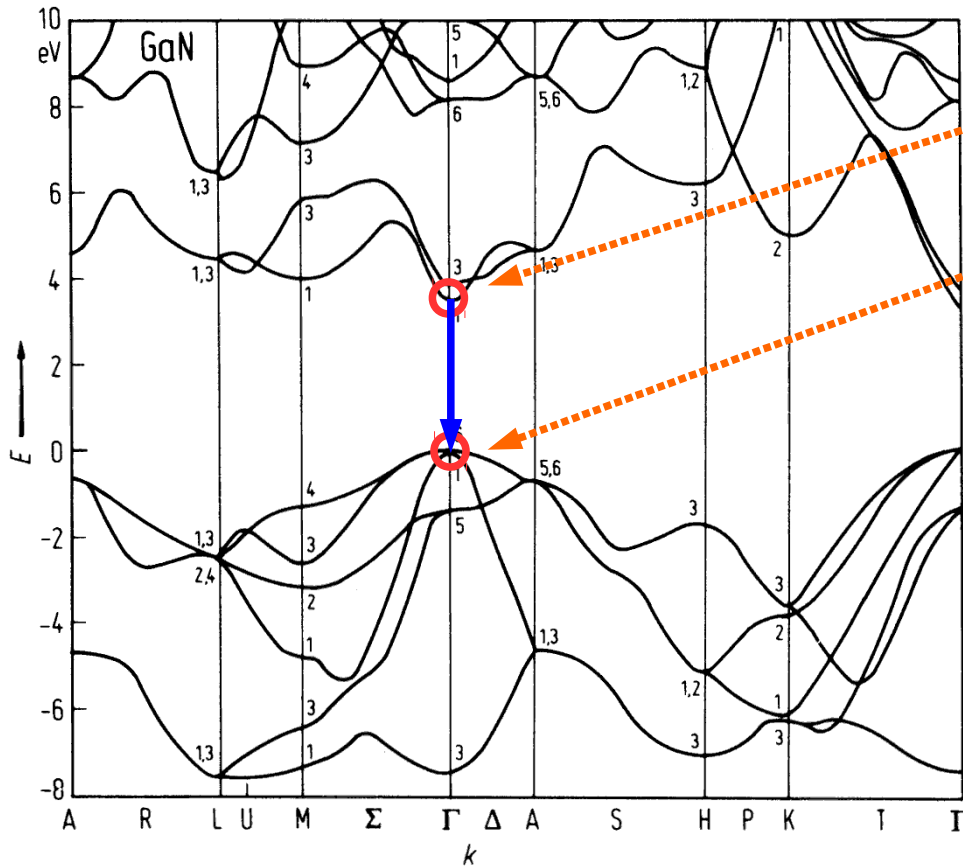
Christine ELIAS
(We-7o)

Outline

- Indirect vs direct bandgap semiconductors
- Two-photon spectroscopy
- Unconventional optical response
- Prospects

Direct bandgap

GaN : electronic bandstructure of wurtzite phase



- ◆ Conduction band min @ Γ
- ◆ Valence band max @ Γ
- ◆ Bandgap ~ 3.5 eV (UV)

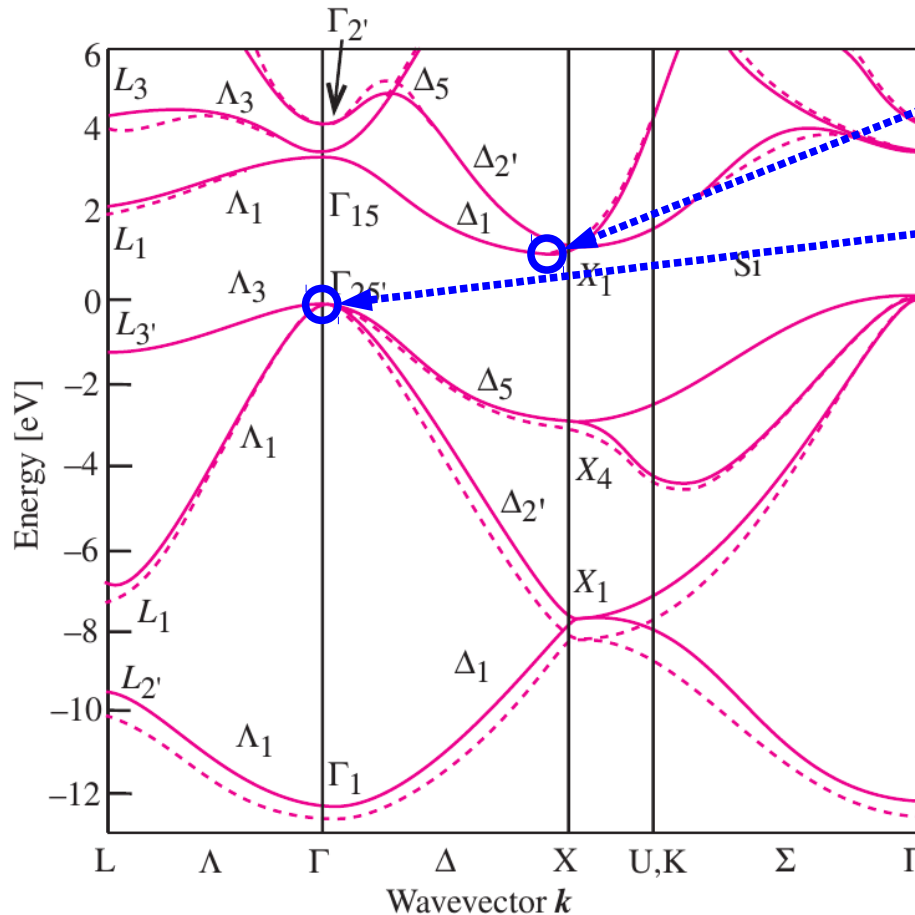
$$\lambda \sim 350\text{nm} \gg a \sim \text{\AA}$$

vertical transition in k-space

Direct recombination

Indirect bandgap : a well-known case

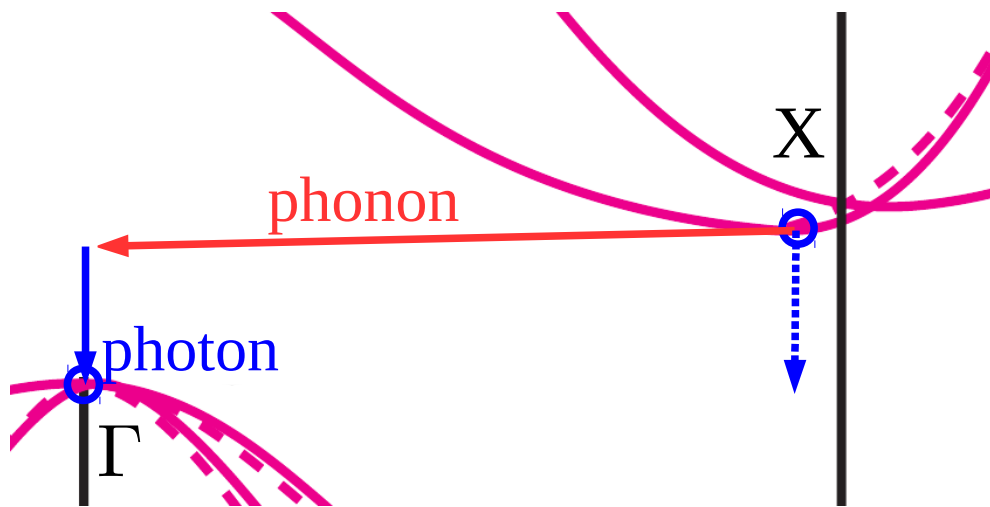
electronic bandstructure of SILICON



- ◆ Conduction band min @ X
- ◆ Valence band max @ Γ
- ◆ Bandgap ~ 1.12 eV (IR)

Momentum conservation
NOT FULFILLED
in direct recombination

Phonon-assisted recombination in silicon



◆ Phonon emission

⇨ momentum conservation

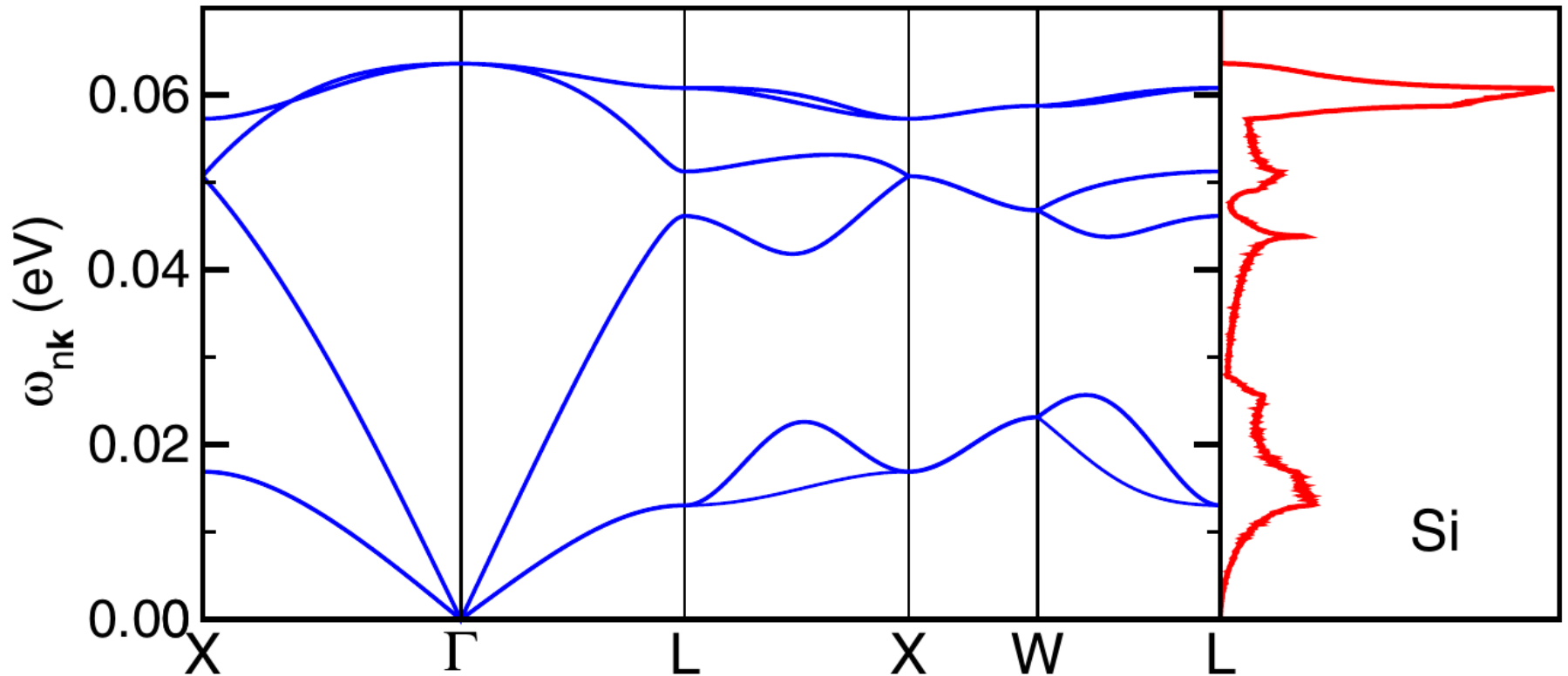
◆ Phonon wavevector

$$q = \Gamma X$$

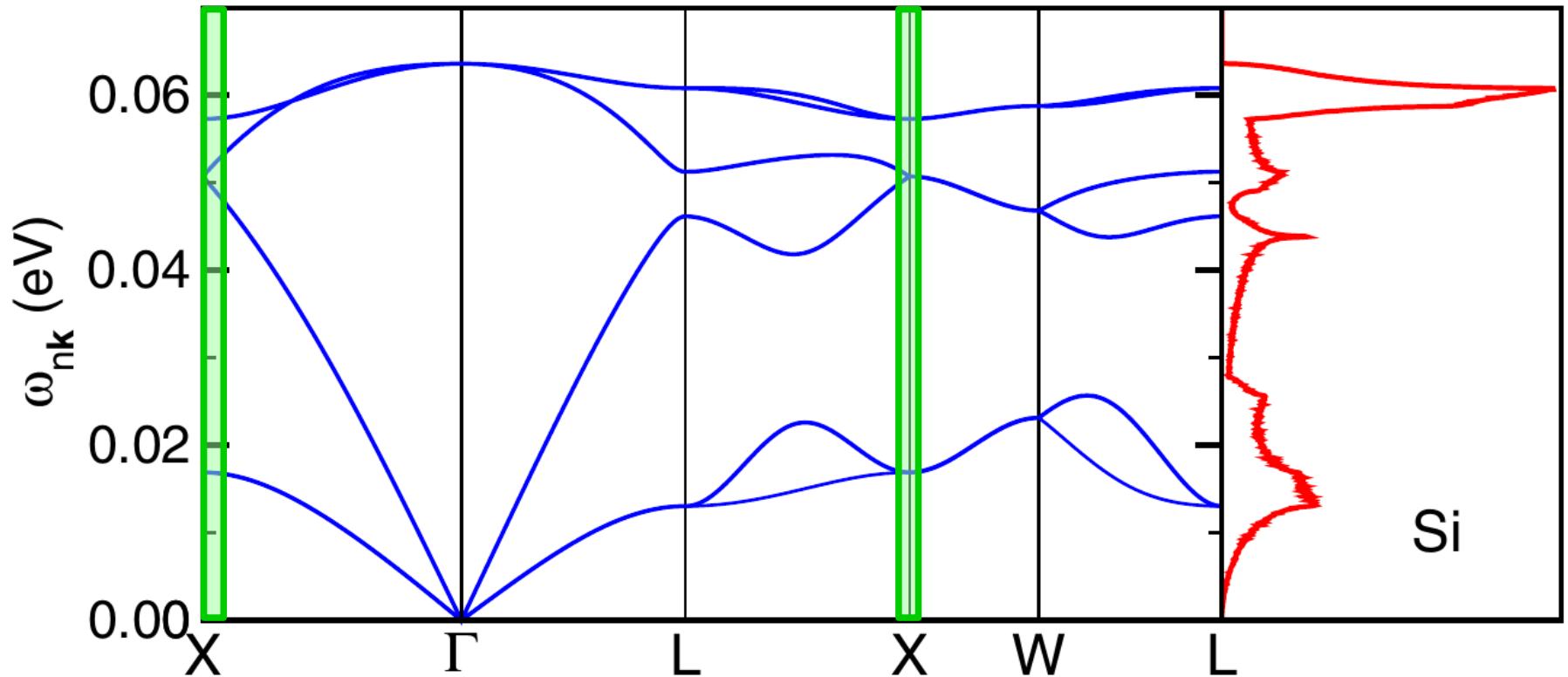
Since $k = 0$ at the zone center Γ ,

phonon-assisted recombination involves phonons from X valley

Phonon bandstructure in silicon



Phonon bandstructure in silicon



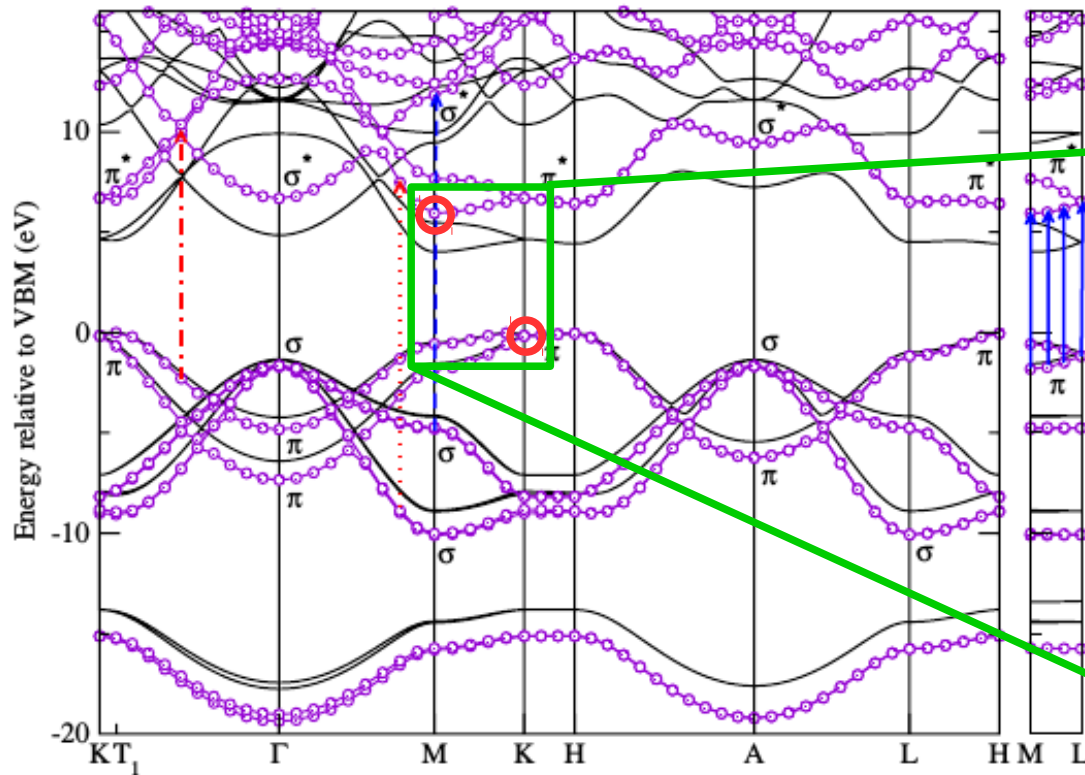
Usual (old) game in indirect bandgap materials :

look for phonons in the same valley as the CB minimum !

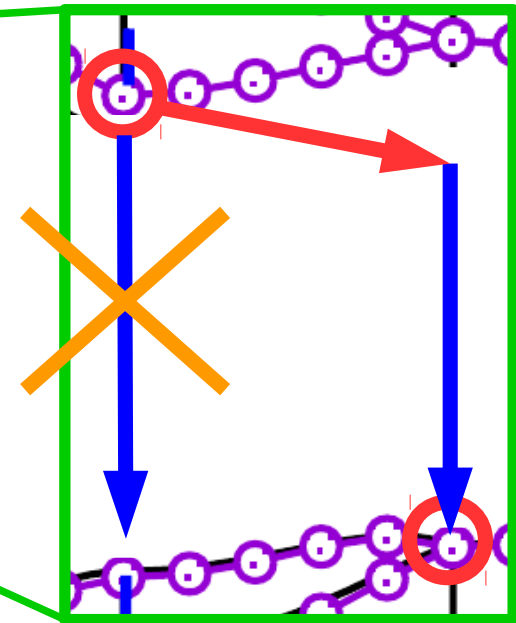
Valence band maximum is not at zone center in hBN

ab initio bandstructure calculations

- Conduction band min @ M
- Valence band max @ K



INDIRECT gap

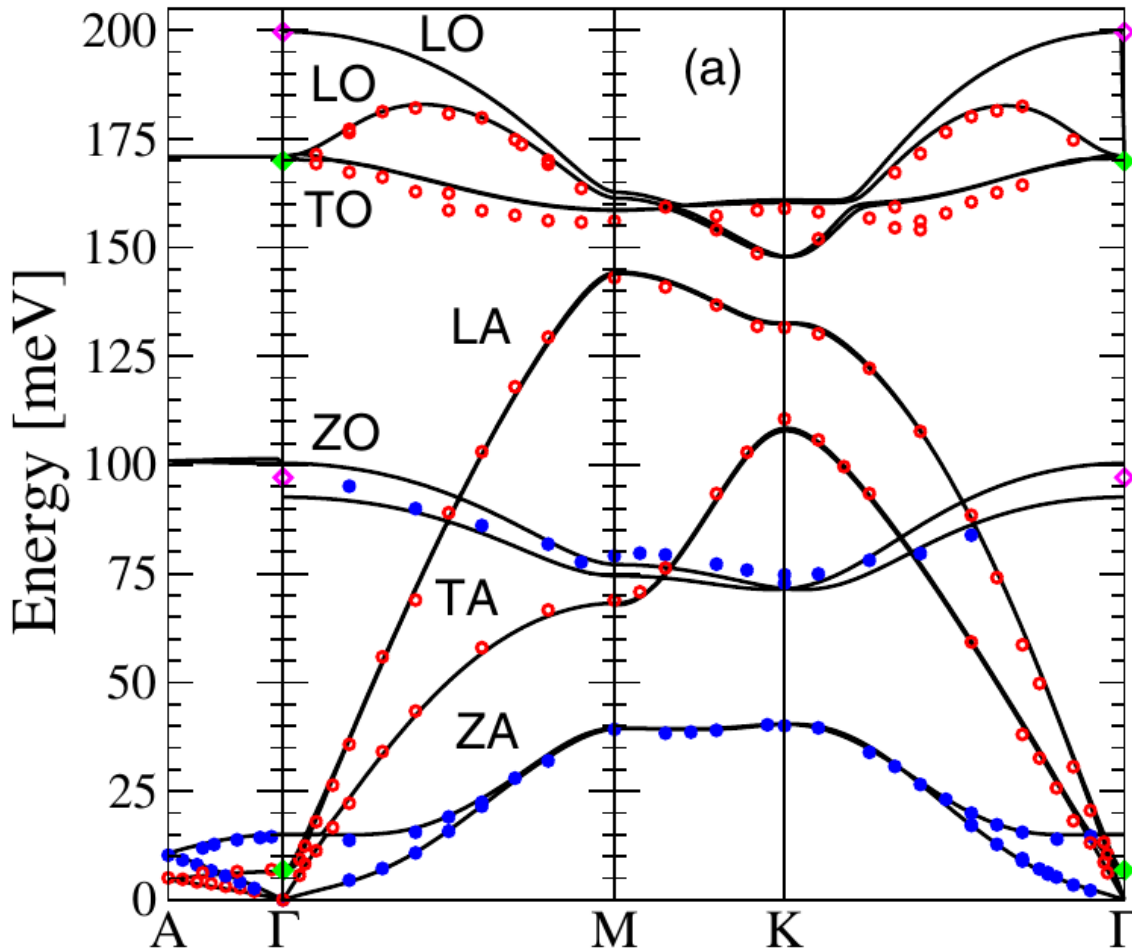


Arnaud, PRL **96**, 026402 (2006)

phonon-assisted recombination

Which phonons for emission in hBN ?

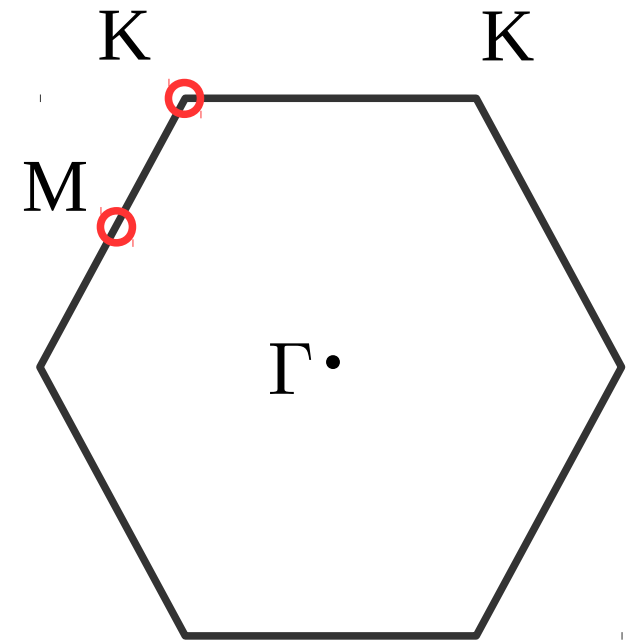
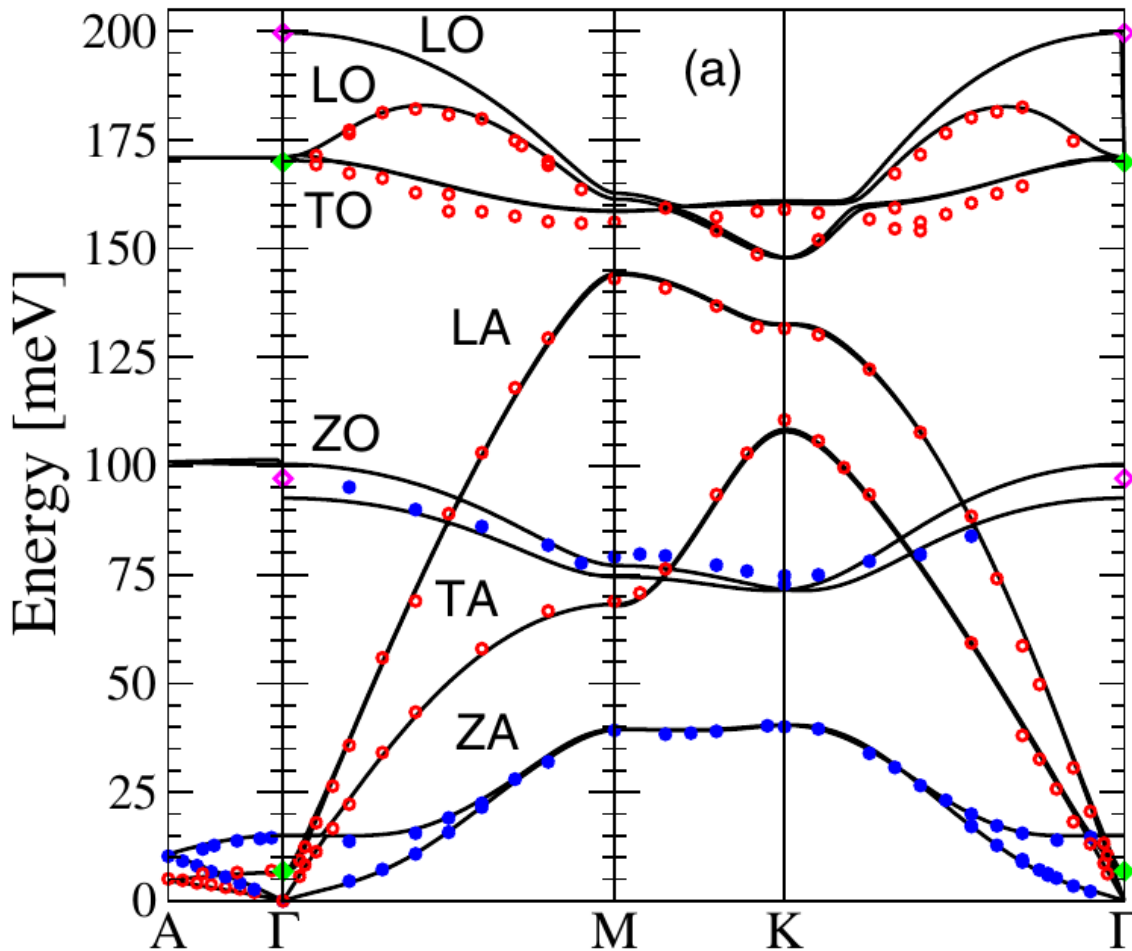
Phonon band-structure



Serrano, PRL **98**, 095503 (2007)

Which phonons for emission in hBN ?

Phonon band-structure

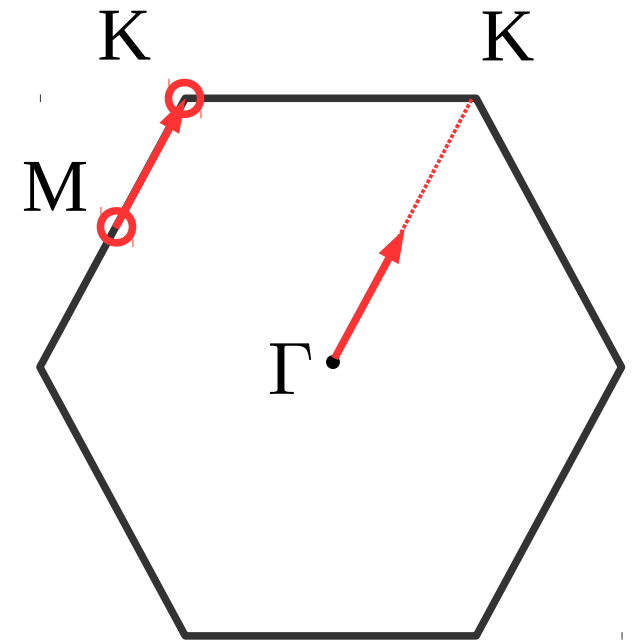
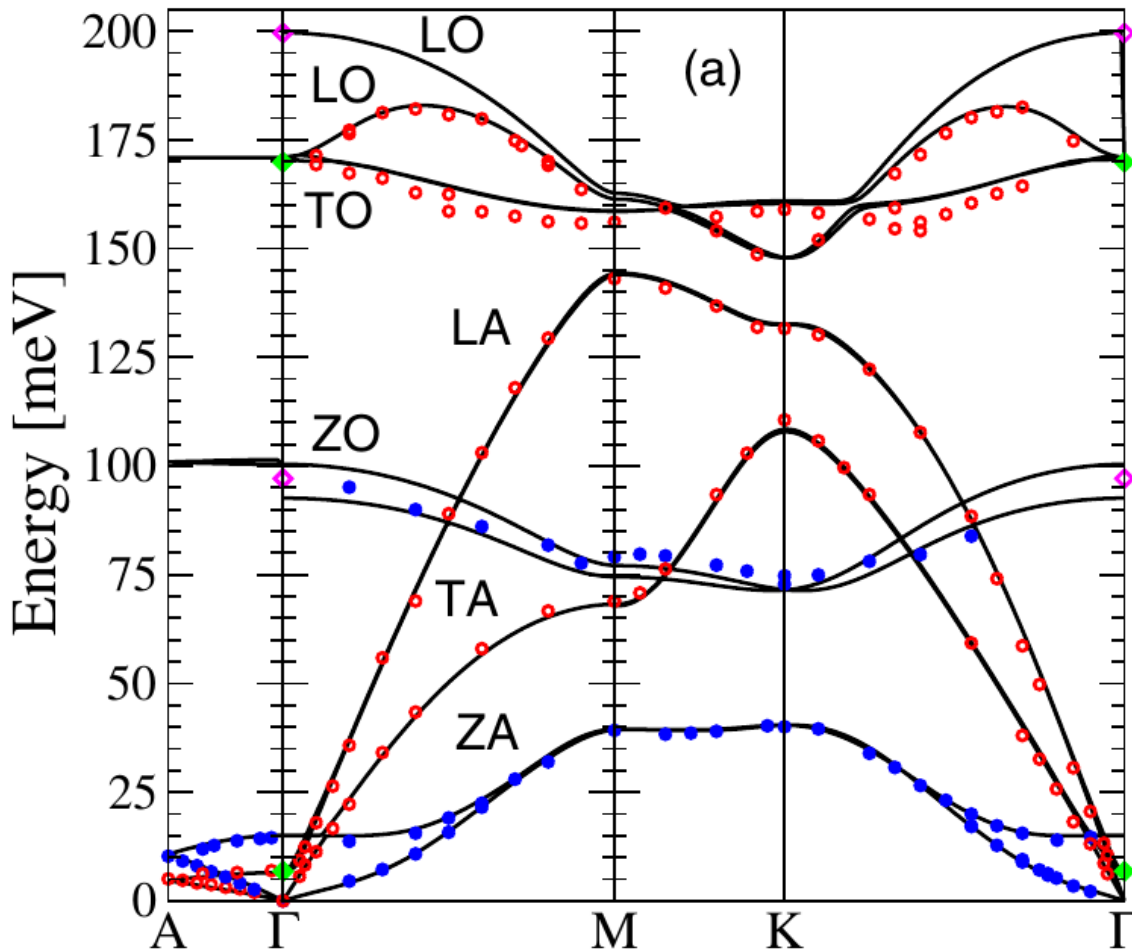


First Brillouin zone
in hBN

Serrano, PRL **98**, 095503 (2007)

Which phonons for emission in hBN ?

Phonon band-structure

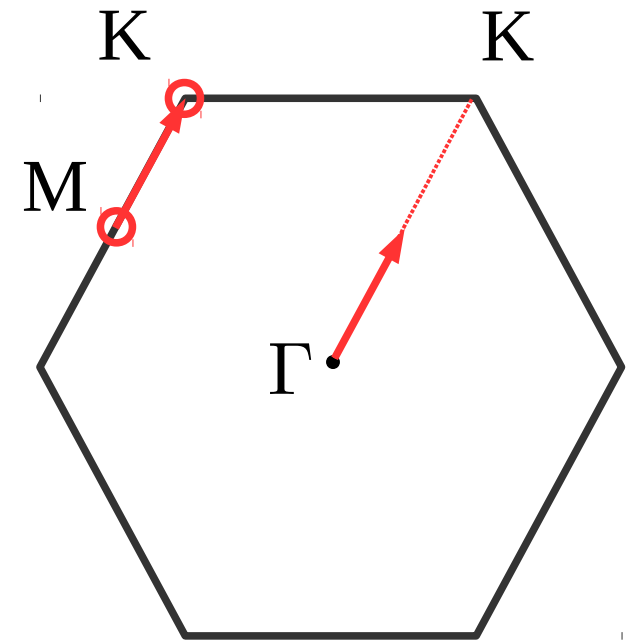
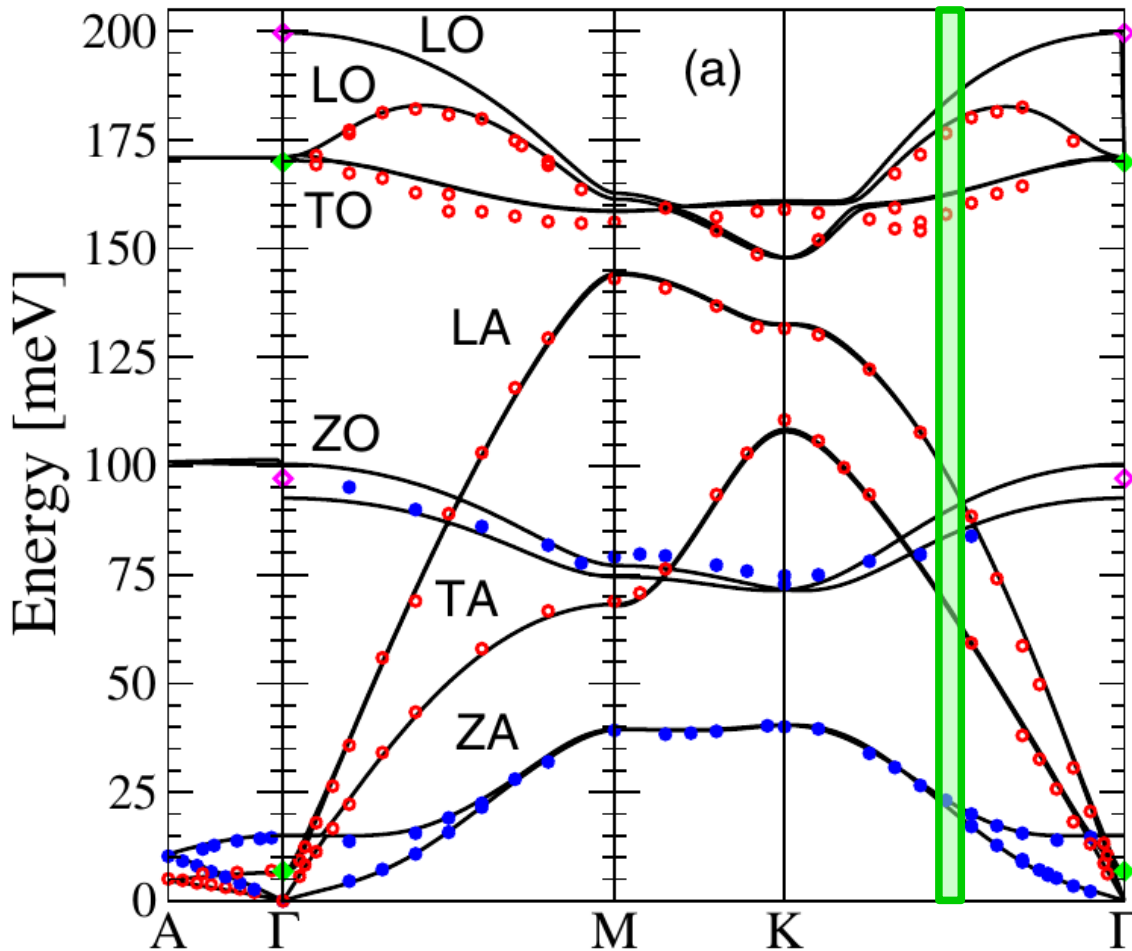


First Brillouin zone
in hBN

Serrano, PRL **98**, 095503 (2007)

Which phonons for emission in hBN ?

Phonon band-structure



First Brillouin zone
in hBN

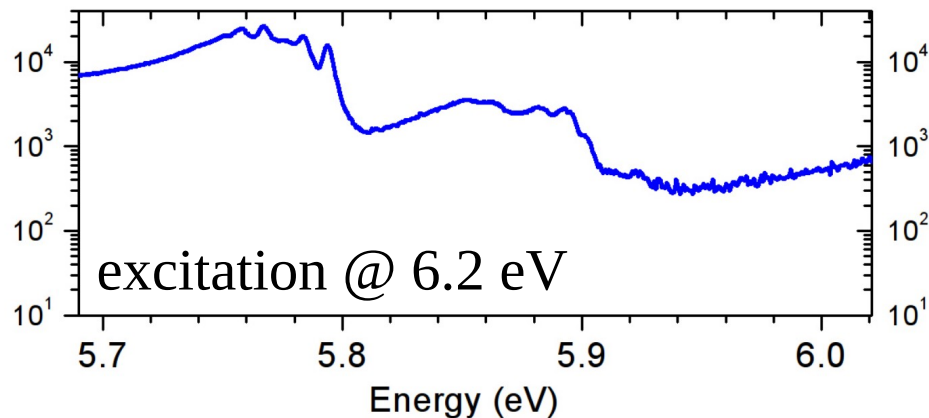
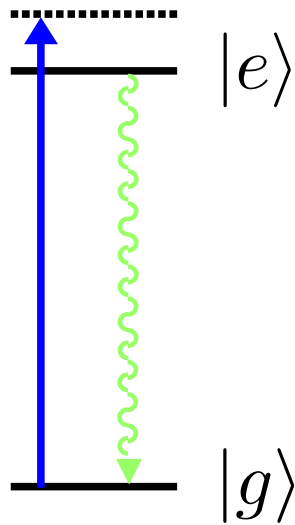
Serrano, PRL **98**, 095503 (2007)

Outline

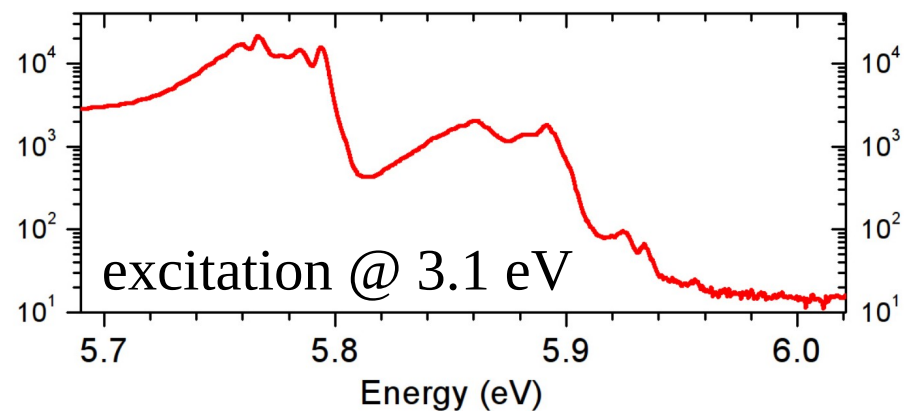
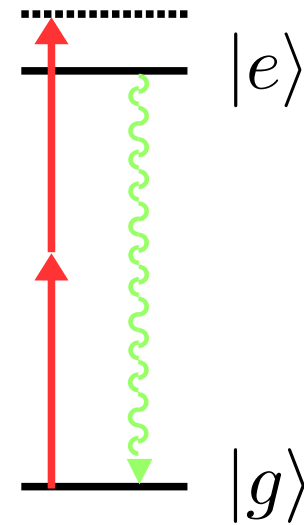
- Indirect vs direct bandgap semiconductors
- Two-photon spectroscopy
- Unconventional optical response
- Prospects

Two-photon spectroscopy

One-photon excitation



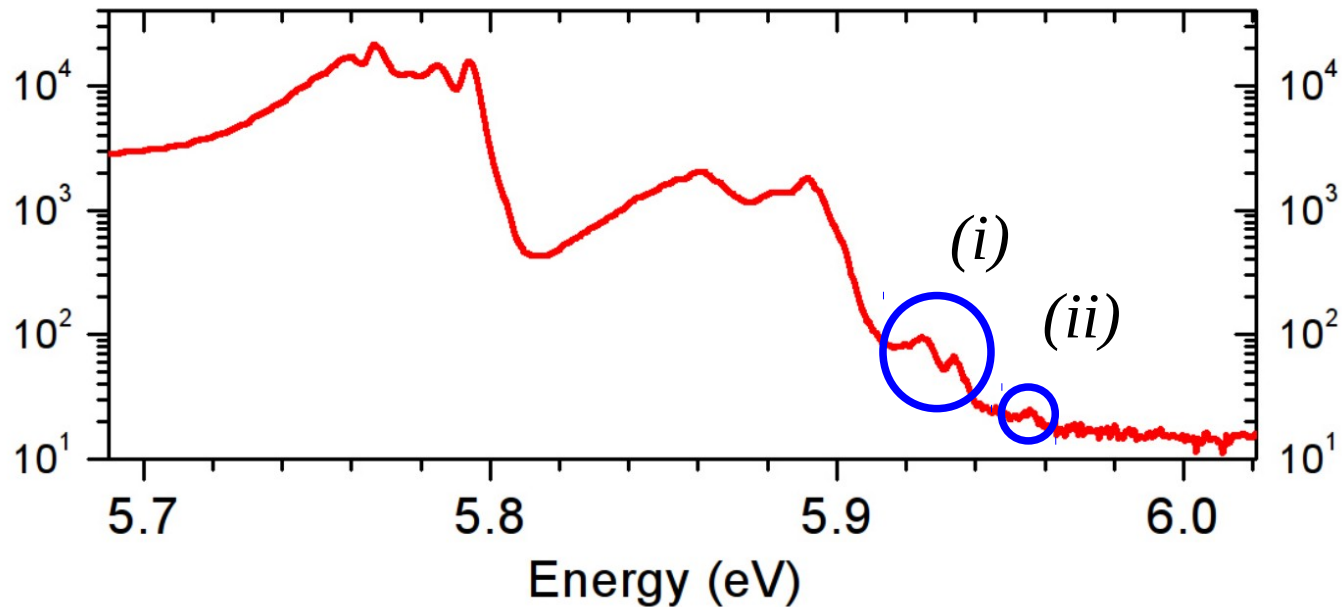
Two-photon excitation



Suppression of laser background

Observation of previously undetected emission lines

Cassabois, Nature Photon. **10**, 262 (2016)

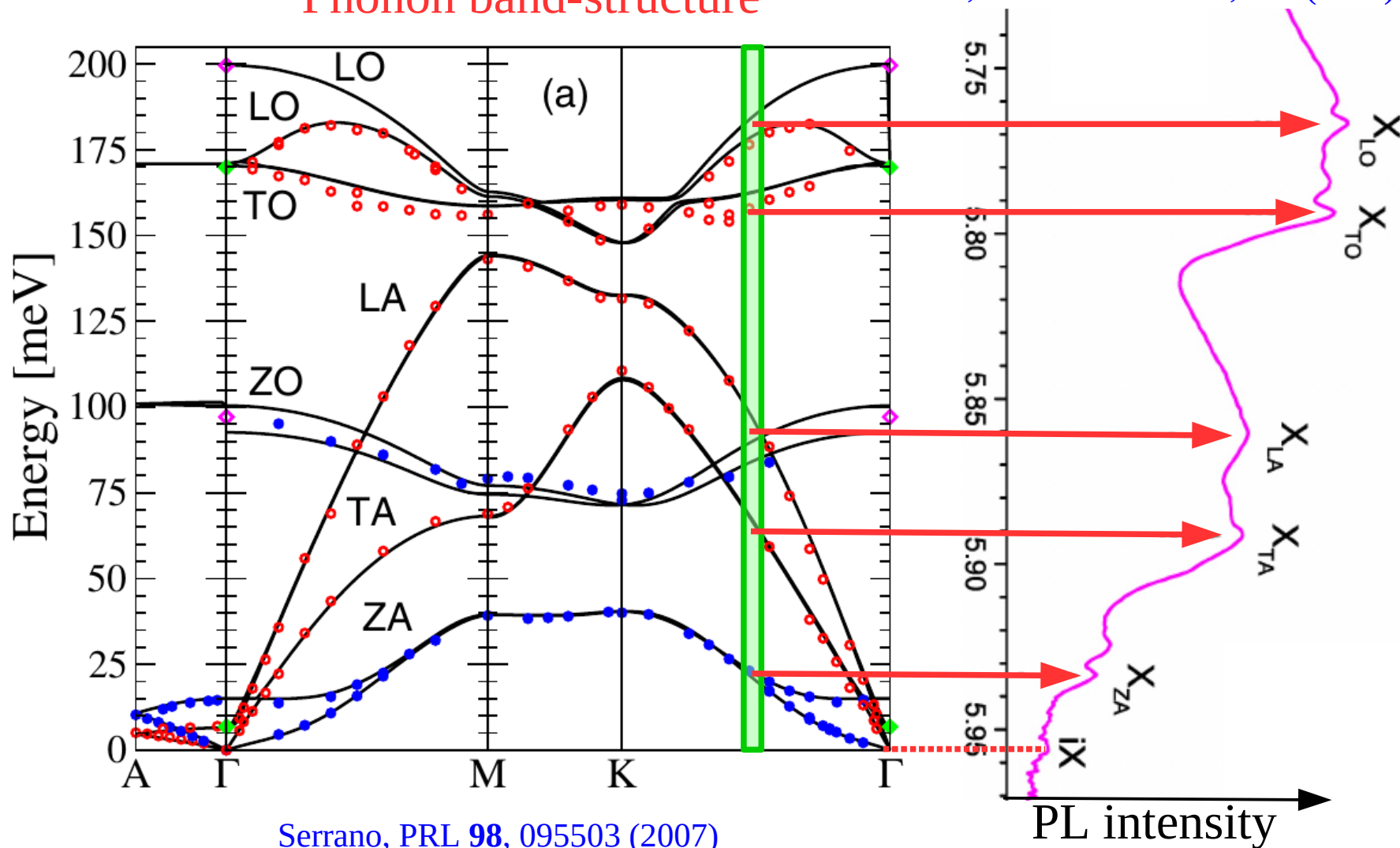


- (i)=doublet line @ 5.93 eV similar to emission lines at lower energy
- (ii)=weaker line @ 5.955 eV
- phonon-assisted recombination ?

Identification of phonon replicas

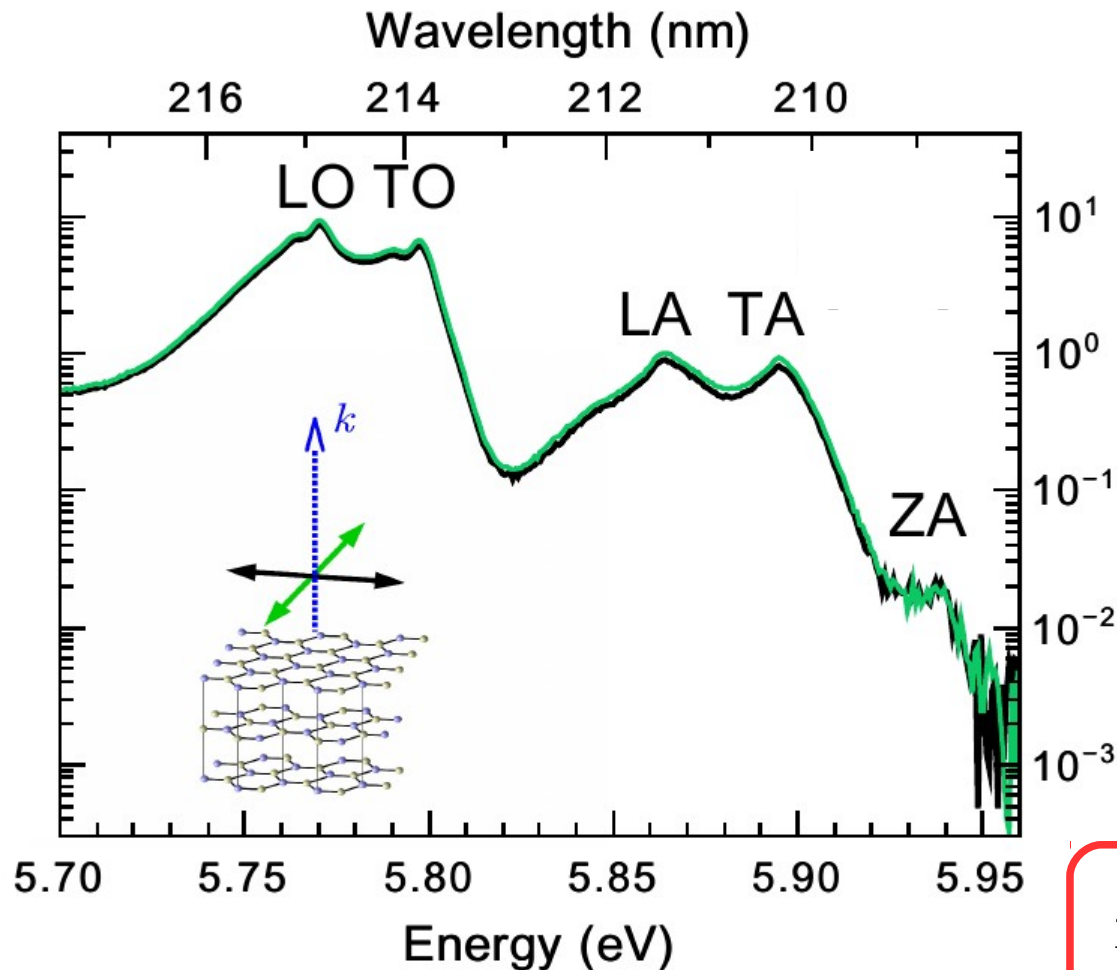
Phonon band-structure

Cassabois, Nature Photon. **10**, 262 (2016)



Serrano, PRL **98**, 095503 (2007)

Polarization-resolved measurements : along c-axis



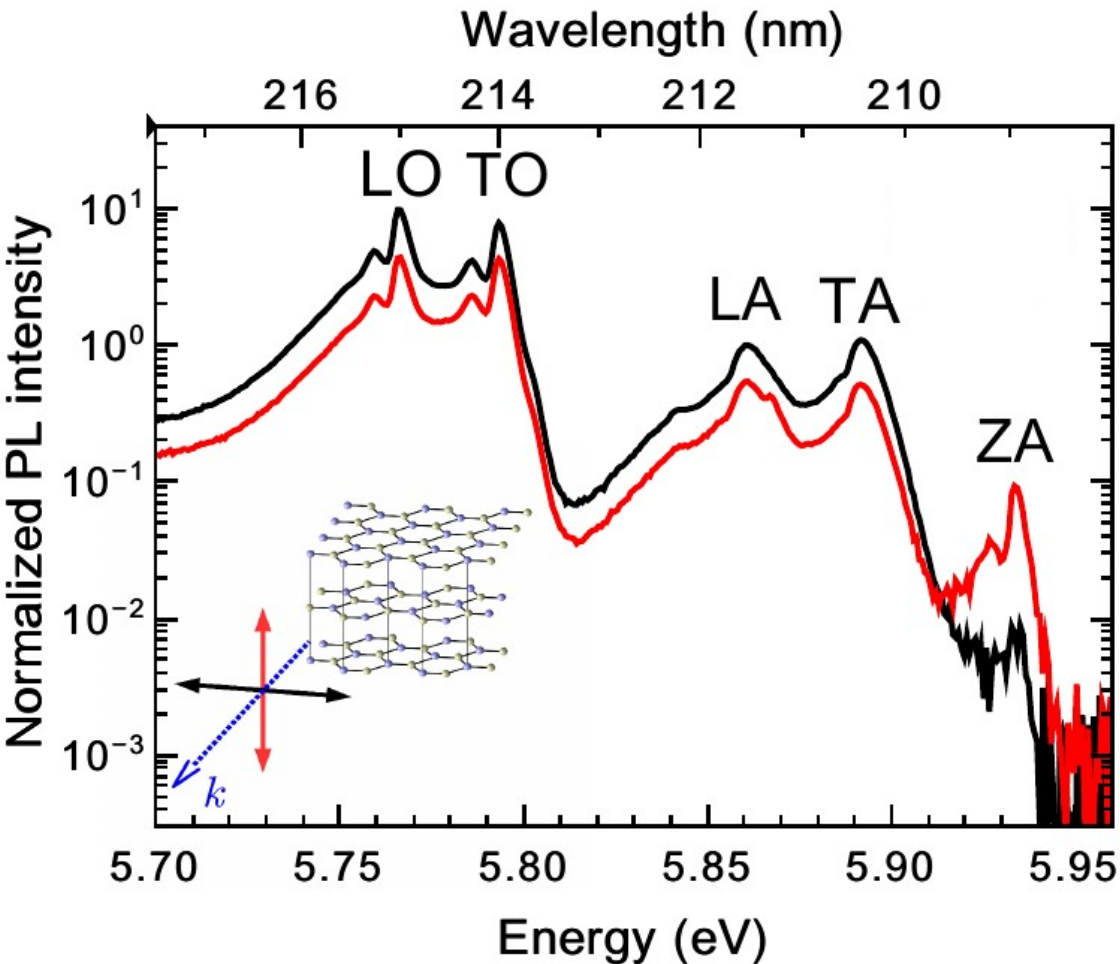
- ♦ Intense optical phonon replicas (LO, TO)
- ♦ Weak acoustic phonon replicas (LA, TA, ZA)
- ♦ Selection rules for phonon-assisted recombination

ZA forbidden for $k \parallel c$

ZA = out-of-plane vibrations
LA, TA = in-plane vibrations

Vuong, 2D Mater. 4, 011004 (2017)

Polarization selection rules : edge detection



- ◆ Detection from sample edge

$$k \perp c$$

- ◆ Strong polarization dependence

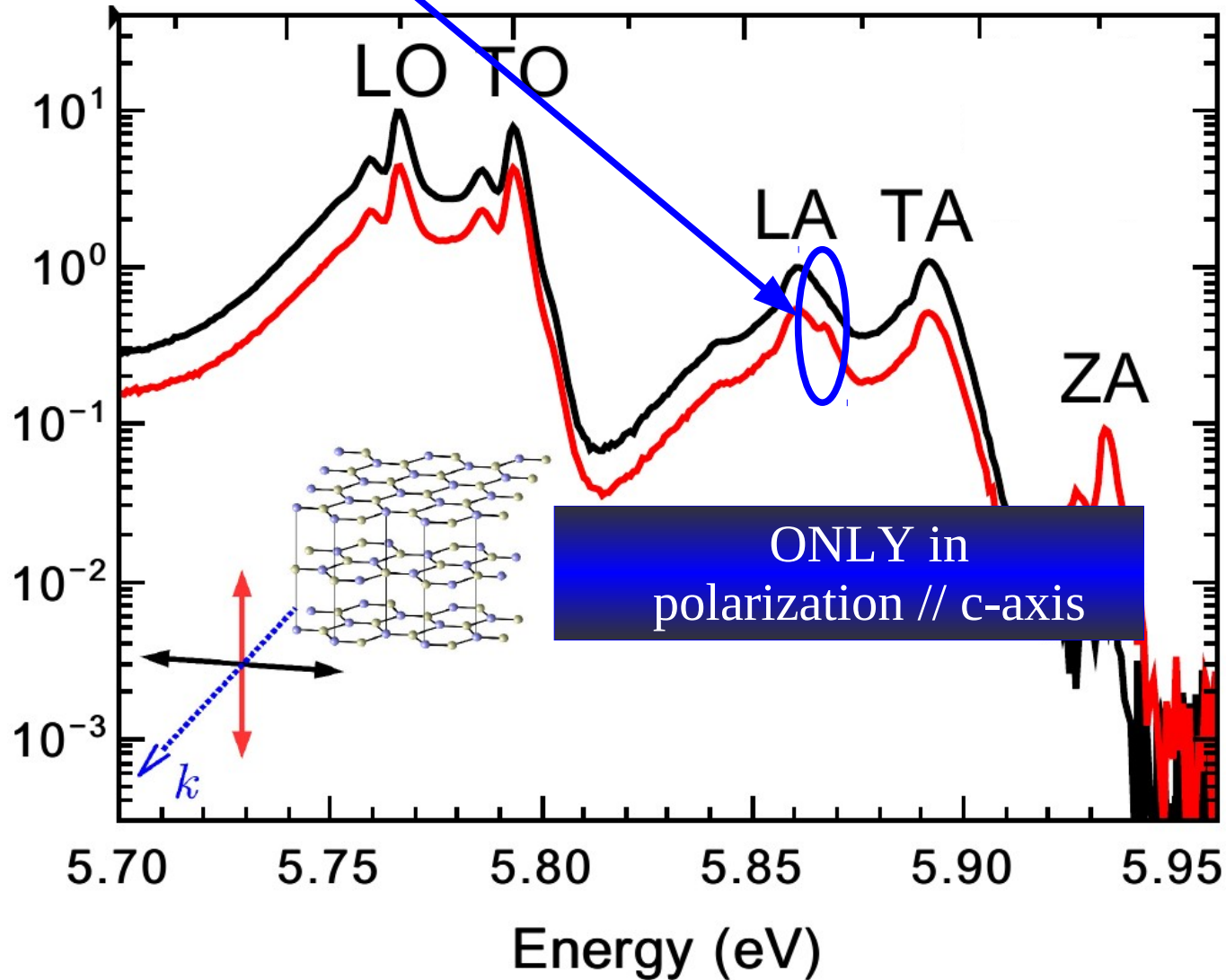
- ◆ Anti-correlation between ZA and (LA, TA, LO, TO)

- ◆ ZA = out-of-plane vibrations

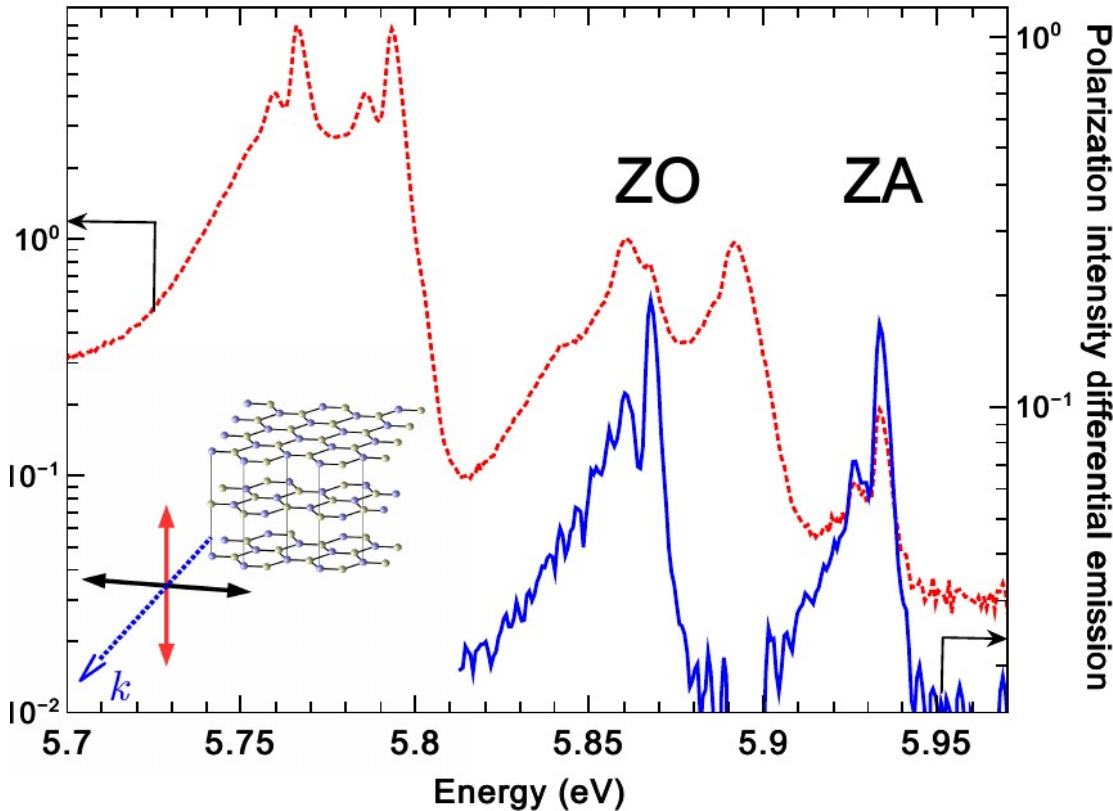
$$\text{allowed for } k \perp c$$

Vuong, 2D Mater. 4, 011004 (2017)

Another previously undetected emission line...

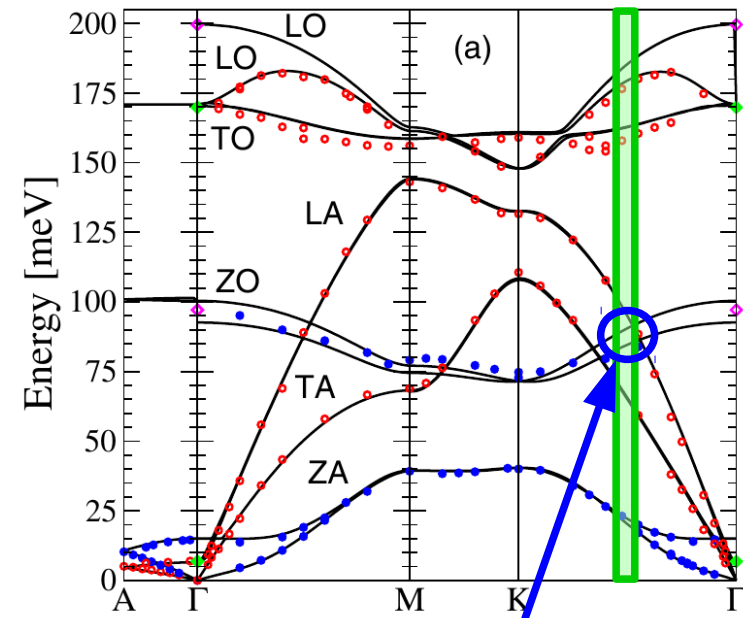


ZO phonon replica

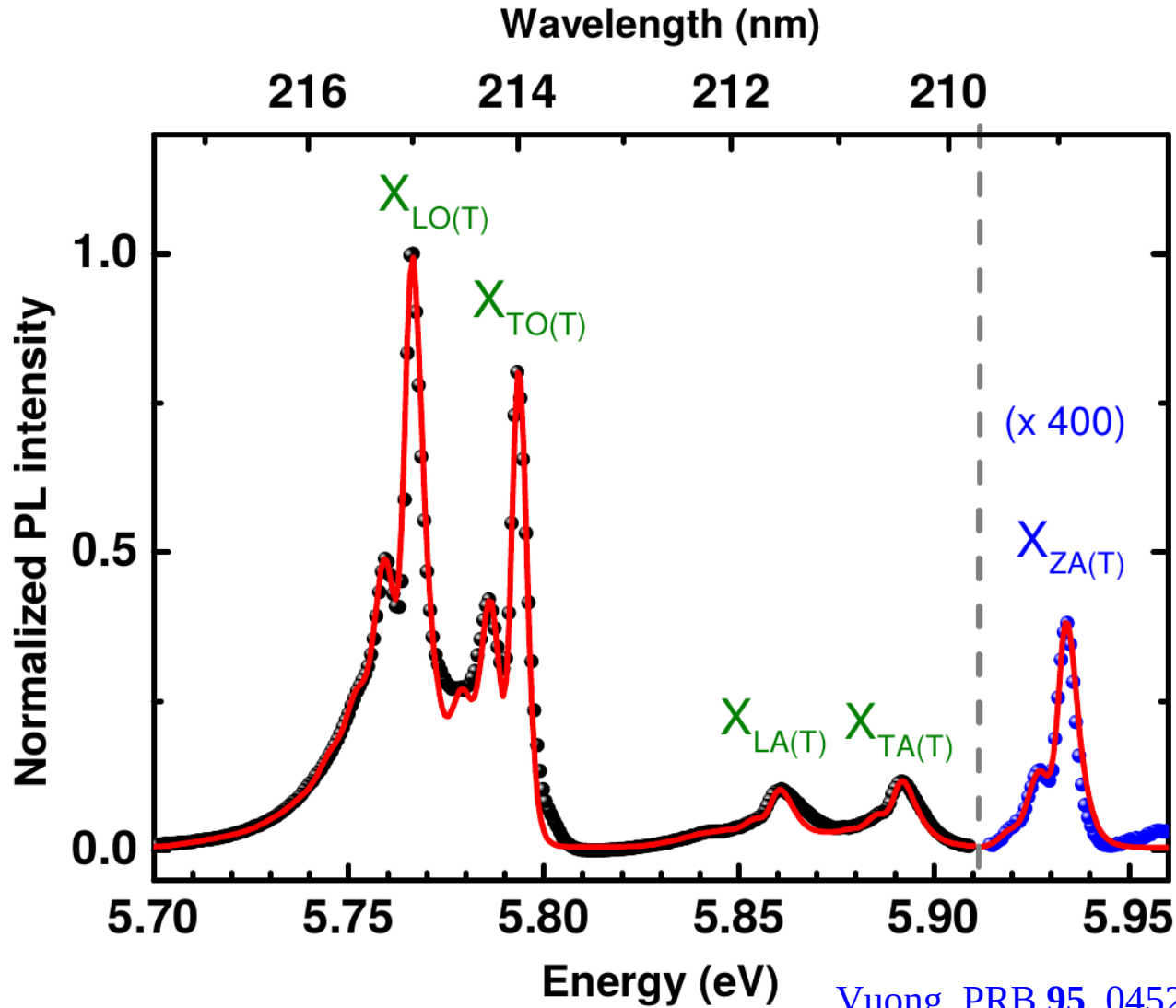


Vuong, 2D Mater. 4, 011004 (2017)

- observation of missing sixth replica
- ZO branch in between LA and TA in middle of Brillouin zone

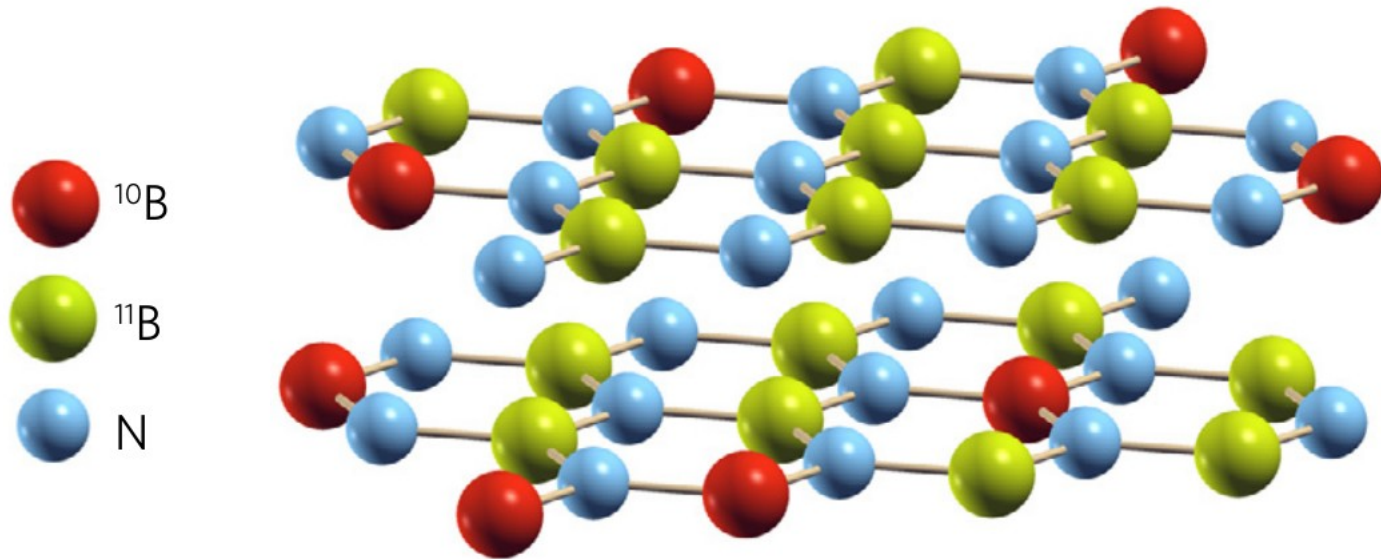


Phonon group velocity



Vuong, PRB 95, 045207 (2017)

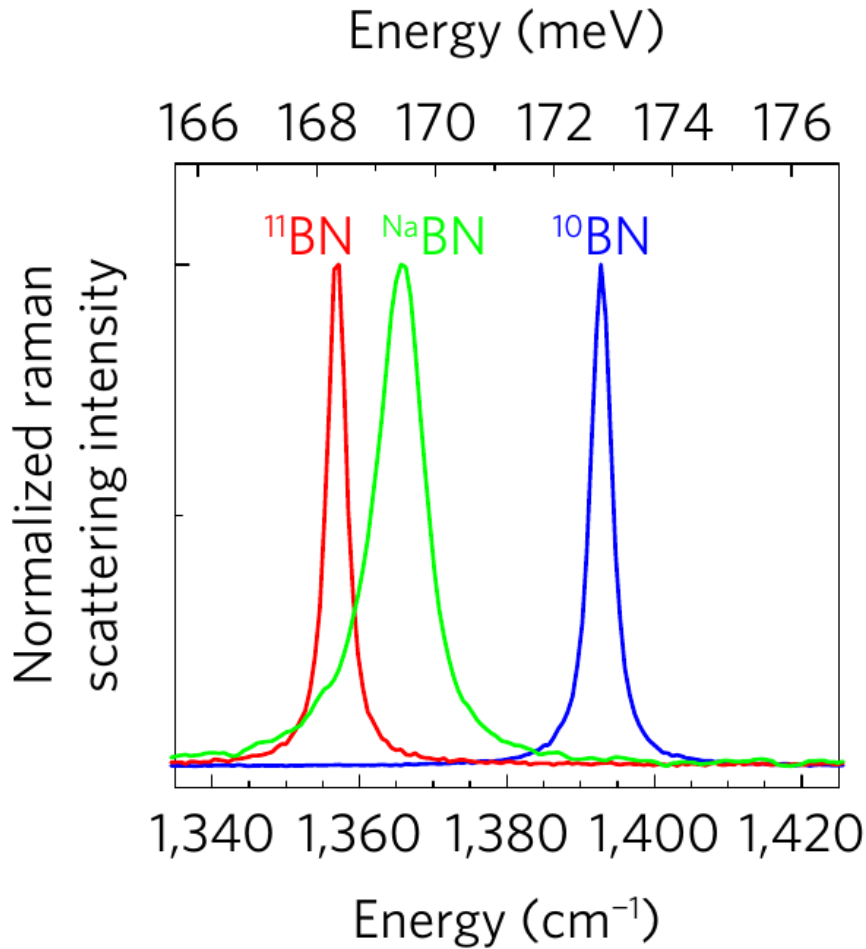
Two boron isotopes : ^{10}B and ^{11}B



- Boron isotopes : 20 at% ^{10}B and 80 at% ^{11}B
- Nitrogen isotopes : 99.6 at% ^{14}N

Vuong, Nature Mat. **17**, 152 (2018)

Raman spectroscopy

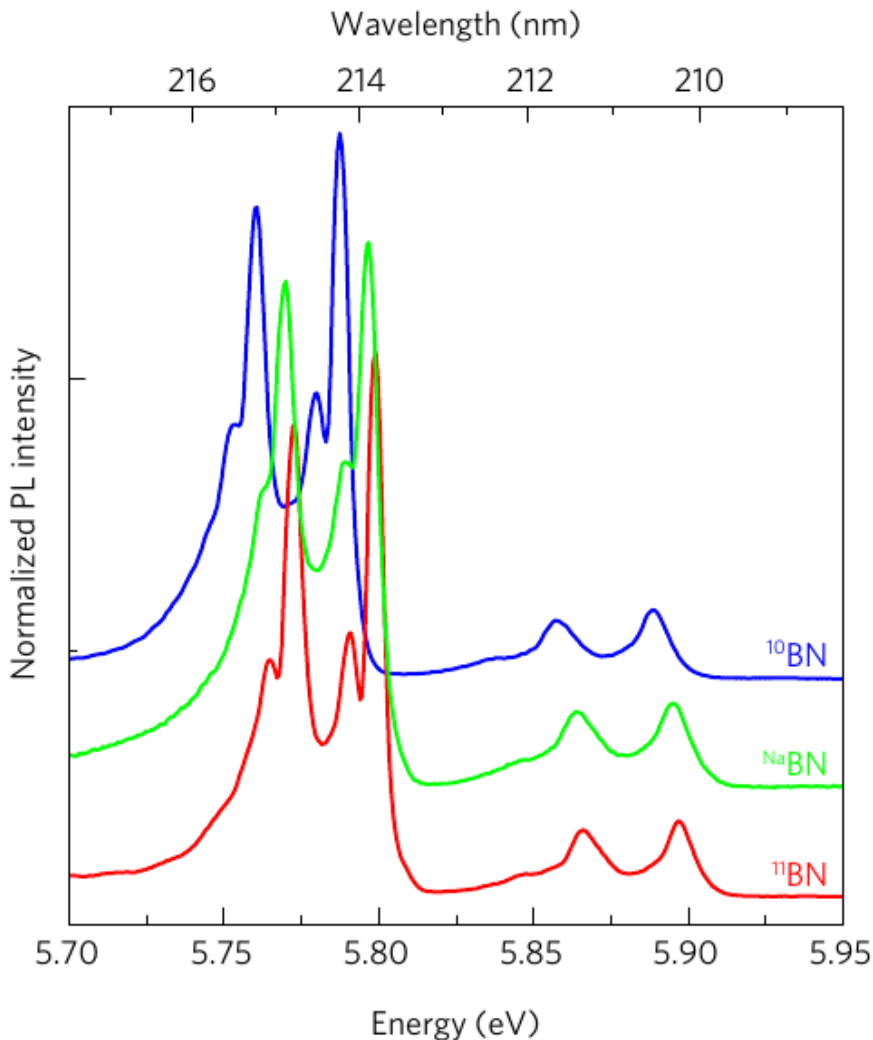


Vuong, Nature Mat. **17**, 152 (2018)

- ♦ Raman-active E_{2g} mode of high energy
- ♦ $\omega \sim \sqrt{\frac{k}{m}}$
- ♦ Narrower lines in ¹⁰BN and ¹¹BN
- ♦ Broadening due to isotopic mass disorder in ^{Na}BN

Isotopic purification

Vuong, Nature Mat. 17, 152 (2018)



- ◆ Global red-shift from ¹¹B to ¹⁰B
- ◆ PL spectrum composed of phonon replicas

$$h\nu = E_{gap} - E_{phonon}$$

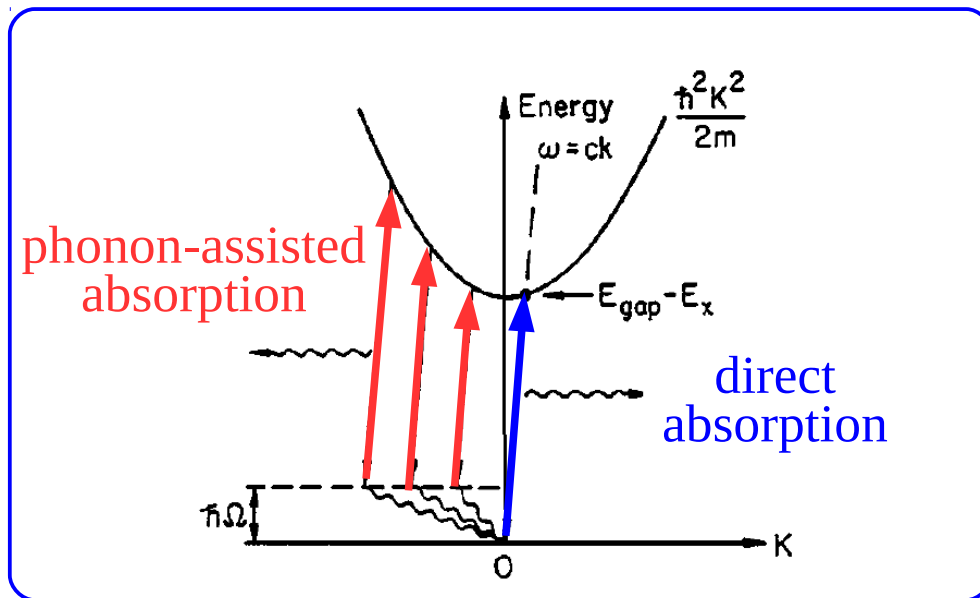
$$\delta E_{gap} \propto \frac{-1}{\sqrt{m}}$$

$$\propto \frac{1}{\sqrt{m}}$$

Outline

- Indirect vs direct bandgap semiconductors
- Two-photon spectroscopy
- Unconventional optical response
- Prospects

Phonon-assisted absorption



- **direct absorption** : within the light-cone

 - > narrow line

- **indirect absorption** : maps the full exciton dispersion

 - > typical **3D JDOS** given by

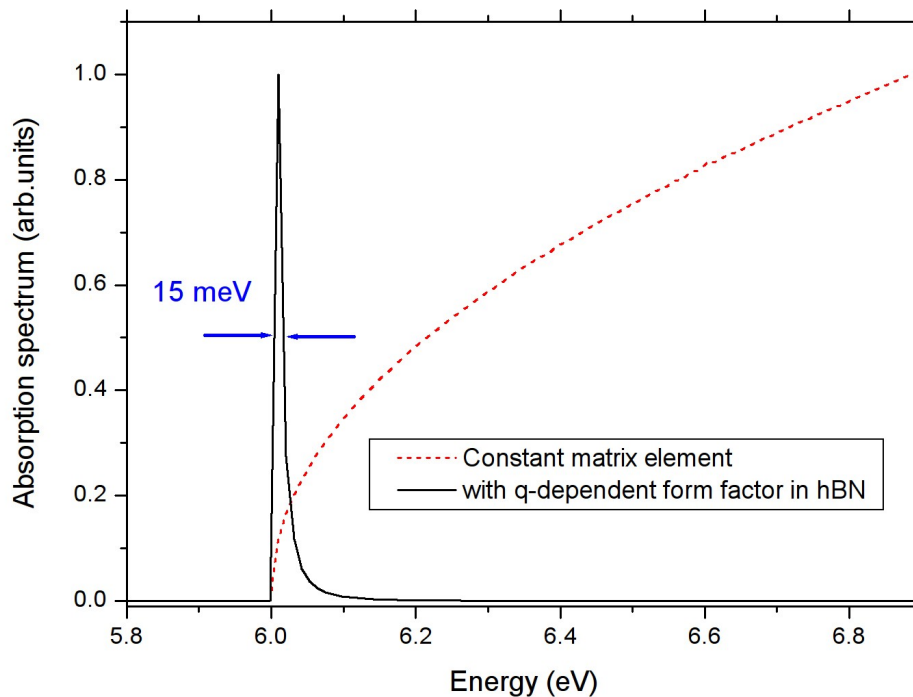
$$\sqrt{E - E_0}$$

Elliott, Phys. Rev. **108**, 1384 (1957)

Absorption profile in hBN

Two ingredients :

- joint density of states
- q-dependent exciton-phonon matrix element : cut-off for

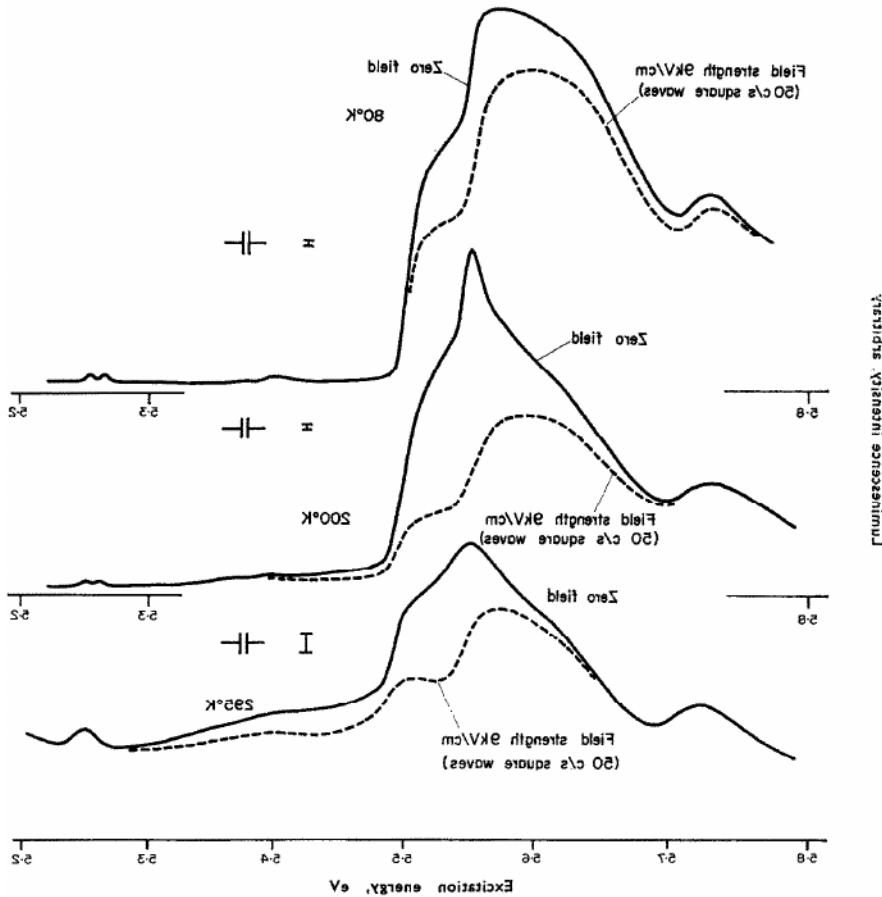


$$q \gg 1/a_B$$

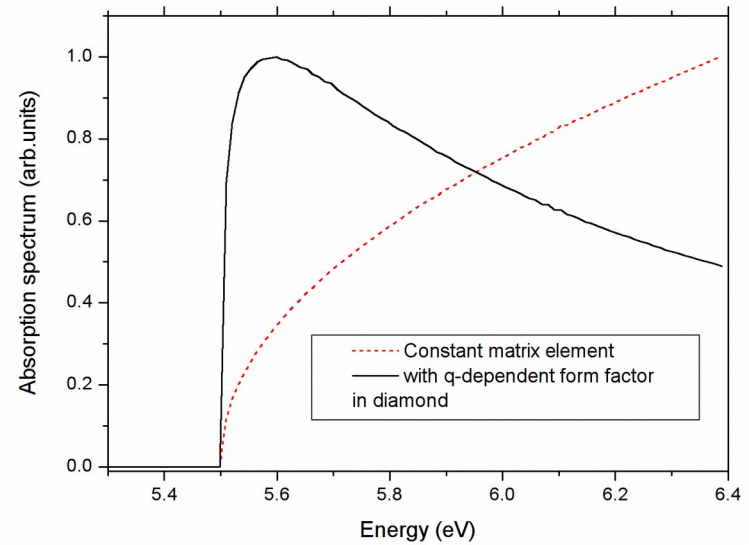
with a_B the exciton Bohr radius

Understanding the spectrum of indirect absorption

Diamond : Valence band @ zone center



Dean, J. Phys. Chem. Solids, 25, 1369 (1964)

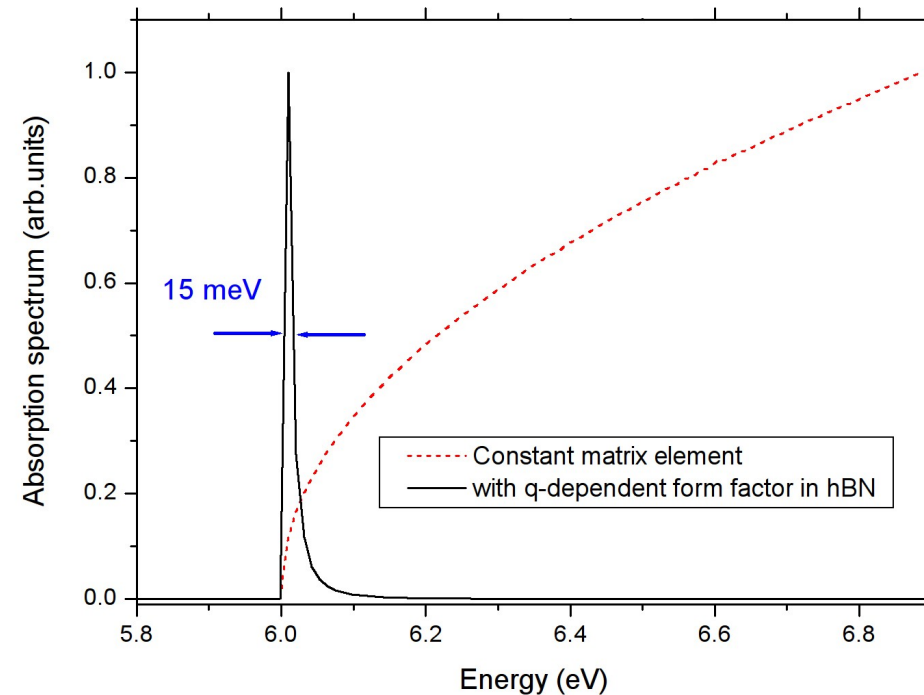
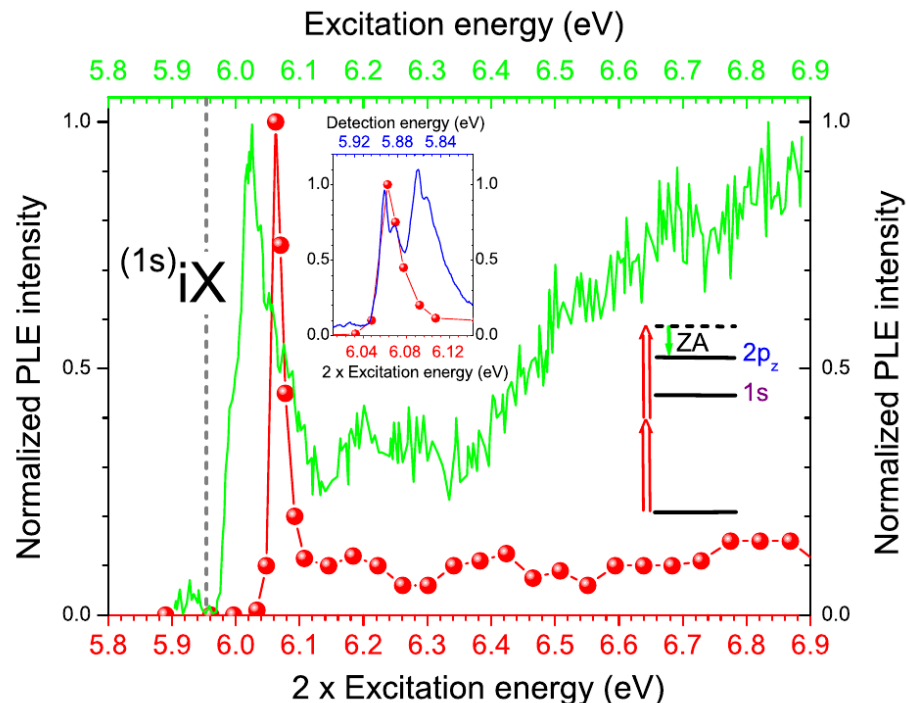


- ◆ $\sqrt{E - E_0}$ within the approximation of Elliott, Phys. Rev. **108**, 1384 (1957)
- ◆ **q-dependence** of exciton-phonon form factor

Understanding the spectrum of indirect absorption in hBN

hBN : Conduction AND Valence bands away from zone center

- a **unique** configuration for indirect bandgap materials
- observation of **narrow** lines for indirect bandgap material



Cassabois, Nature Photon. **10**, 262 (2016)

Outline

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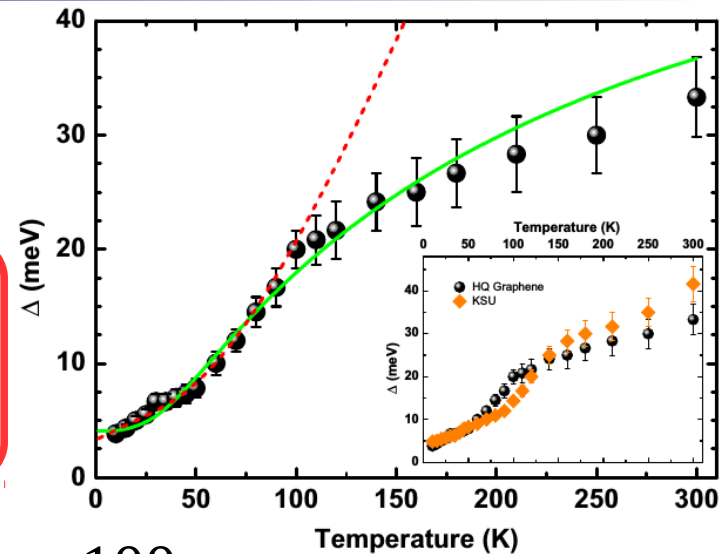
Strong exciton-phonon coupling in hBN, but why ?

Thermally-assisted broadening

Phys. Rev. B **95**, 201202(R) (2017)

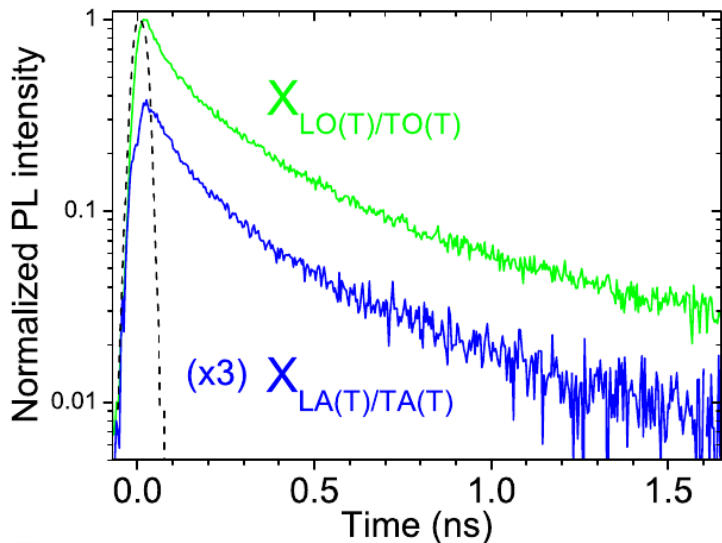
Gaussian profile

+ width increasing as \sqrt{T}



Phonon-assisted recombination time ~ 100 ps

Phys. Rev. B **93**, 035207 (2017)



Fast enough to :

- **bypass** non-radiative recombination
- get **high** internal quantum efficiency

First *ab initio* calculations of phonon-assisted emission

PHYSICAL REVIEW B **99**, 081109(R) (2019)

Rapid Communications

Theory of phonon-assisted luminescence in solids: Application to hexagonal boron nitride

E. Cannuccia,^{1,2} B. Monserrat,³ and C. Attaccalite^{1,4,5}

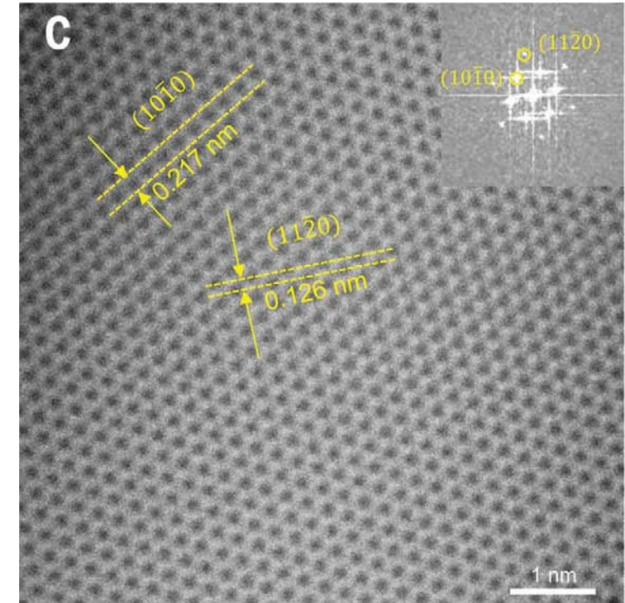
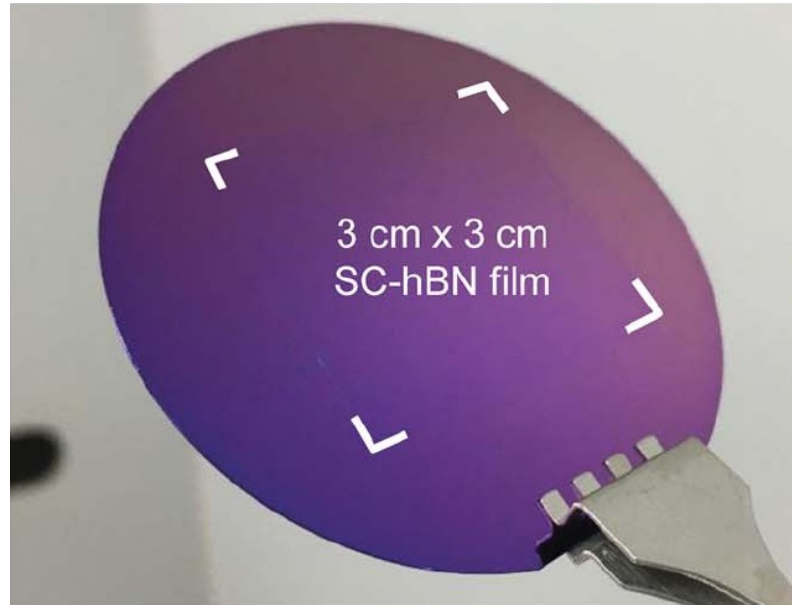
PHYSICAL REVIEW LETTERS **122**, 187401 (2019)

Exciton-Phonon Coupling in the Ultraviolet Absorption and Emission Spectra of Bulk Hexagonal Boron Nitride

Fulvio Paleari,^{1,*} Henrique P. C. Miranda,^{1,2} Alejandro Molina-Sánchez,³ and Ludger Wirtz¹

Epitaxy of high-quality hBN

Wafer-scale single crystal of monolayer hBN (KIST, Korea)



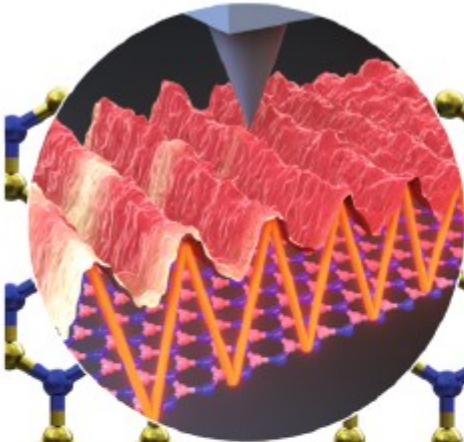
Lee, Science **362**, 817–821 (2018)

**NEXT STEPS : Thick epilayers
+ DOPING !**

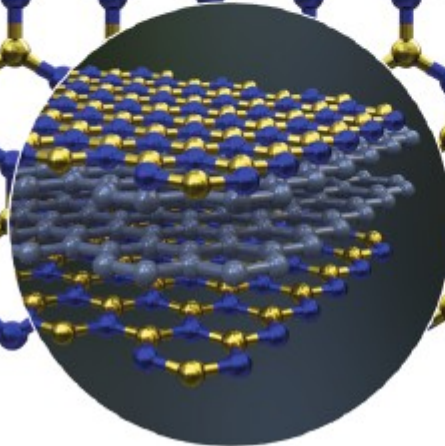
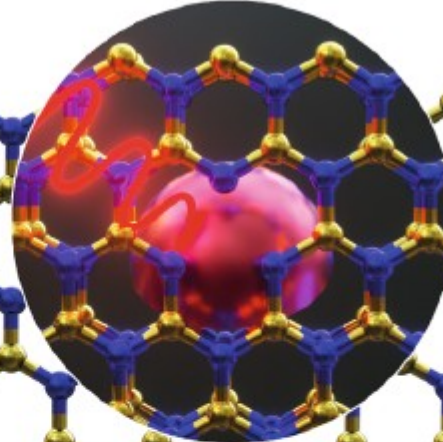
Photonics with hBN

Nature Reviews Materials 4, 552 (2019)

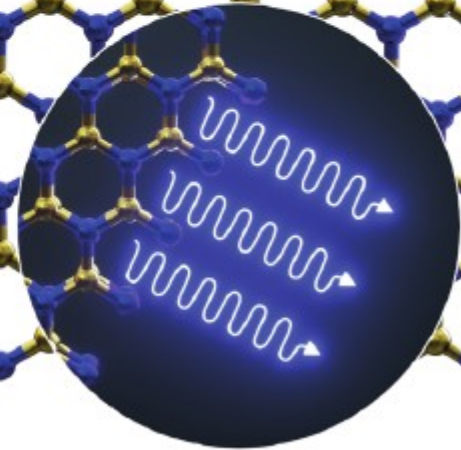
Infrared nanophotonics



Single-photon emitters



van der Waals heterostructures



Ultraviolet emitters

Acknowledgements

L2C, Montpellier, France

C. Elias
P. Vuong
T. Pelini
P. Valvin
L. Martinez
V. Jacques
B. Gil

LPS, Orsay, France

A. Zobelli

C2N, Saclay, France

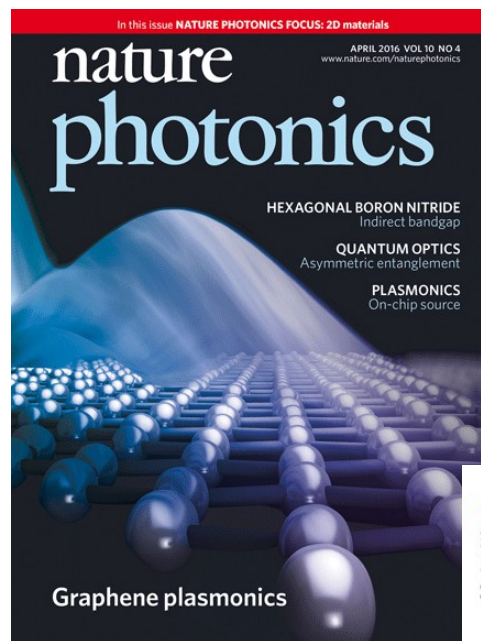
A. Ouerghi

NIMS, Ibaraki, Japan

K. Watanabe
T. Taniguchi

Barcelona, Spain

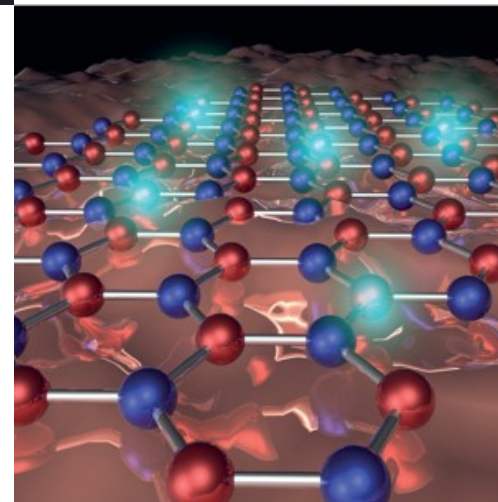
L. Artus
R. Cusco



nature
REVIEWS

August 2019 volume 4 no. 8
www.nature.com/naturematerials

MATERIALS



KSU, USA

J. Edgar

Nottingham, UK

S. Novikov

Optoelectronic properties of hexagonal boron nitride

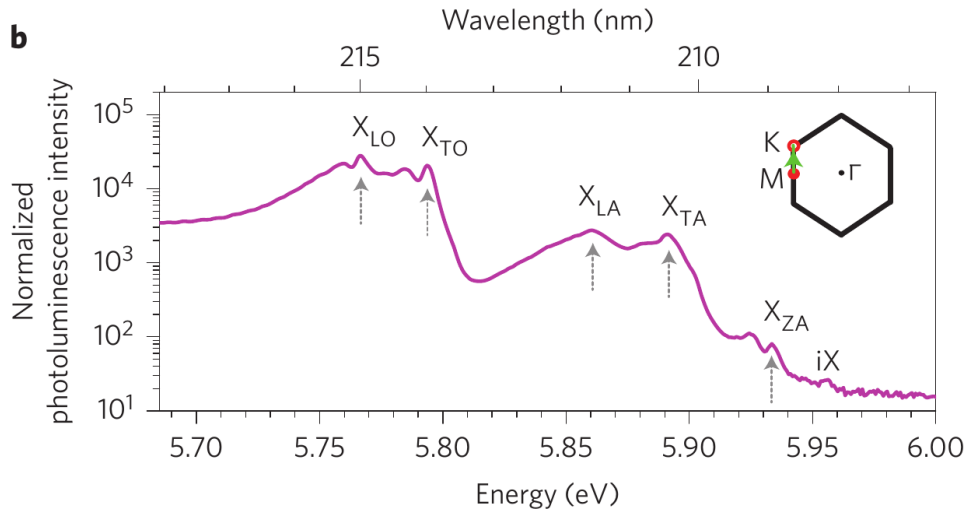
G. Cassabois

*Laboratoire Charles Coulomb
CNRS / Université de Montpellier
Montpellier, France*



Bulk hBN: an indirect bandgap material

Optical spectroscopy



Phonon-assisted emission

Cassabois, *Nature Photon.* **10**, 262 (2016)

♦ Isotopic purification

Vuong, *Nature Mat.* **17**, 152 (2018)

♦ Polarization selection rules

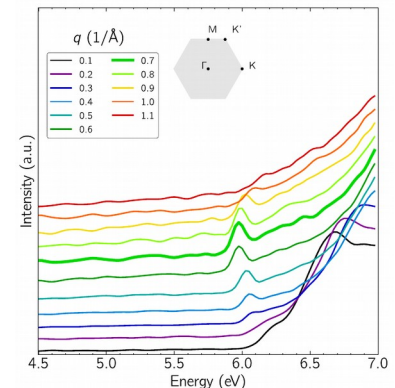
Vuong, *2D Mater.* **4**, 011004 (2017)

♦ Phonon group velocity

Vuong, *PRB* **95**, 045207 (2017)

EELS

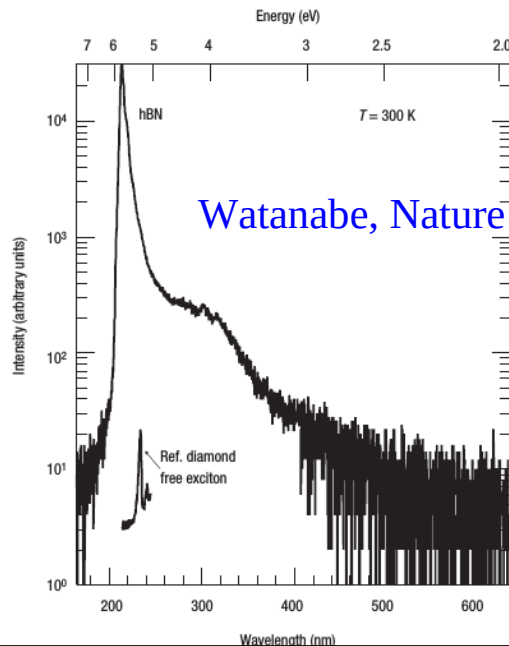
Schuster, *PRB* **97**, 041201 (2018)



Deep UV opto-electronics

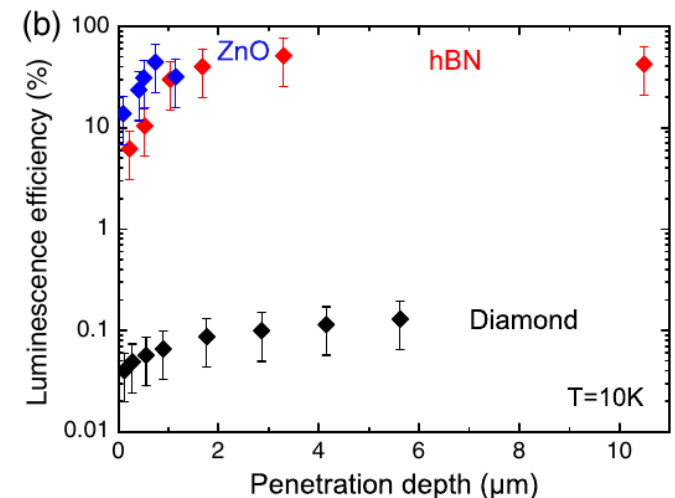
hBN = perfect candidate for deep UV

- High extraction efficiency
(as usual for indirect semiconductors)
- High internal quantum efficiency
VERY UNUSUAL



Watanabe, Nature Mat. 3, 404 (2004)

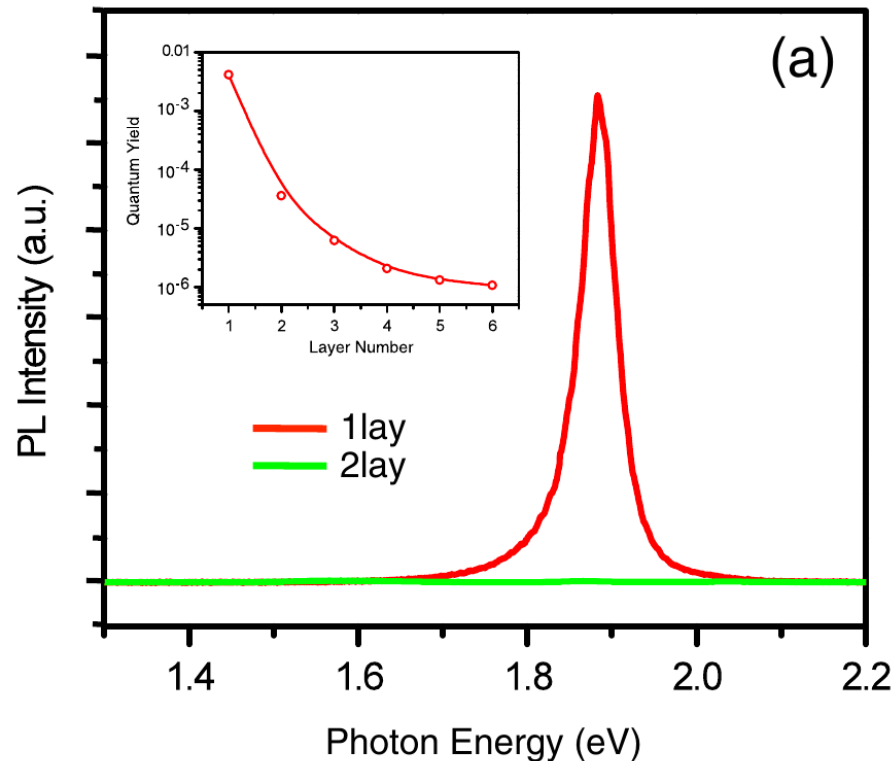
Schue, PRL 122, 067401 (2019)



Monolayer hBN : a direct bandgap semiconductor

Direct bandgap emission in monolayer

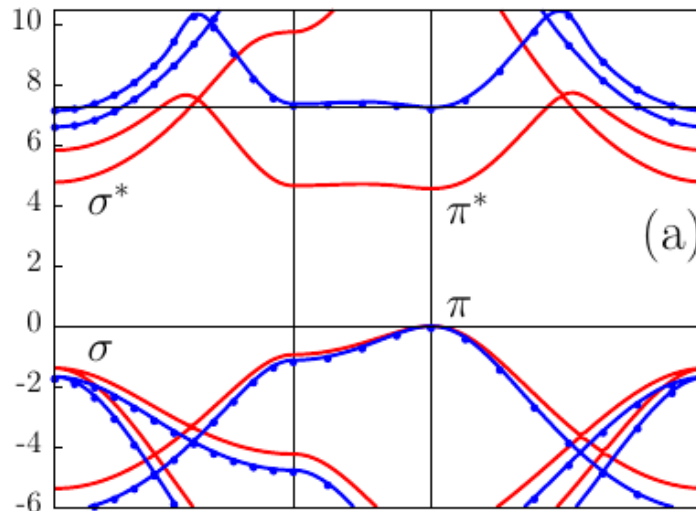
- The textbook example of MoS_2



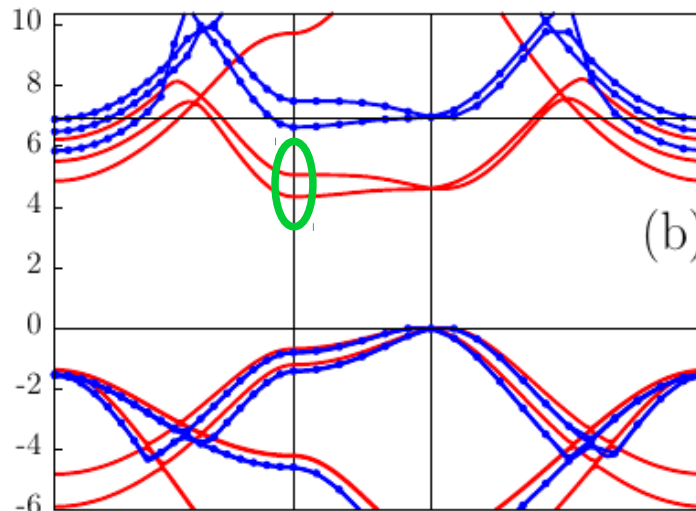
Phys. Rev. Lett. **105**, 136805 (2010)

- Same effect is predicted in hBN !!

Electronic bandstructure vs layer number



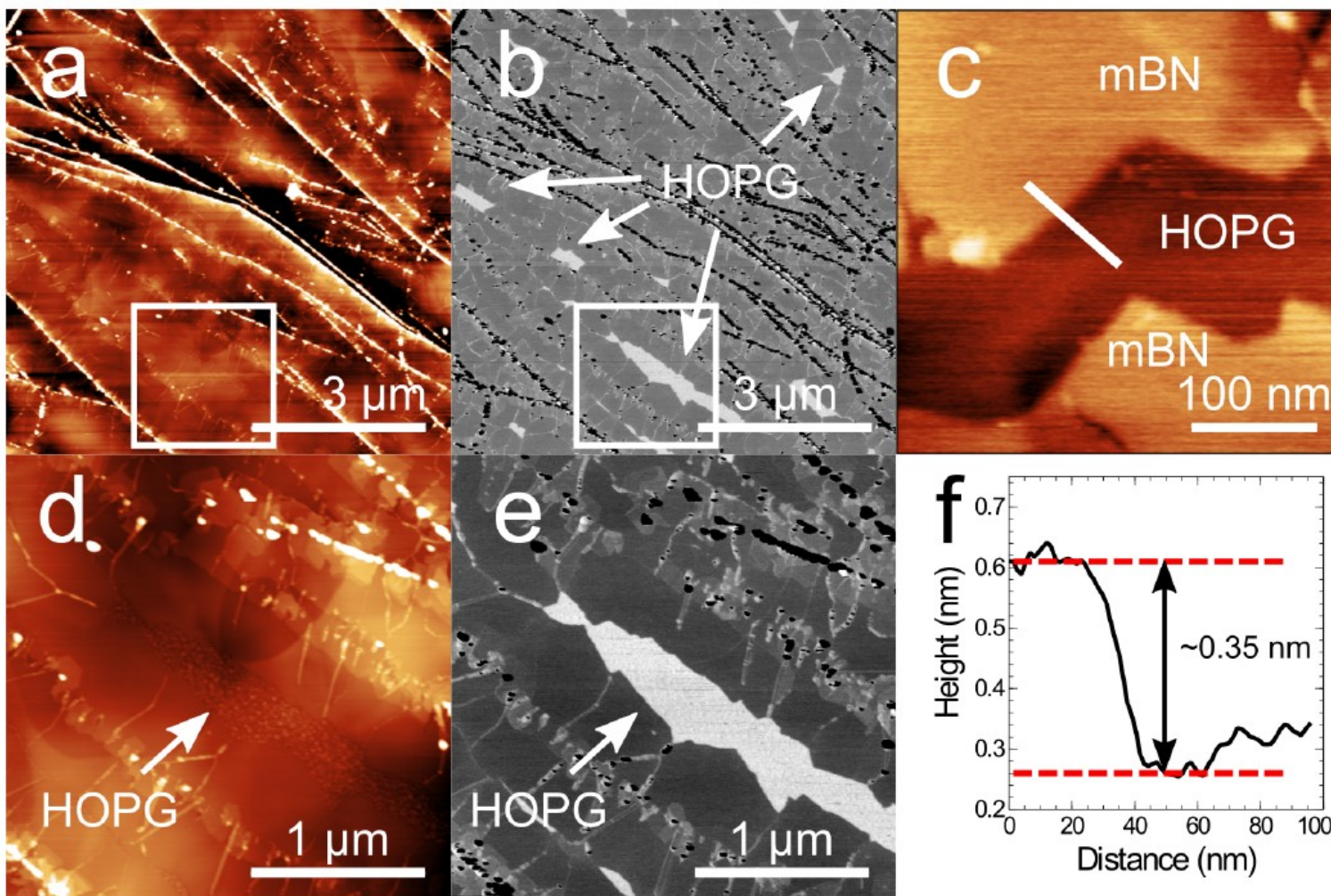
1 layer : direct bandgap



2 layers : indirect bandgap
to bulk

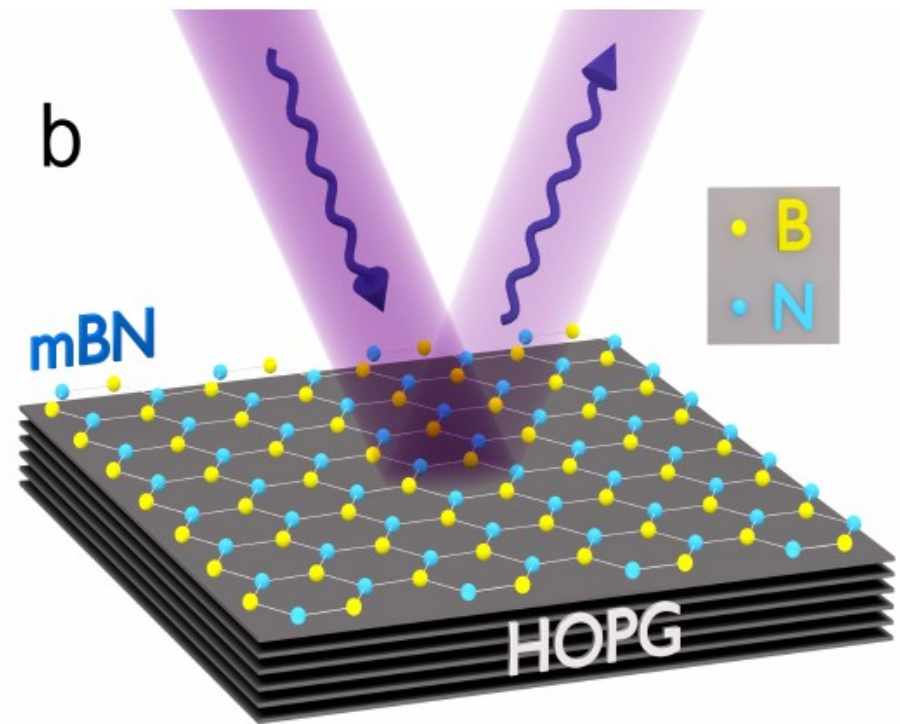
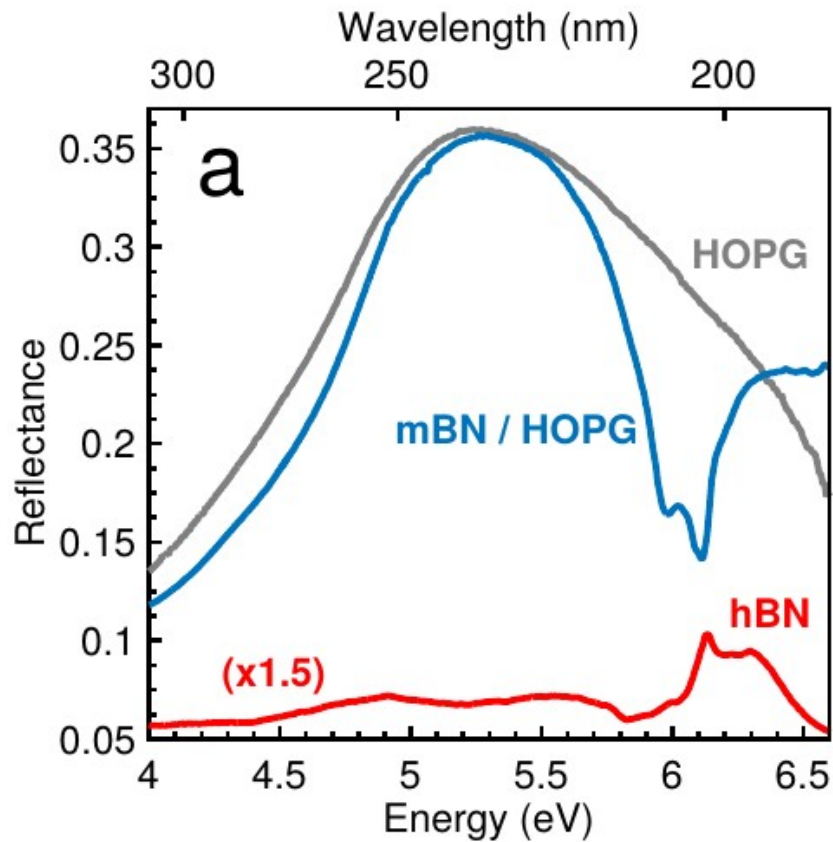
AFM in epitaxial monolayer hBN

High-temperature MBE S. Novikov (Nottingham)



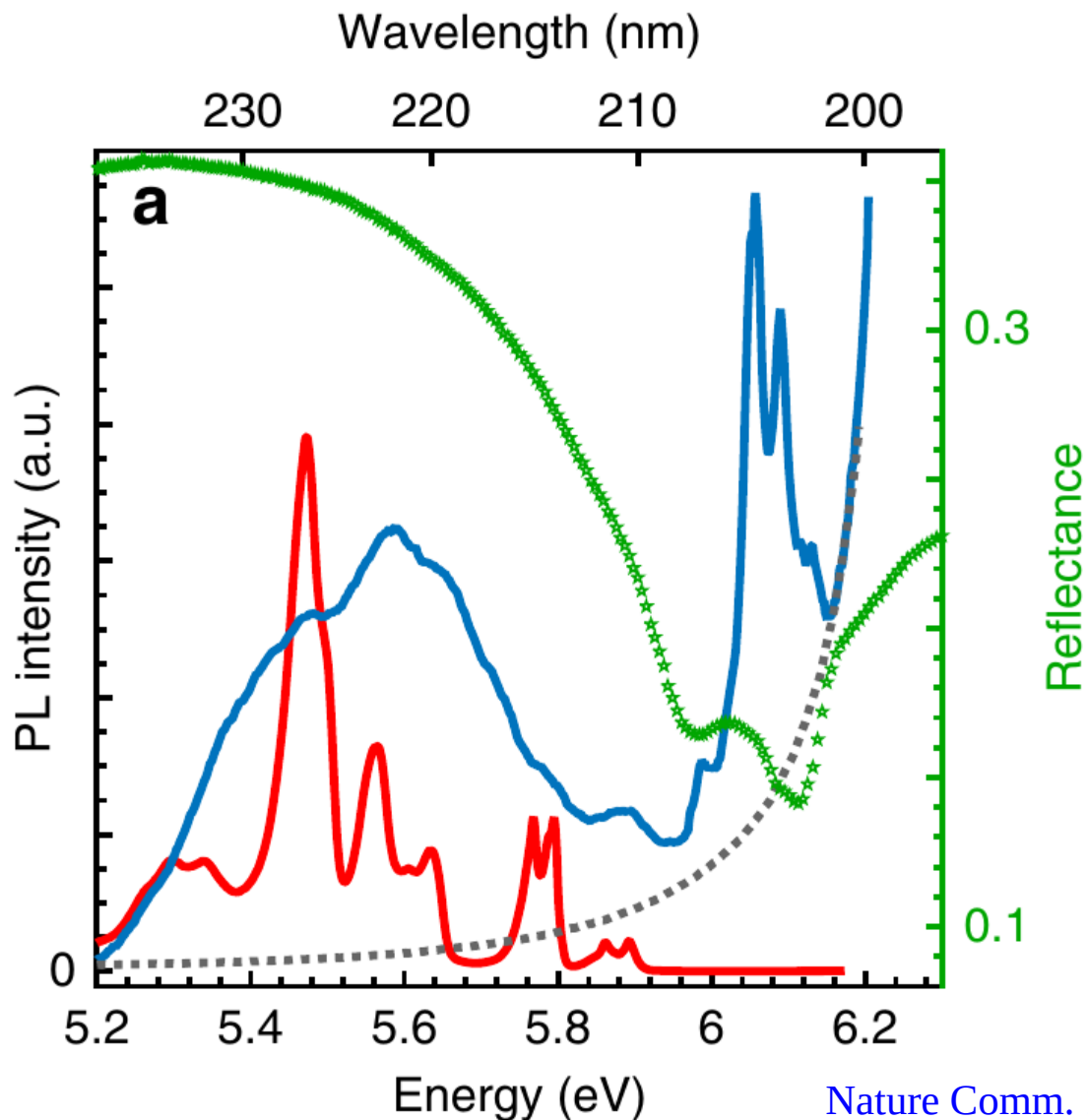
Nature Comm. 10, 2639 (2019)

Reflectance in epitaxial monolayer hBN



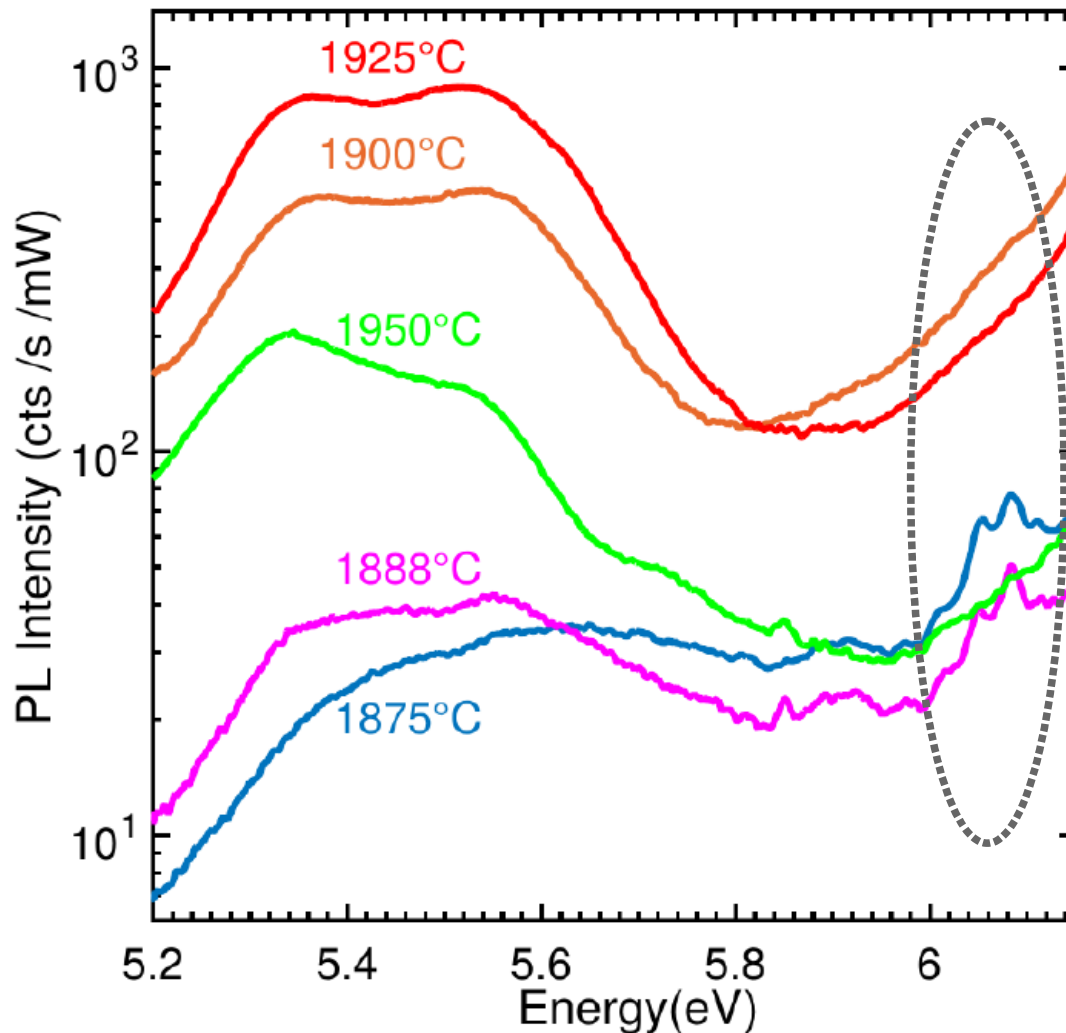
Nature Comm. **10**, 2639 (2019)

Photoluminescence in epitaxial monolayer hBN



Nature Comm. **10**, 2639 (2019)

Thickness dependence

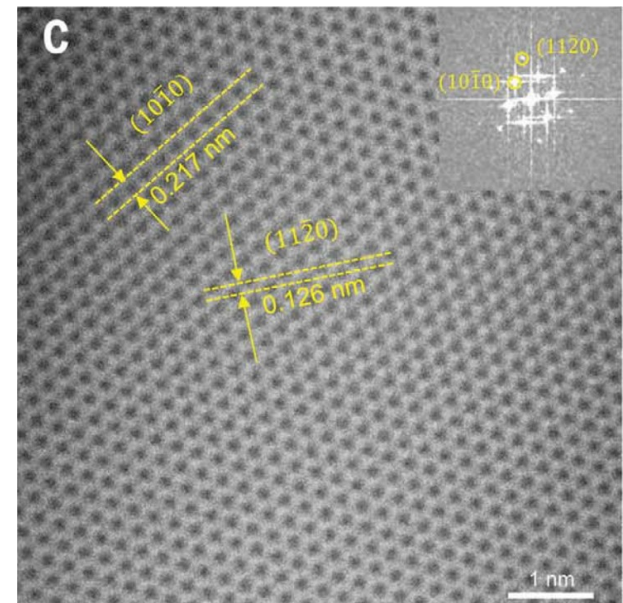
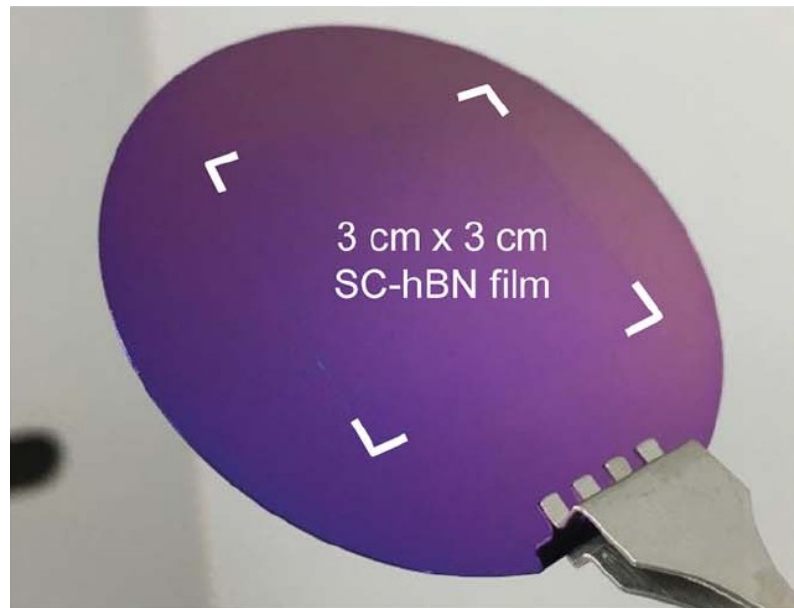


- ◆ BN coverage increases with boron-cell temperature
- ◆ Simultaneous suppression of monolayer emission

Nature Comm. **10**, 2639 (2019)

Recent breakthrough in CVD

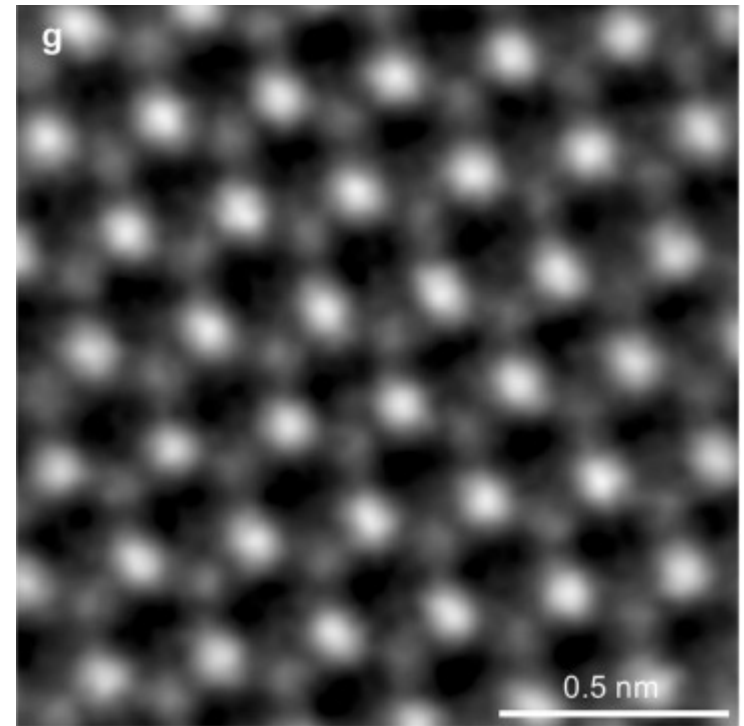
Wafer-scale single crystal of monolayer hBN (KIST, Korea)



Lee, Science **362**, 817–821 (2018)

Another recent breakthrough in CVD

Wafer-scale single crystal of monolayer hBN (Peking Univ., China)



Wang, Nature **570**, 91 (2019)

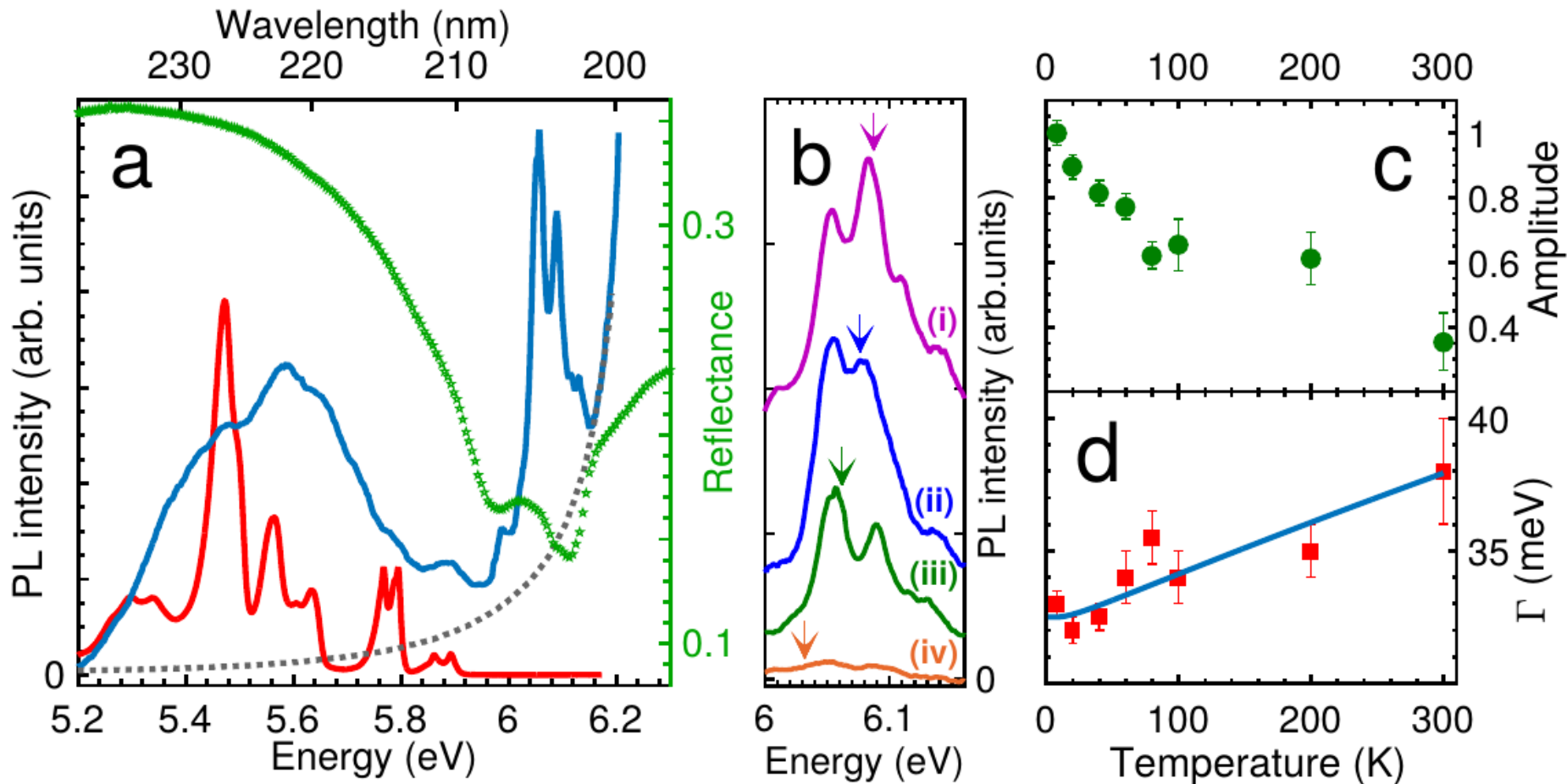
Deep UV Emission in Hexagonal Boron Nitride: from Bulk to Monolayer

G. Cassabois

*Laboratoire Charles Coulomb
CNRS / Université de Montpellier
Montpellier, France*



Direct bandgap crossover in epitaxial monolayer hBN

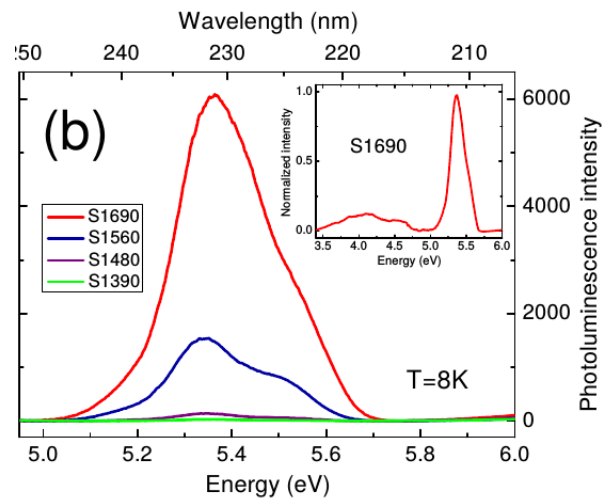
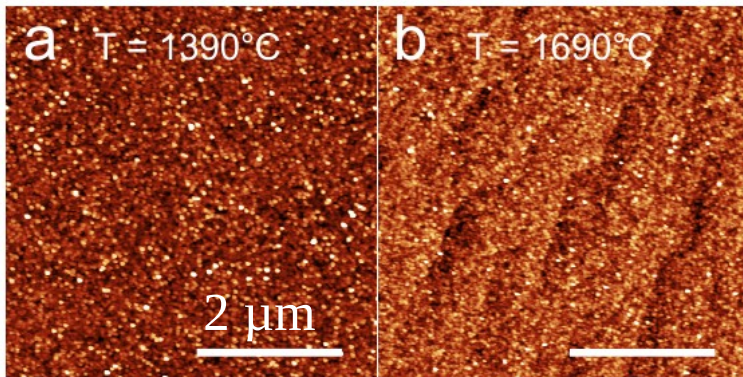


Nature Comm. **10**, 2639 (2019)

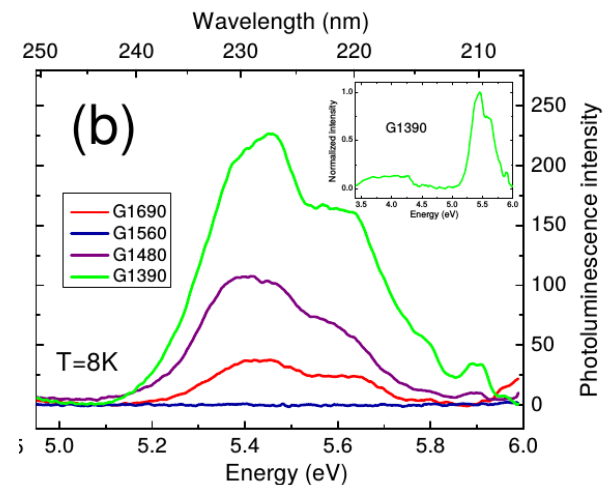
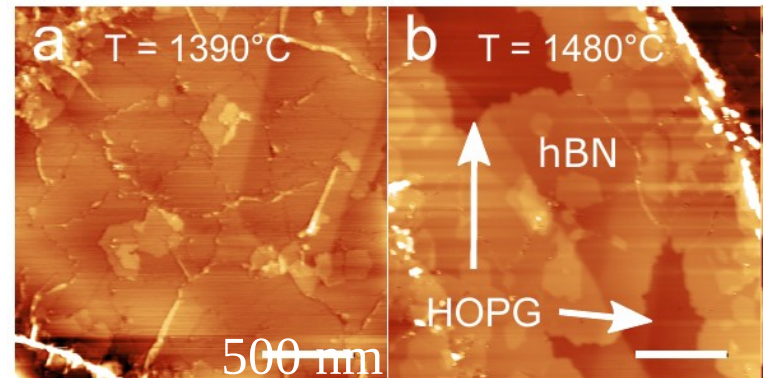
MBE

S. Novikov (Nottingham)

hBN on sapphire



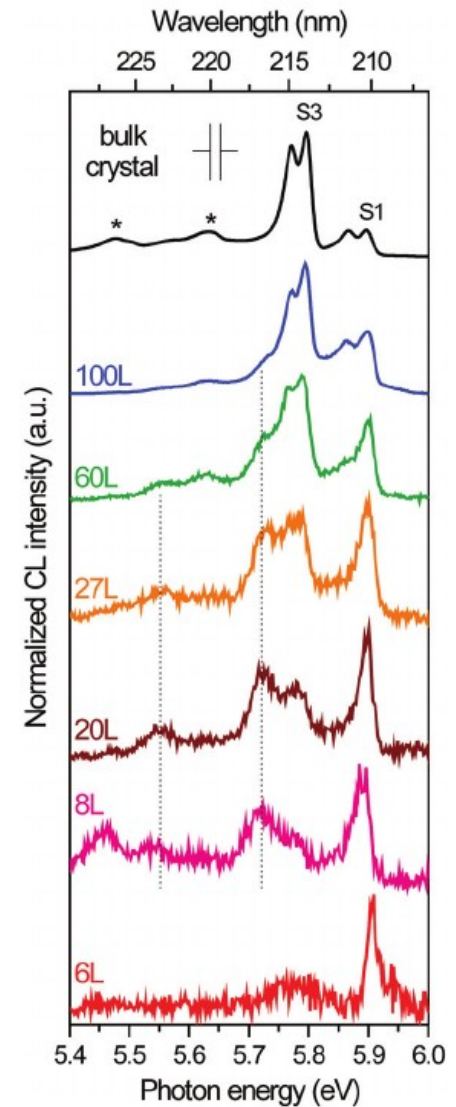
hBN on graphite



Vuong, 2D Mater. 4, 021023 (2017)

Few-layer hBN crystals

- Cathodoluminescence down to 6 monolayers
 - ◆ Exfoliated flakes
 - ◆ Modification of phonon replica intensity
 - ◆ Dominant emission at 5.9 eV (TA phonon)

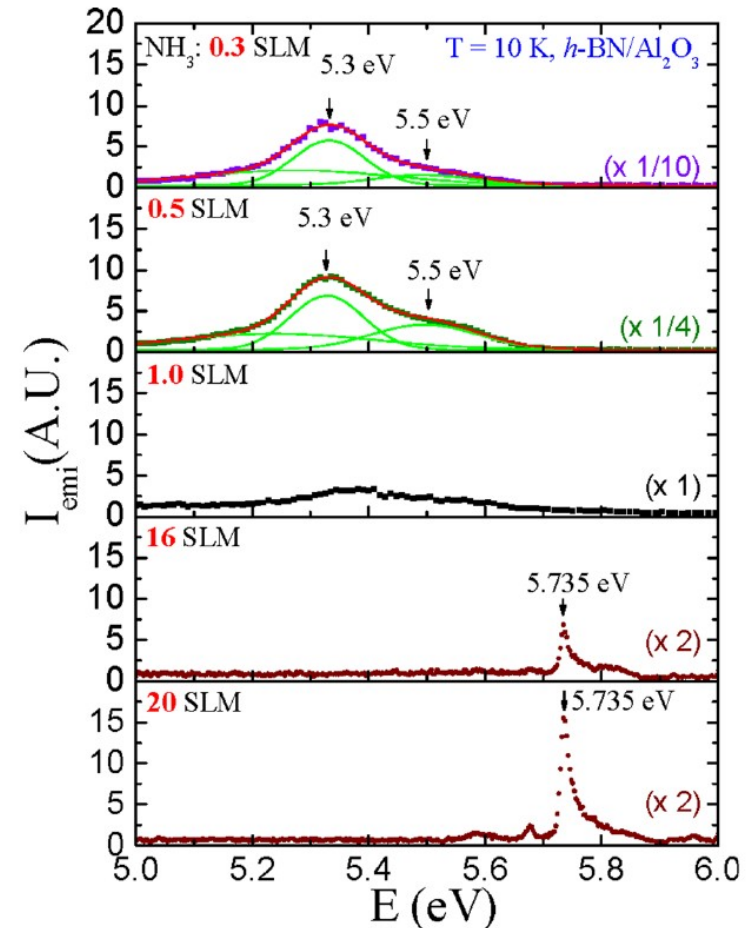
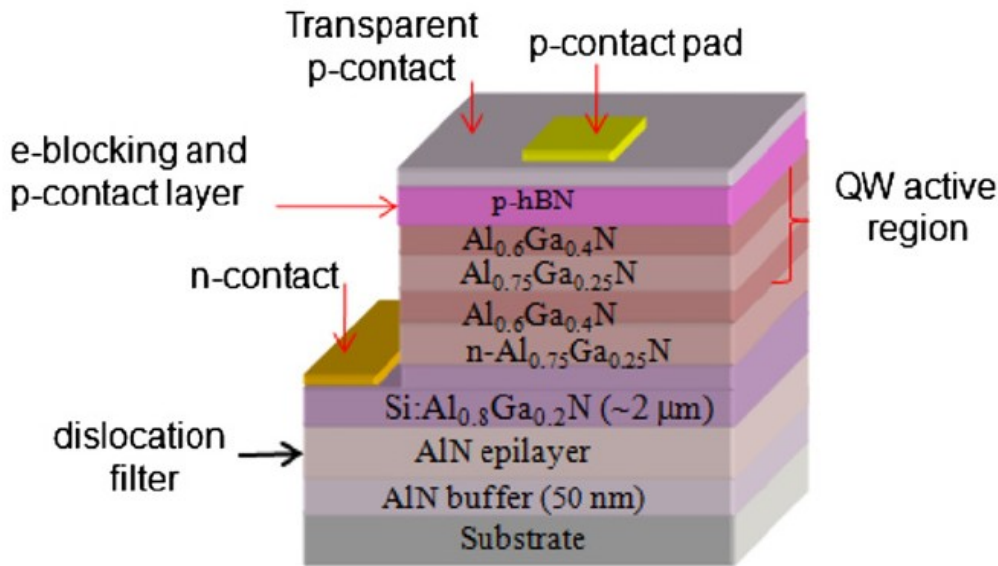


Schué, *Nanoscale*, 10.1039/C6NR01253A

MOCVD

Pioneering work at Texas Tech (H.X. Jiang)

Deep-UV LED device



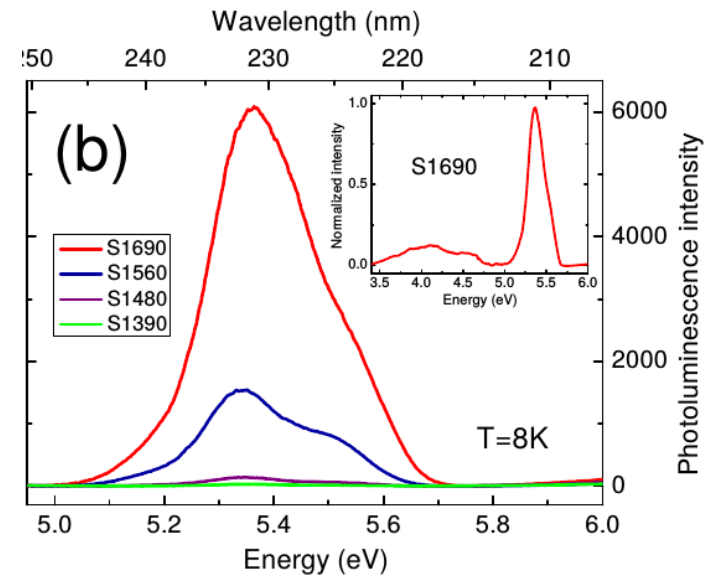
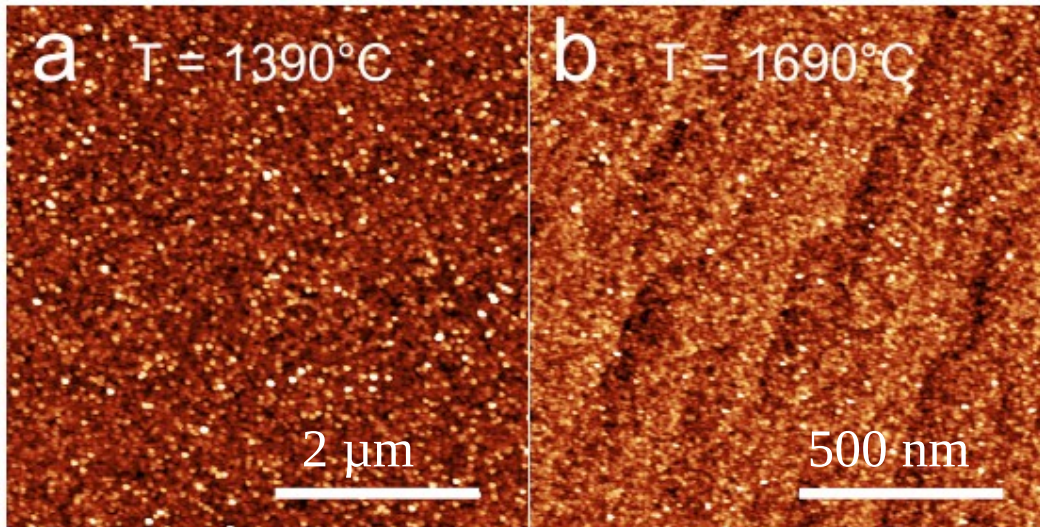
Jiang, *Semicond. Sci. Technol.* **29**, 084003 (2014)

Du, *APL* **108**, 052106 (2016)

MBE

S. Novikov (Nottingham)

hBN on sapphire

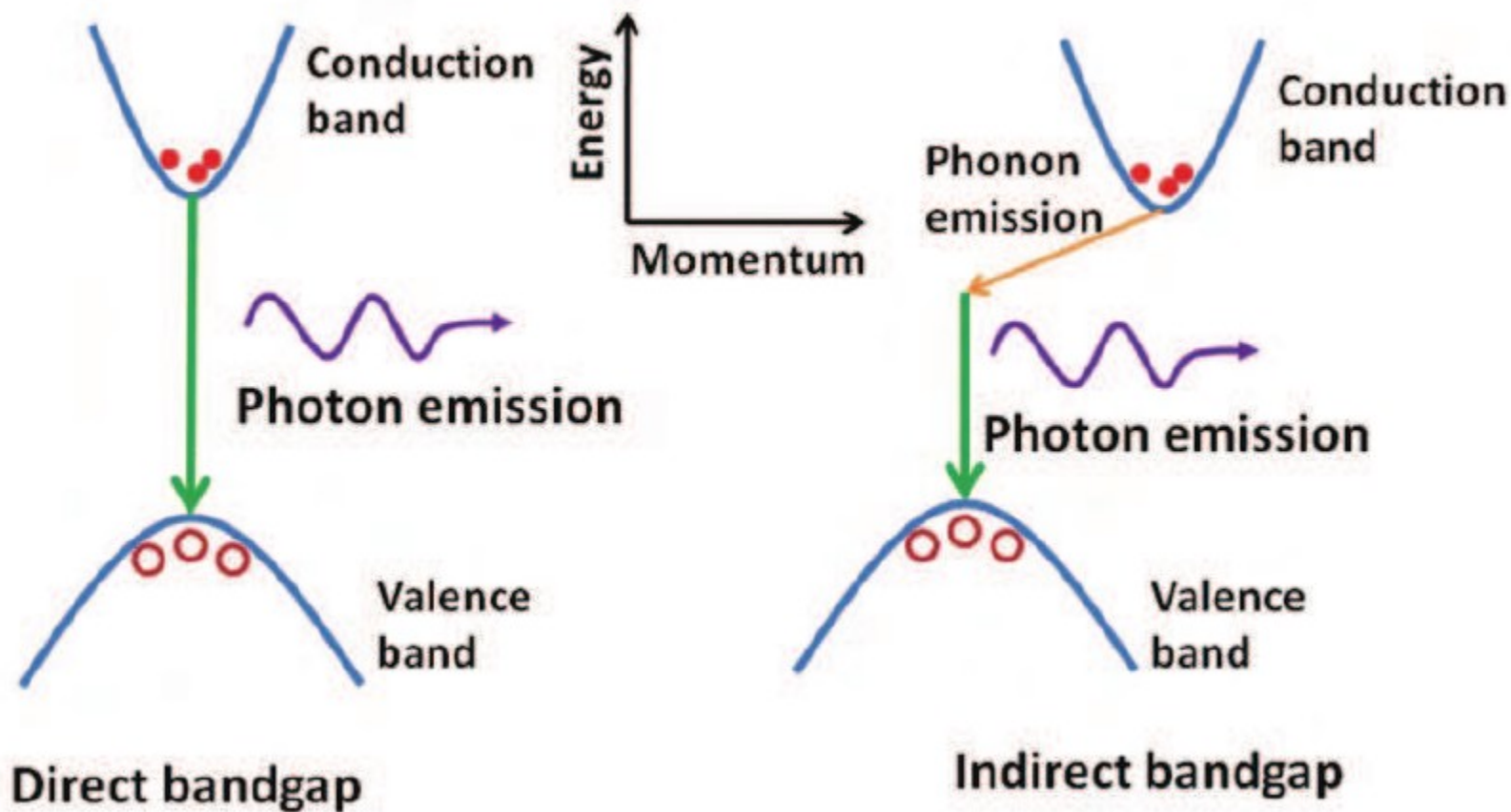


Vuong, 2D Mater. 4, 021023 (2017)

Direct versus indirect recombination

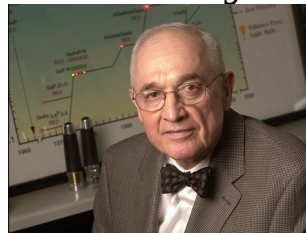
Direct

Indirect

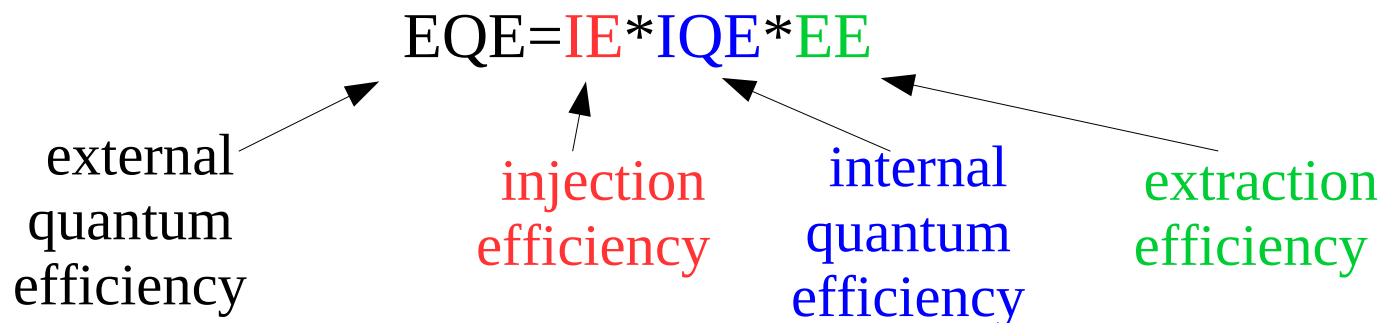


Back in the early times of LED research

- In the 1920s : the amazing contribution of Losev (Leningrad) with the first LED based on SiC
- In the 1960s : the Holonyak work on GaAsP



at that time, the best strategy was not clear :
direct or indirect semiconductors ?



LEDs based on a bulk active region

Direct bandgap

Indirect bandgap

internal
quantum
efficiency

HIGH

LOW

(phonon-assisted emission)

extraction
efficiency

LOW

HIGH

(re-absorption)

LEDs based on a bulk active region

	Direct bandgap	Indirect bandgap
internal quantum efficiency	HIGH	LOW (phonon-assisted emission)
extraction efficiency	LOW (re-absorption)	HIGH

In the 1980s, came the revolution of quantum wells

High IQE in hBN

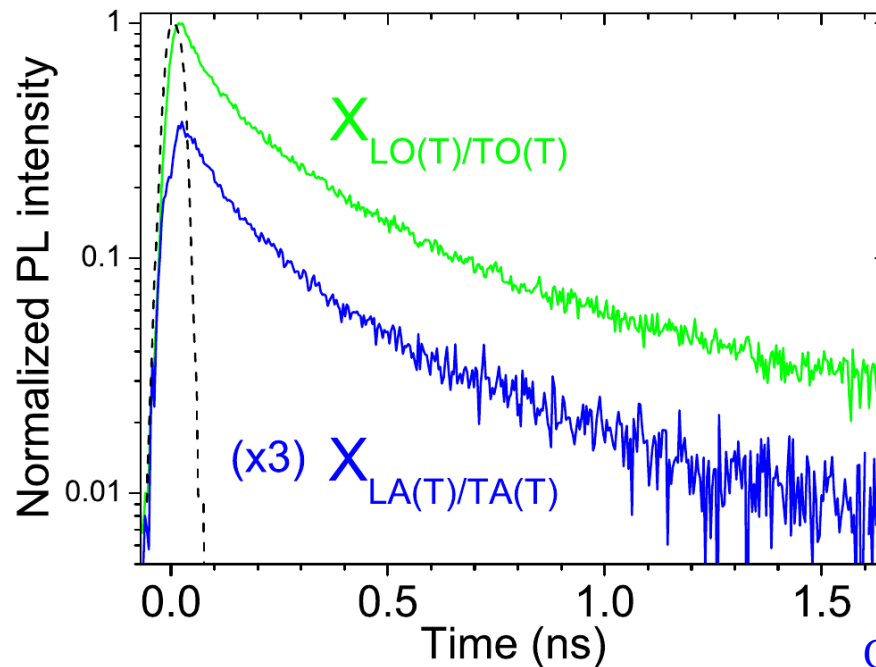
- $$IQE = \frac{\gamma_{rad}}{\gamma_{rad} + \gamma_{nrad}}$$

- ◆ **Direct** semiconductors : $\gamma_{rad} \gg \gamma_{nrad}$
- ◆ **Indirect** semiconductors : $\gamma_{rad} \ll \gamma_{nrad}$
- ◆ In hBN : $\gamma_{rad} \gtrsim \gamma_{nrad}$

Phonon-assisted recombination fast enough
to bypass non-radiative processes

Recombination dynamics

- time-resolved PL measurements at the energy of the **optical** and **acoustic** phonon replicas



200 ps lifetime

Cassabois, PRB **93**, 035207 (2016)

- identical decays reflecting the dynamics of the *iX* indirect exciton reservoir

Theory of Line-Shapes of the Exciton Absorption Bands

Yutaka TOYOZAWA

Research Institute for Fundamental Physics, Kyoto University, Kyoto

(Received April 12, 1958)

A general theory of line-shapes of the exciton absorption bands is developed with the help of generating function method. When the exciton-lattice coupling is weak, and the exciton effective mass is small, the absorption band is of a Lorentzian shape, provided that the temperature T is not too high. The half-value width H is given by the level broadening of the optically produced $\mathbf{K}=0$ exciton due to lattice scattering, so that it is proportional to T except at low temperatures. If the coupling is strong, or the exciton effective mass is large, or the temperature is very high, the absorption band is expected to be of a Gaussian shape, and H is proportional to \sqrt{T} . The mutual influence of adjacent absorption bands is also discussed; it causes the asymmetry and repulsion of the components as temperature rises.

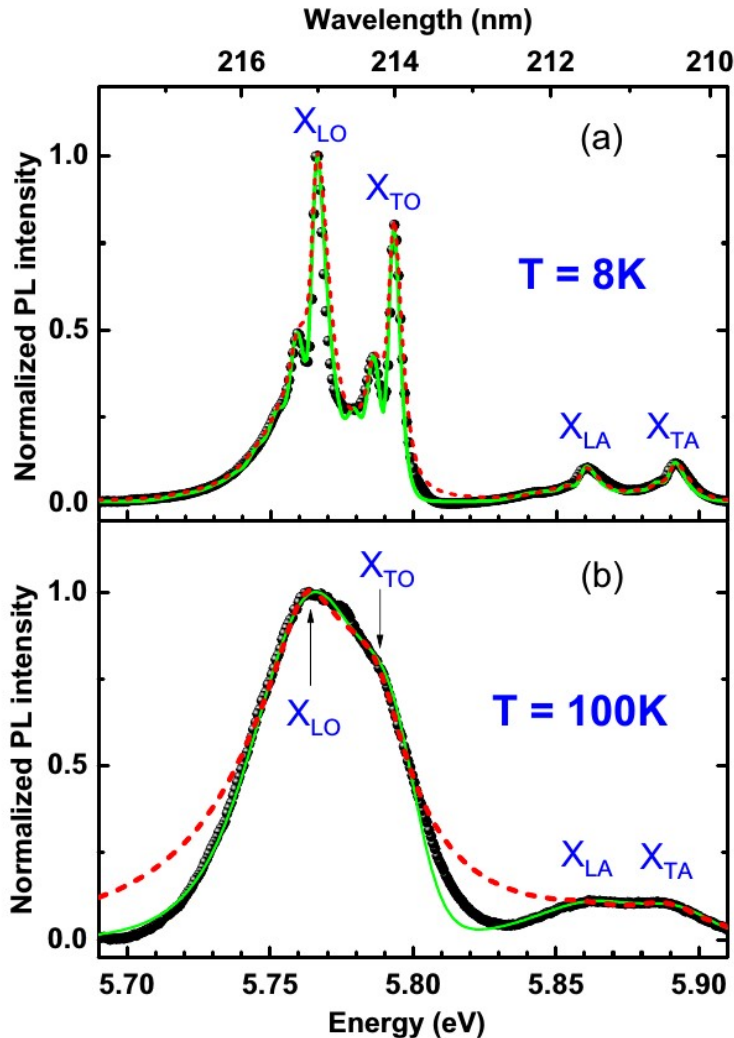
Strong coupling

Gaussian profile
+ width increasing as \sqrt{T}

Weak coupling

Lorentzian profile
+ width increasing as T

Gaussian lineshape

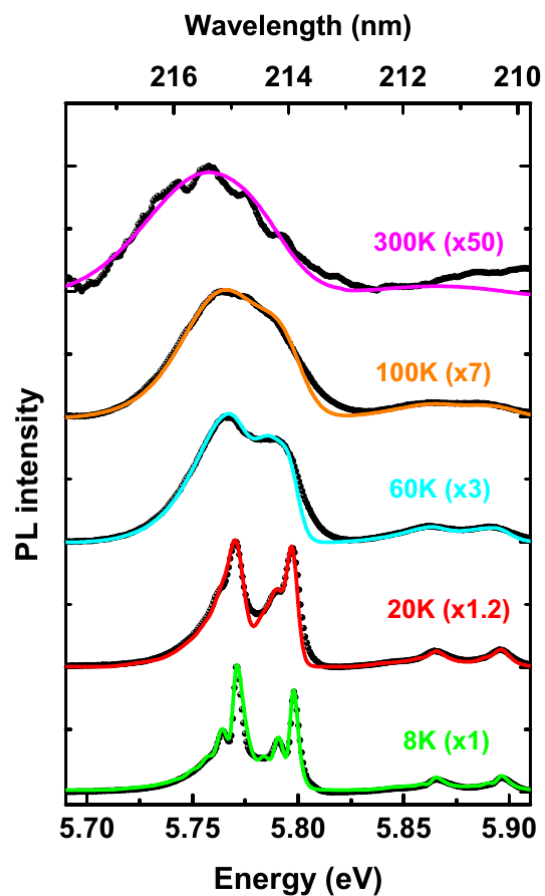


Gaussian profile

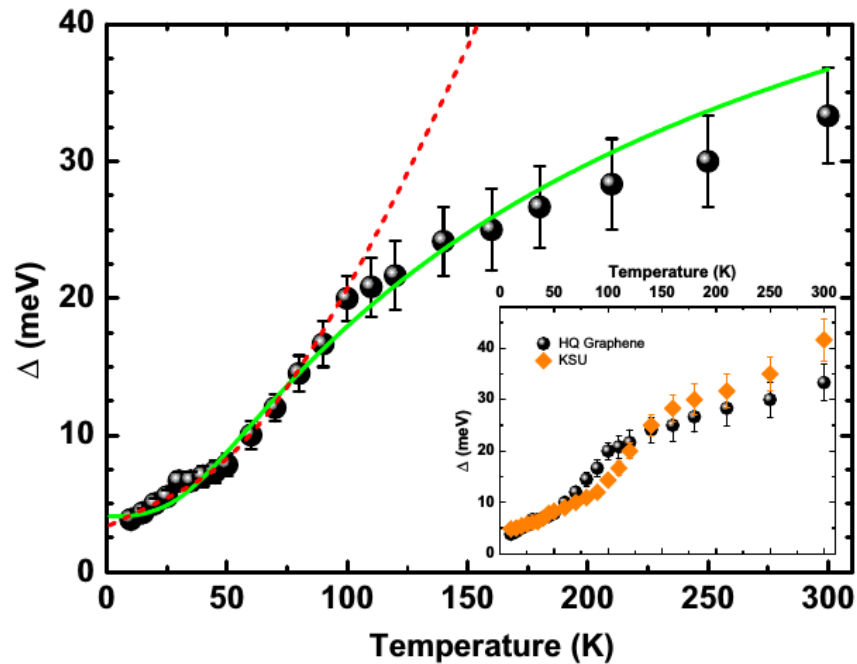
- at low temperature
- **AND** at high temperature

Vuong, PRB **95**, 201202(R) (2017)

Thermal broadening



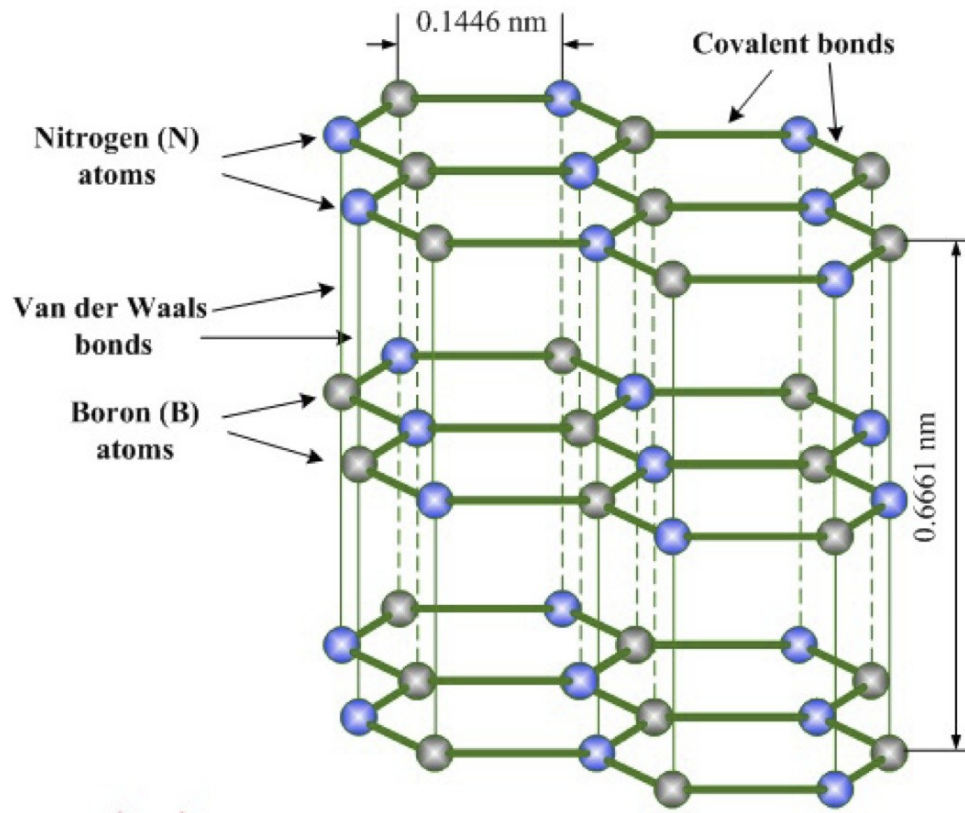
width increasing as \sqrt{T}



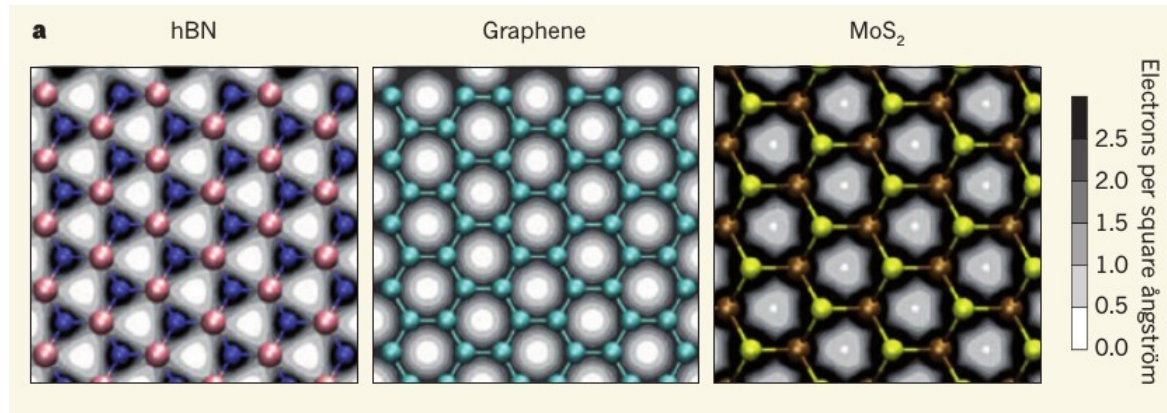
Vuong, PRB **95**, 201202(R) (2017)

“White graphite”

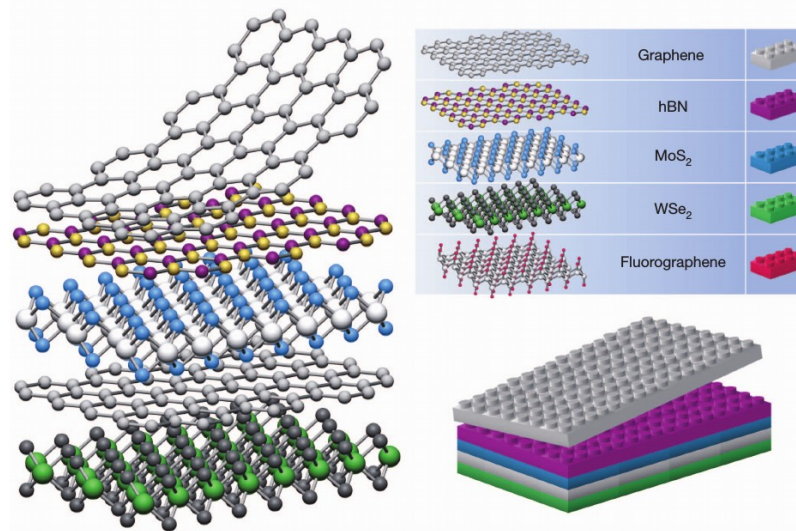
Hexagonal boron nitride structure



Beyond graphene

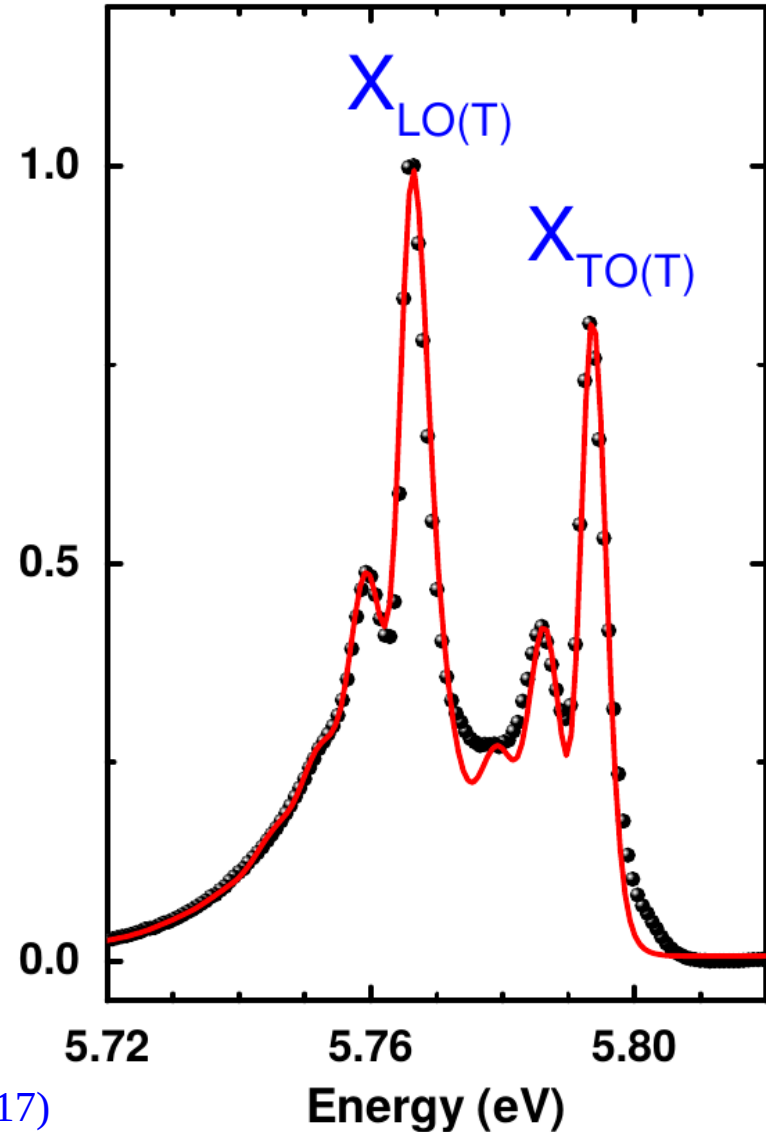
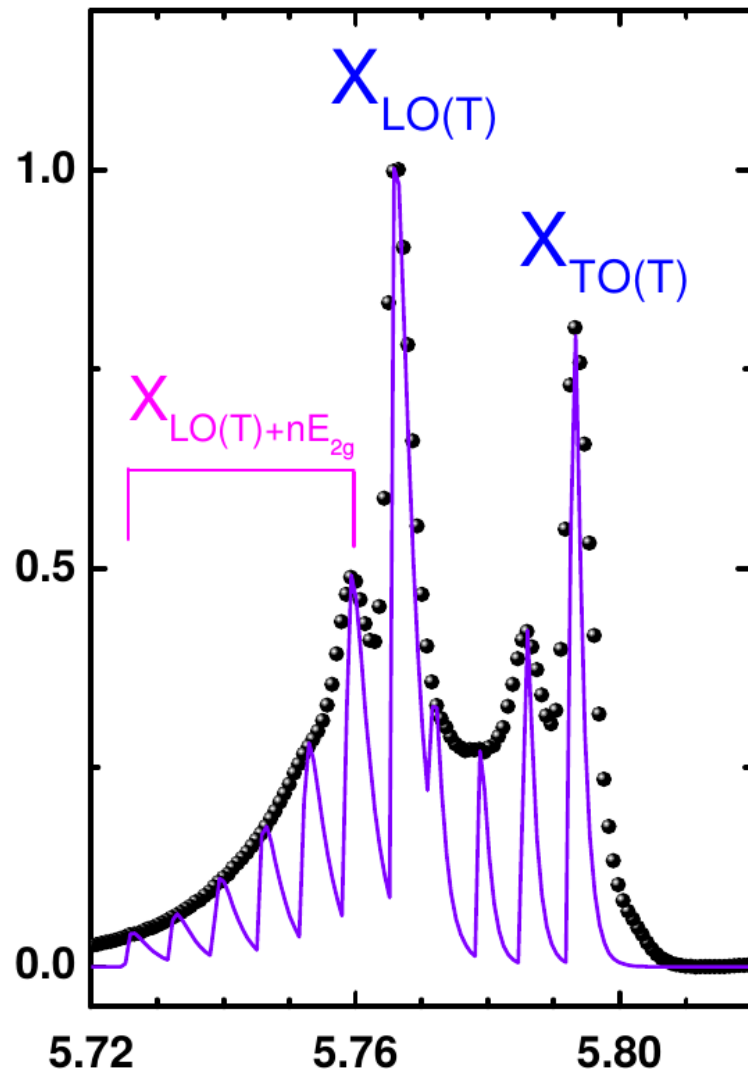


Van der Waals heterostructures



Geim, Nature **499**, 419 (2013)

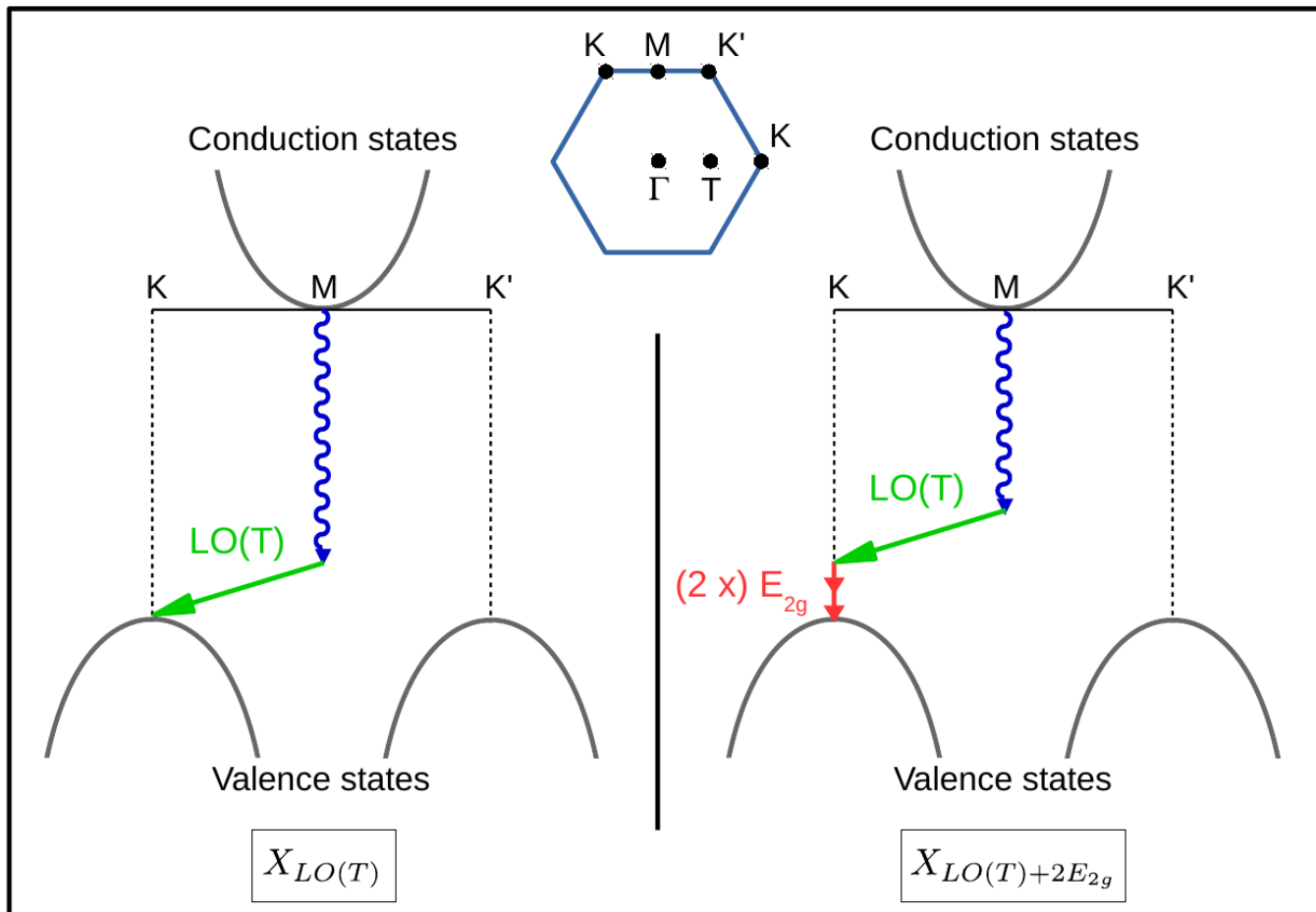
Raman overtones



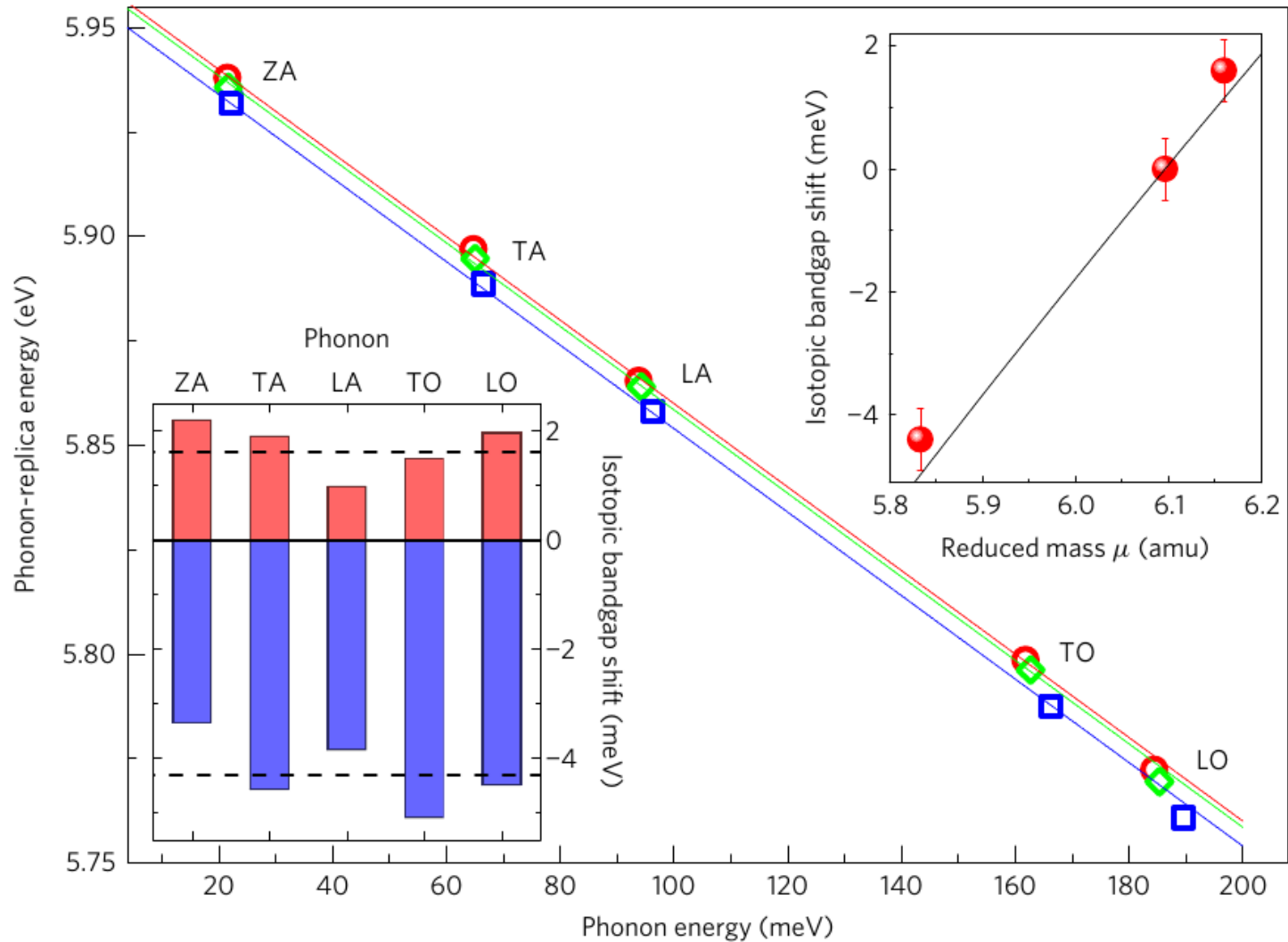
Vuong, PRB 95, 045207 (2017)

High-order phonon-assisted processes

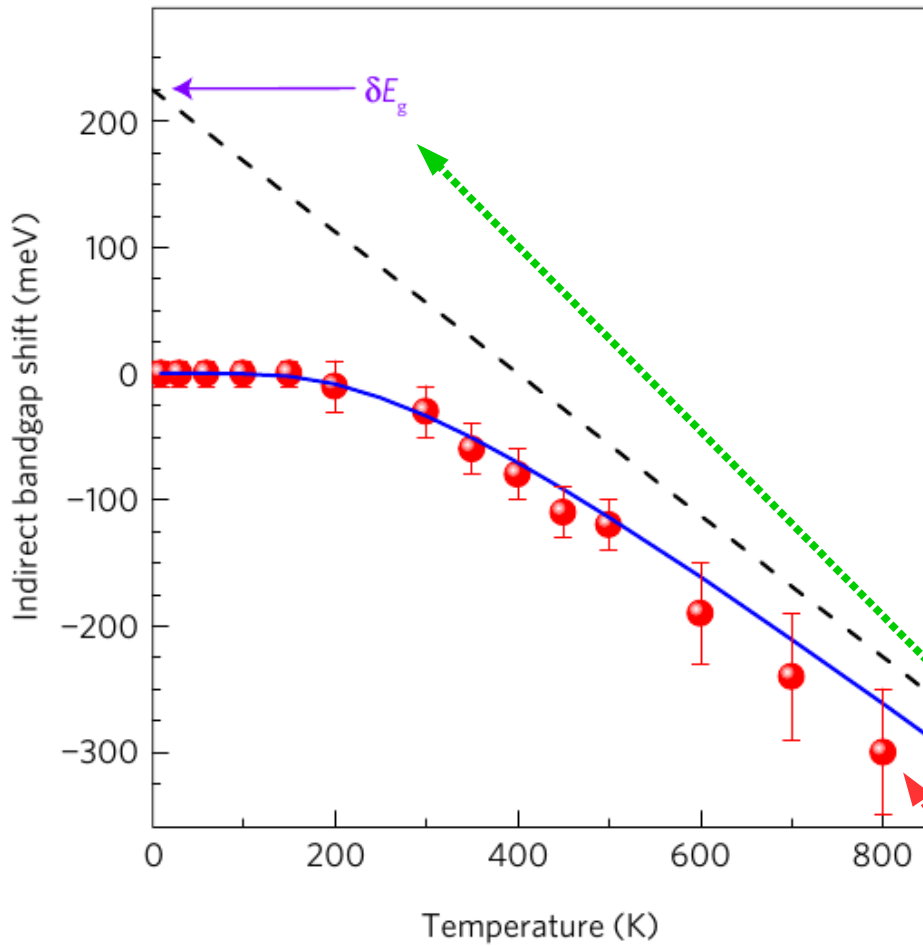
- low-energy Raman-active mode @ zone center
- no momentum change



Isotopic tuning of phonon replicas



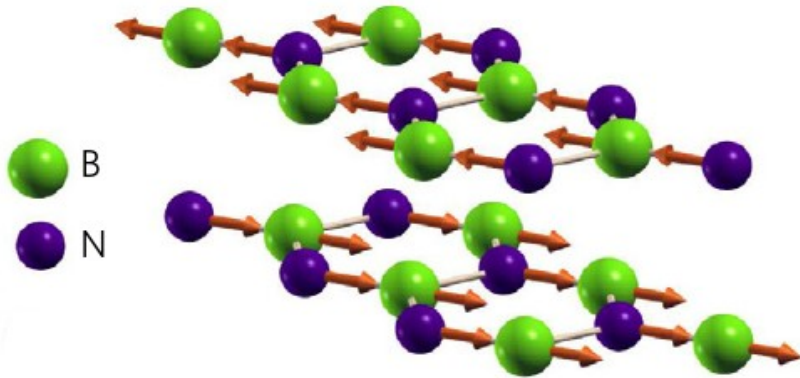
Bandgap renormalization



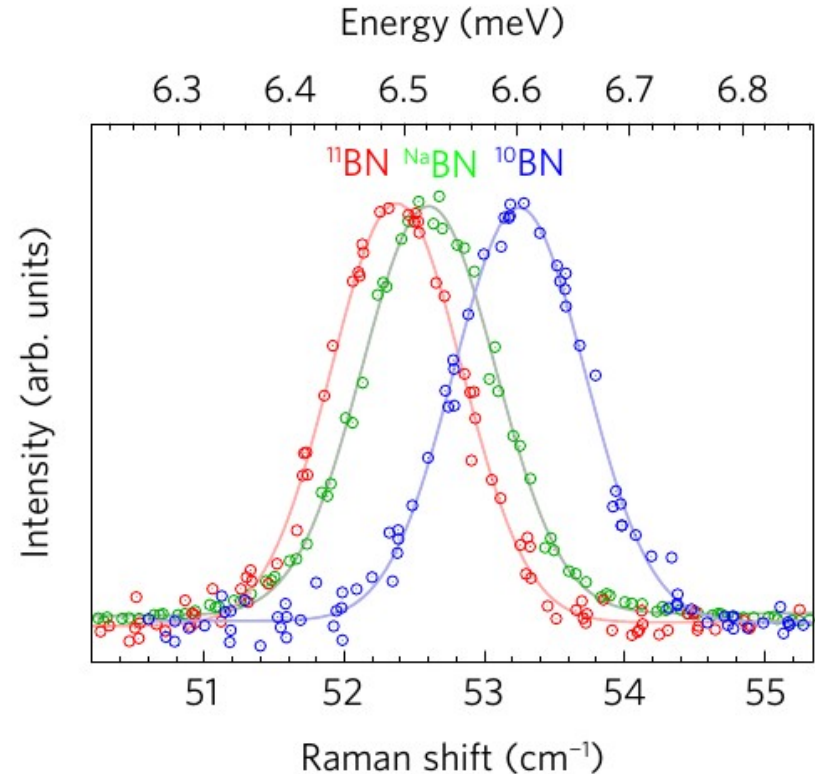
- ◆ Isotope-dependent bandgap renormalization δE_{gap}
- ◆ 6 meV change from ^{10}BN to ^{11}BN
- ◆ δE_{gap} in $^{\text{Na}}\text{BN}$ = single fitting parameter in isotopic tuning of phonon replicas
- ◆ 225 meV-value in fair agreement with temperature-dependent data from JAP 115, 53503 (2014)

Interlayer shear mode

a



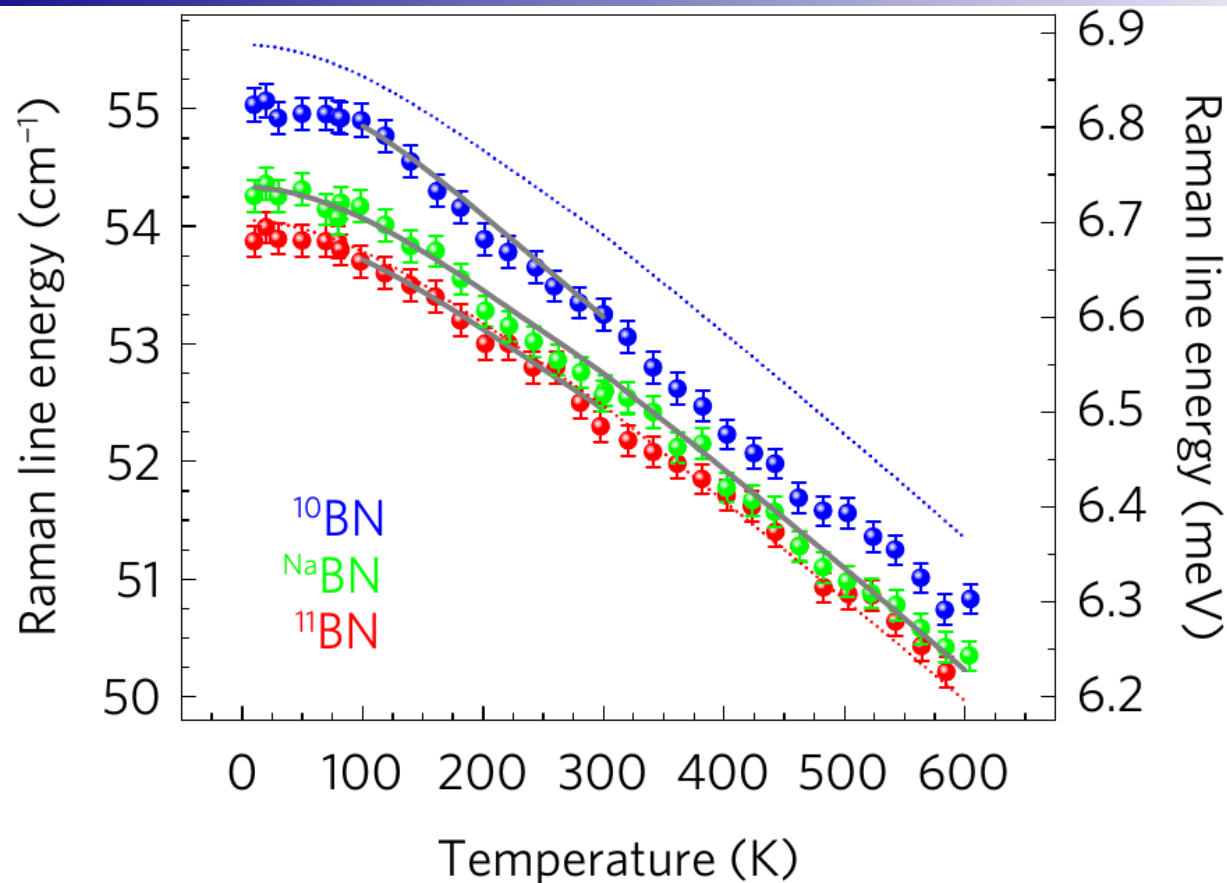
b



- ❖ Raman-active E_{2g} mode of low energy
- ❖ High-resolution Raman spectra around 50 cm^{-1} !

The lower the B mass, the higher the phonon energy : again, BUT...

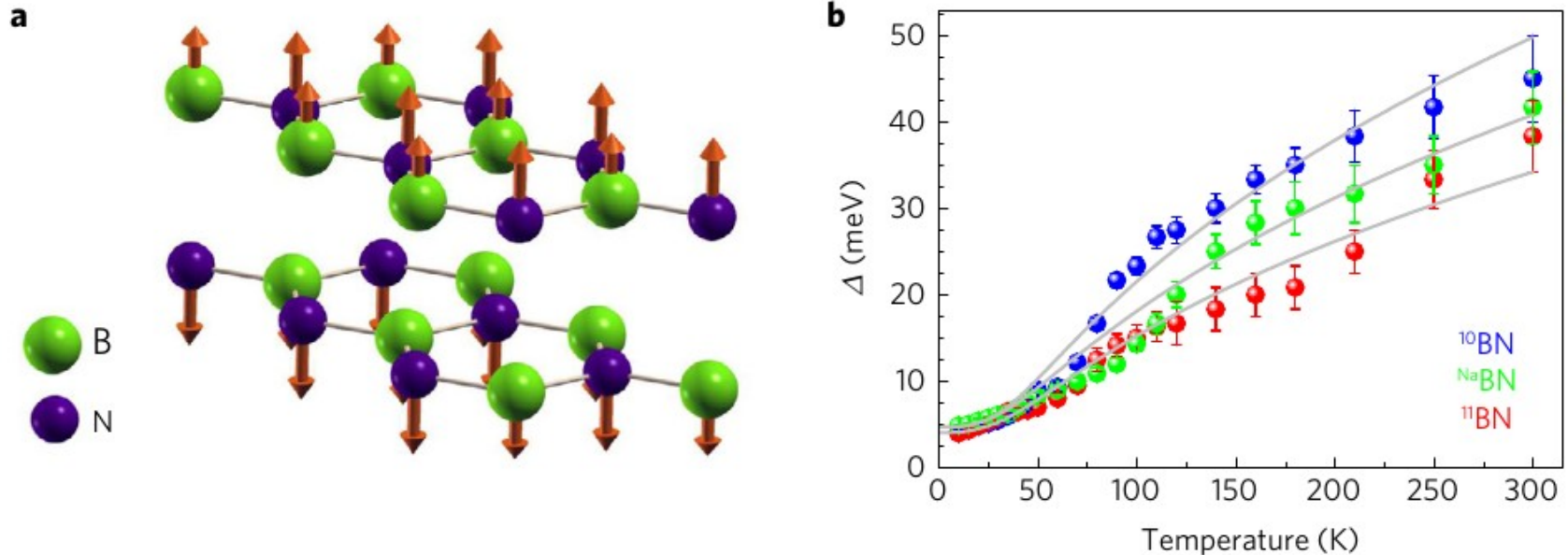
Isotope-dependent thermal shift



♦ **Isotope-dependent** temperature dependence !

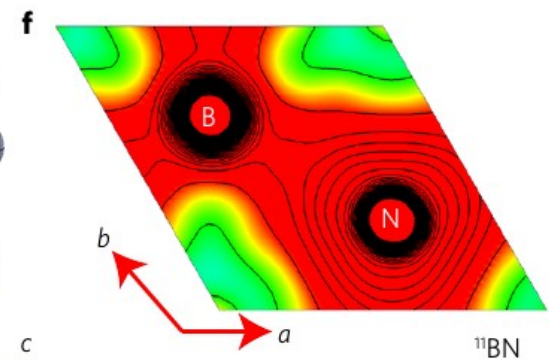
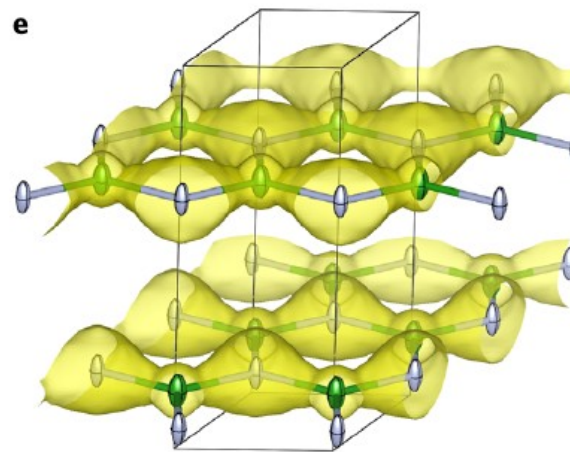
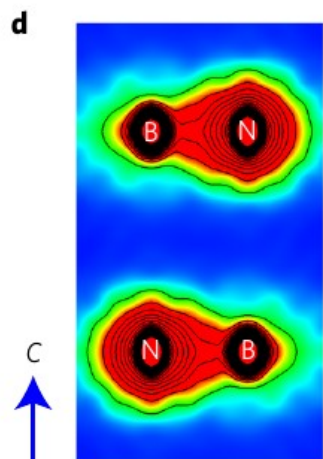
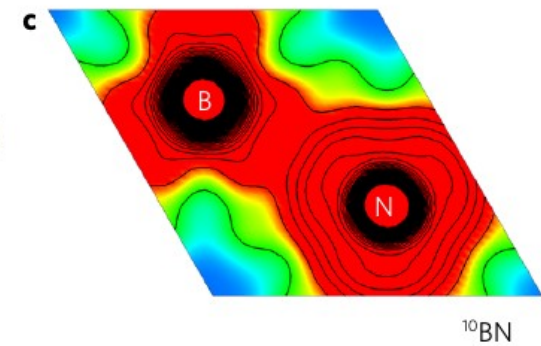
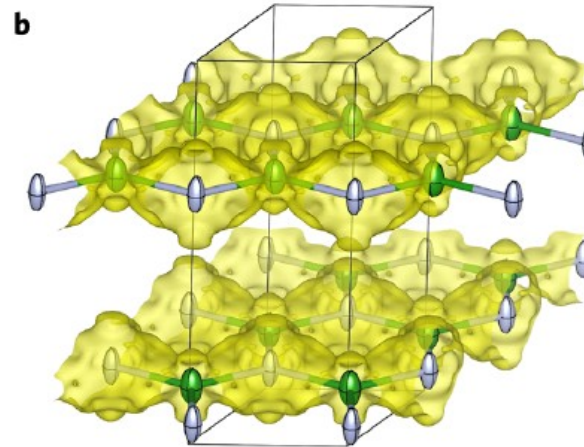
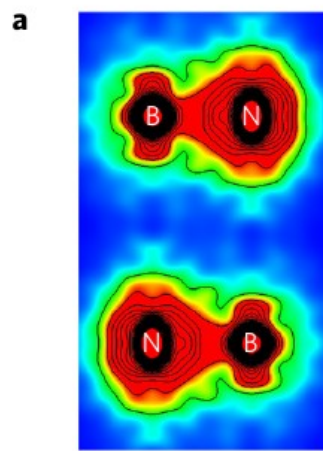
♦ $E \propto 1/c^p$ with c the interlayer distance ; p depends on isotope

Interlayer breathing mode



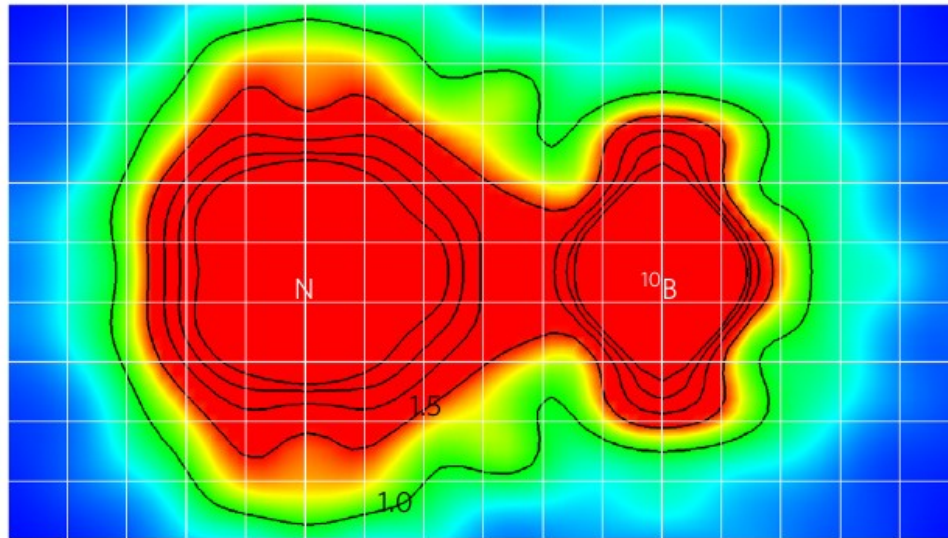
- ✦ IR and Raman inactive phonon : silent B_{1g} mode
- ✦ **Silent** but driving the PL thermal broadening
(PRB **95**, 201202 (2017))
- ✦ **Isotope-dependent** phonon broadening

X-ray diffraction experiments

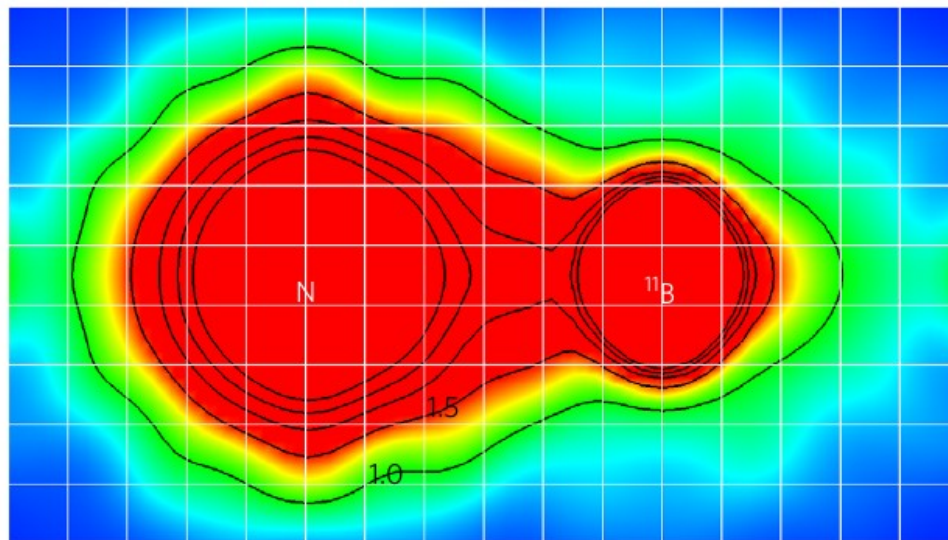


Isotope-dependent electronic distribution

^{10}BN

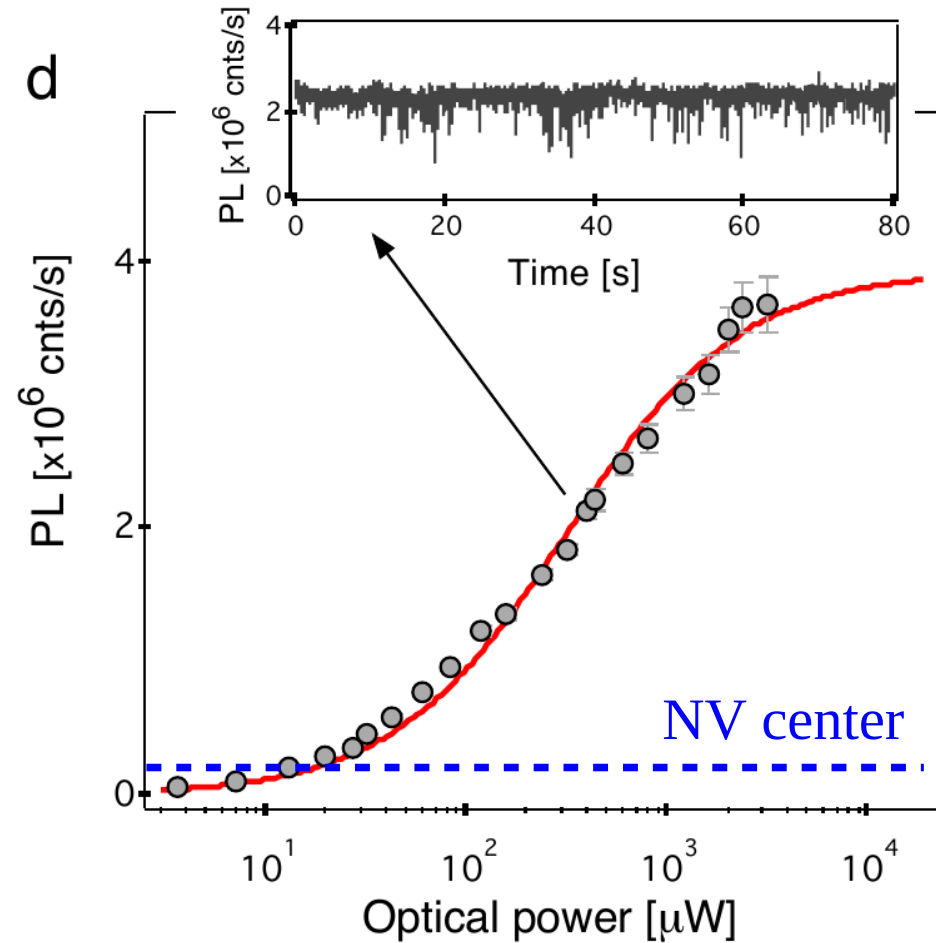
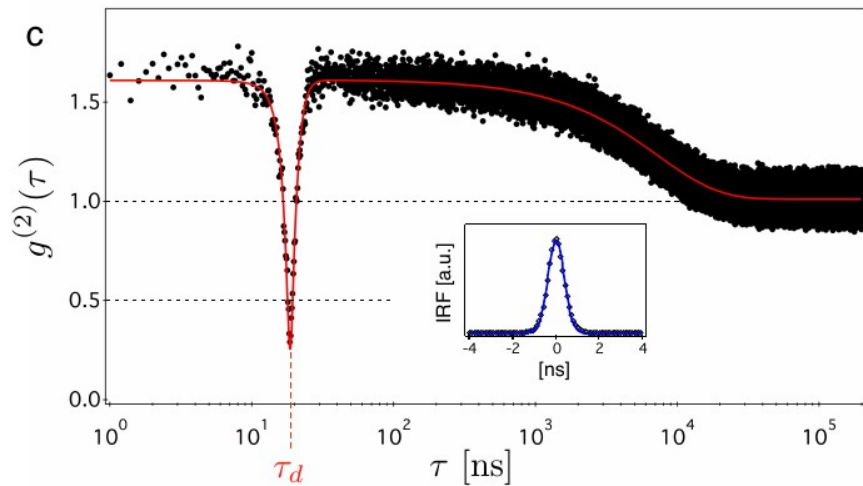
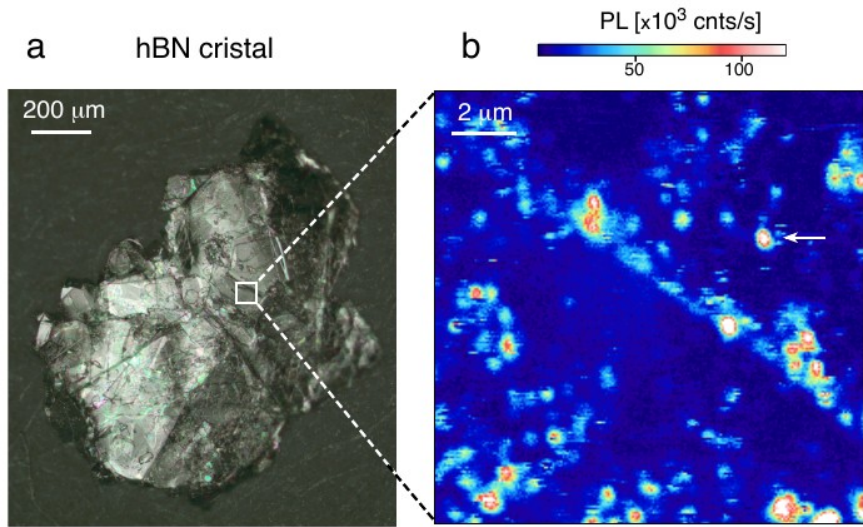


^{11}BN



c-axis

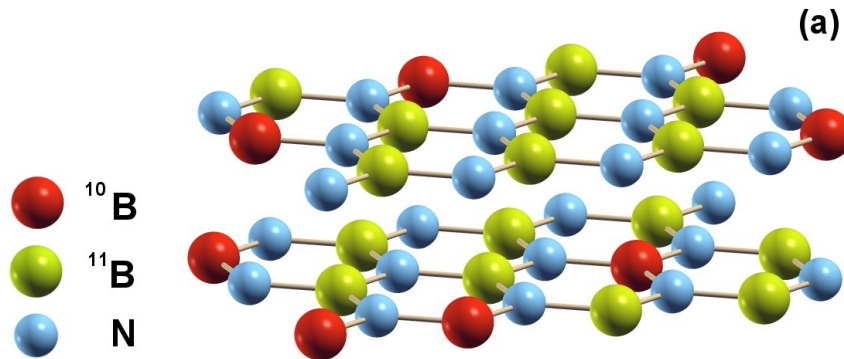
Point defects in hBN as bright single-photon sources



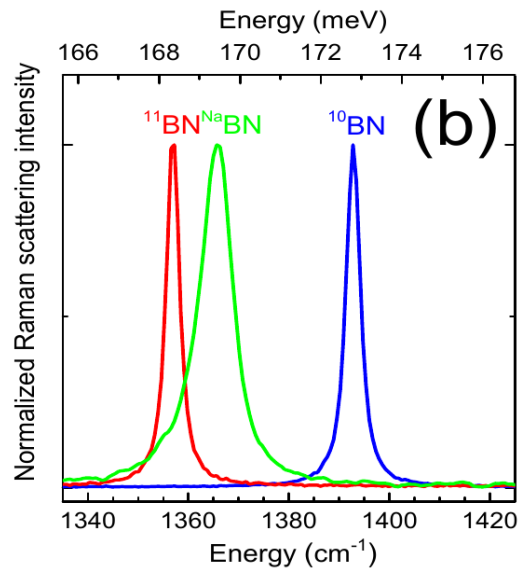
Phys. Rev. B **94**, 121405(R) (2016)

Isotopic purification

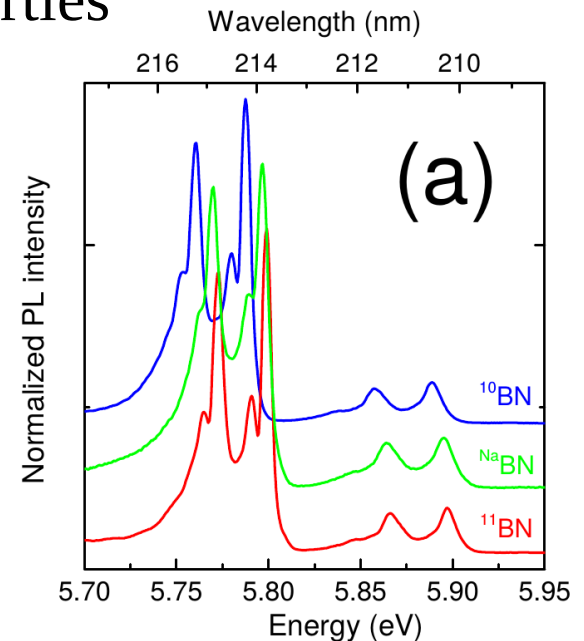
- Isotopic mixture



- Impact on vibrational and electronic properties



submitted for publication



Applications

Powder



« white graphite »

- › many industrial applications
- › solid lubricant, thermal coating, additive in plastics, cosmetics...

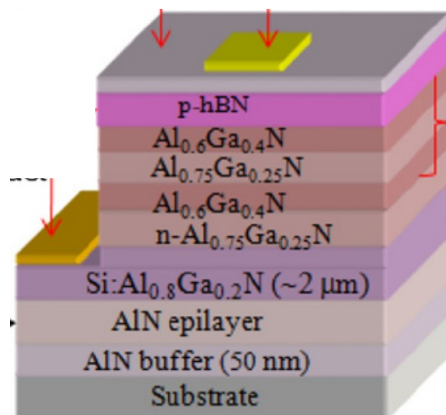
Polycrystals



Watanabe, Nature Mater. 3, 404 (2004)

- › deep-UV light emission
- › graphene substrate
- › Van der Waals heterostructures

Epilayers



Jiang, Semicond. Sci. Technol. 29, 084003 (2014)

- › growth by MOCVD + MBE
- › deep-UV light emission
- › UV opto-electronics (transparent p-contact, mechanical release layer)

hBN in the industry

SAINT-GOBAIN



BORON NITRIDE

POWDERS

MACHINABLE CERAMICS

COATINGS

PDS PRODUCTS

MARKETS

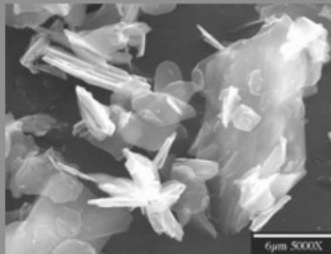
RESOURCE CENTER

Saint-Gobain Boron Nitride

A global leader in the development and production of Boron Nitride solutions with a focus on technical support and innovation.



Boron Nitride Products



The ideal material solution.

Saint-Gobain Ceramic Materials Boron Nitride products is a renowned leader in producing a full spectrum of Boron Nitride material solutions for a variety of industries, including [aerospace](#), [automotive](#), [ceramic manufacturing](#), [electronics](#), [semiconductors](#), [metal working](#) and [cosmetics](#).

Boron Nitride products are manufactured as [powders](#), [solid finished components and blanks](#), [aqueous coatings](#), as well as [solid source dopants](#). Custom end use products are a specialty of ours, including custom solid shapes, powder formulations and others. We can work with you from initial development to final implementation of your application, and at any step in between.



hBN in the industry

SAINT-GOBAIN



BORON NITRIDE

POWDERS

MACHINABLE CERAMICS

COATINGS

PDS PRODUCTS

MARKETS

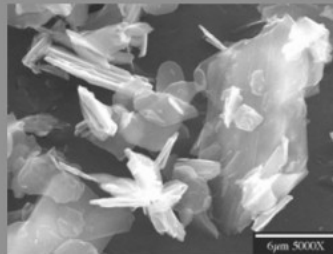
RESOURCE CENTER

Saint-Gobain Boron Nitride

A global leader in the development and production of Boron Nitride solutions with a focus on technical support and innovation.



Boron Nitride Products



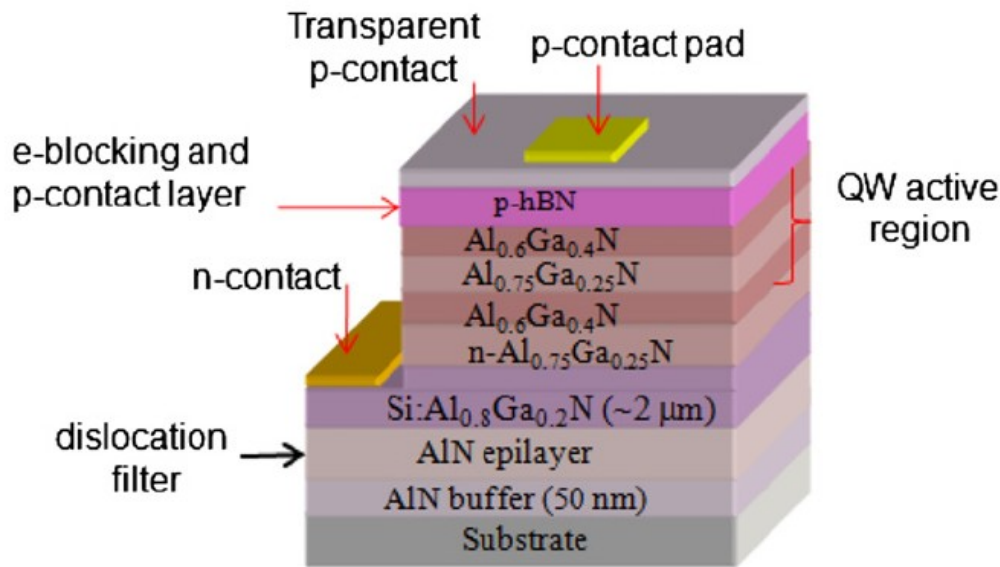
The ideal material solution.

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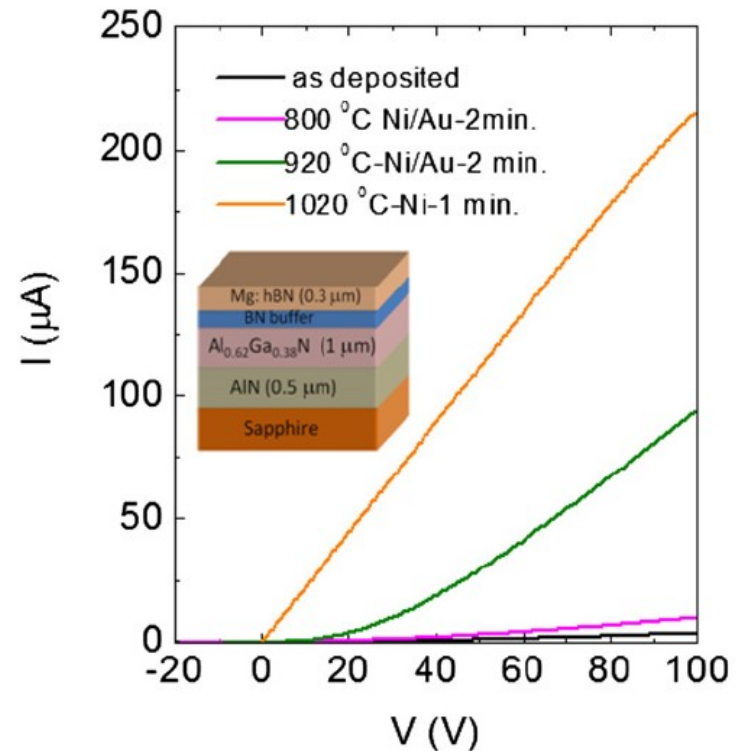
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Highly conductive p-type hBN layer

Deep-UV LED device

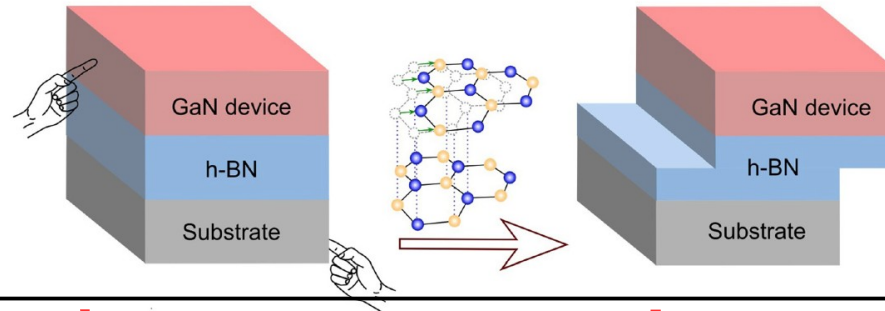


p-BN:Mg /n-AlGaN structure

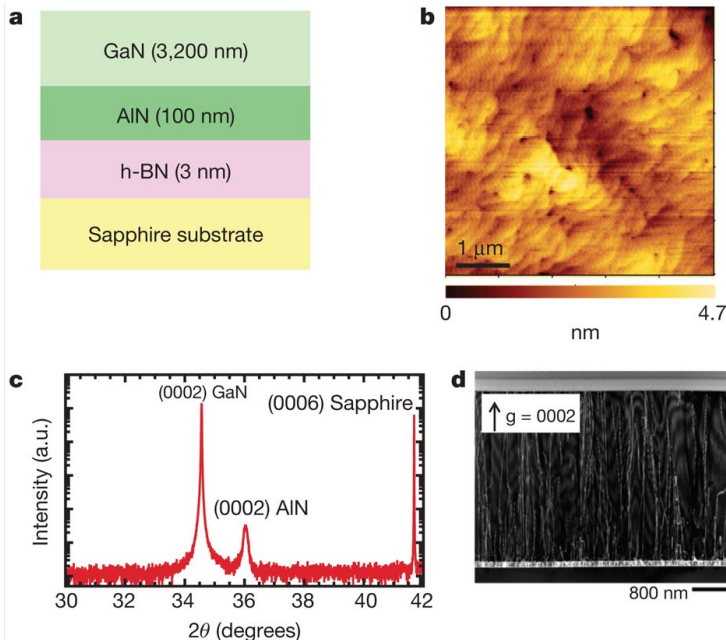


Jiang, Semicond. Sci. Technol. 29, 084003 (2014)

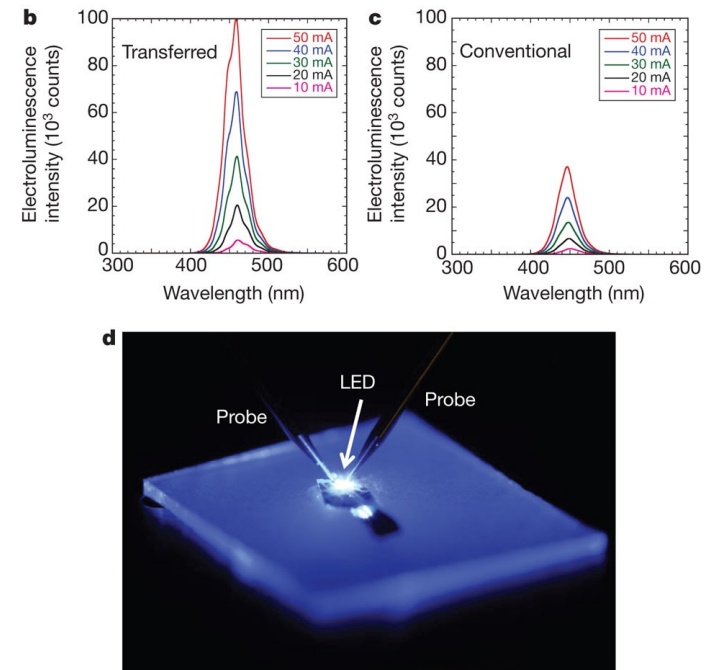
hBN as release layer for mechanical transfer



Growth of AlN on hBN



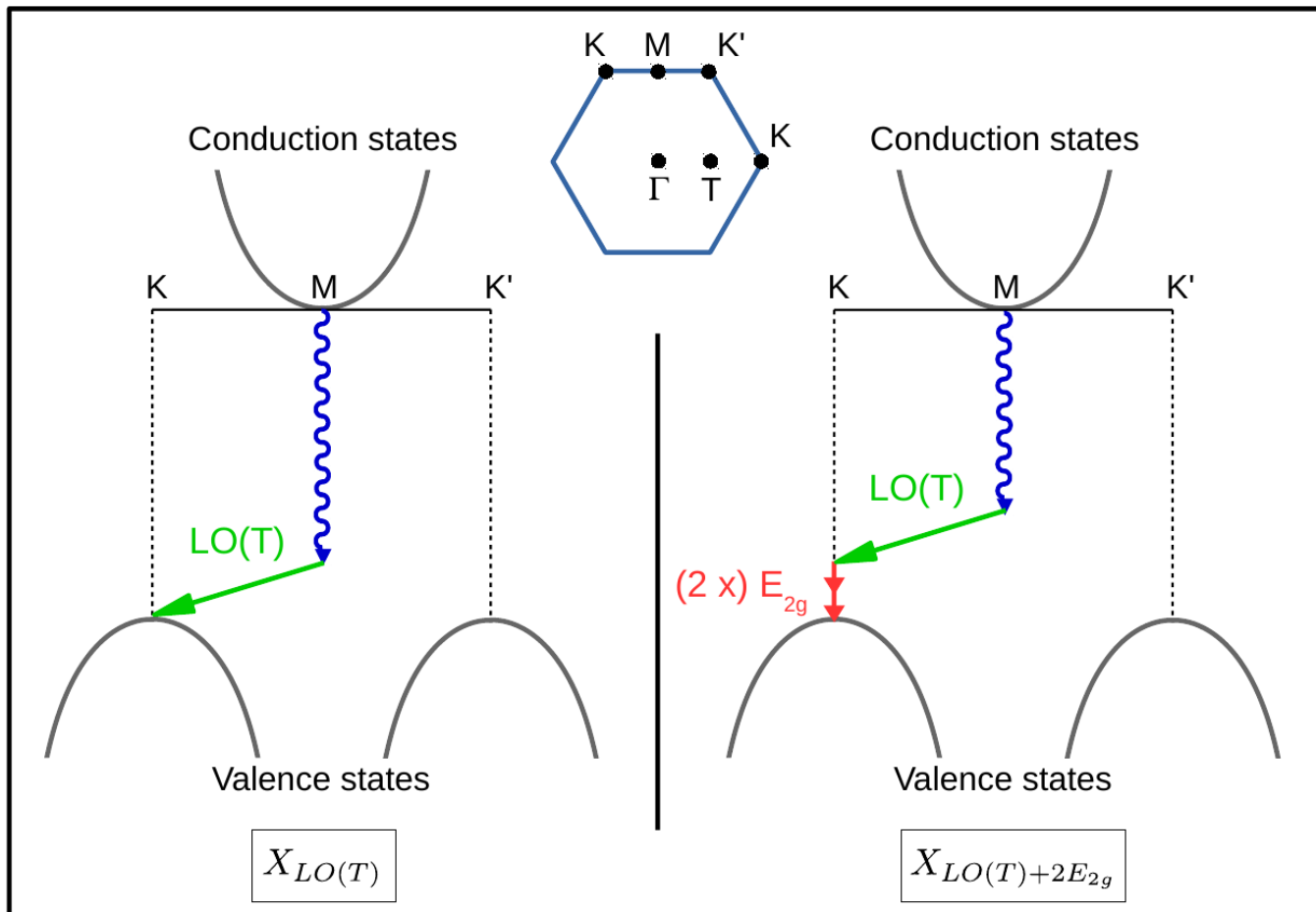
Multi-quantum well LED



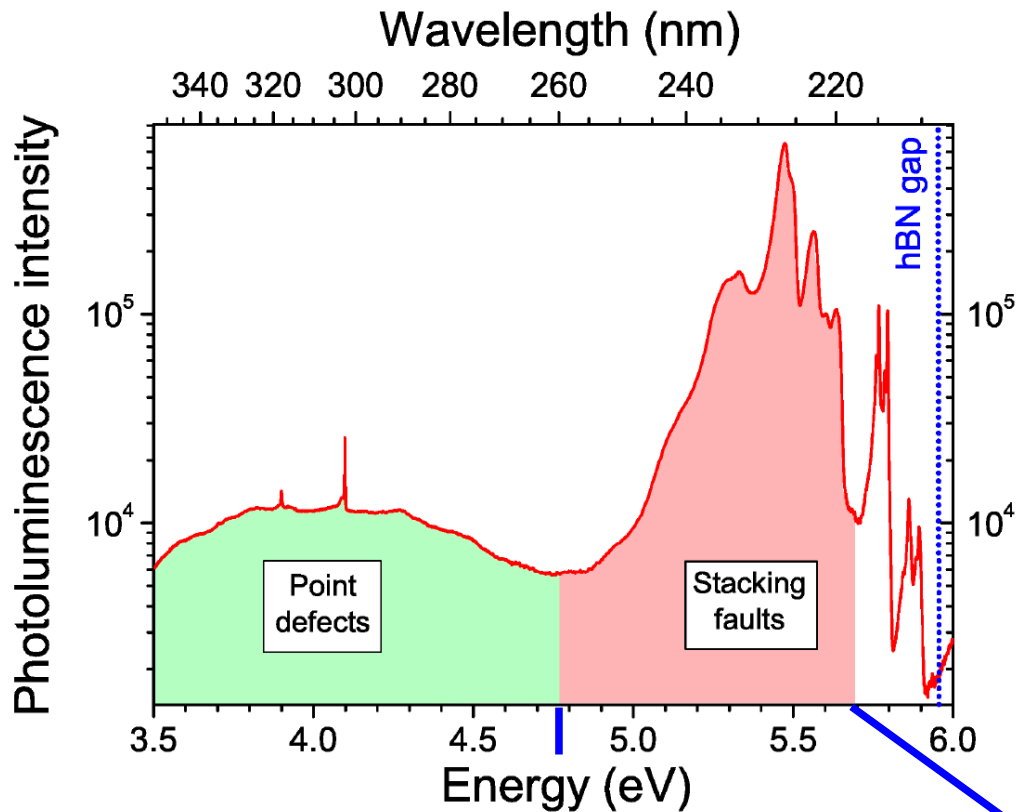
Kobayashi, Nature 484, 223 (2012)

High-order phonon-assisted processes

- low-energy Raman-active mode @ zone center
- no momentum change



Optical properties



Phonon replicas above 5.7 eV

Indirect bandgap

Nature Photonics **10**, 262 (2016)

Phonons & anharmonicity

PRB **94**, 155435 (2016)

Single-photon source
PRB **94**, 121405(R) (2016)

poster 1.160
by P. Vuong

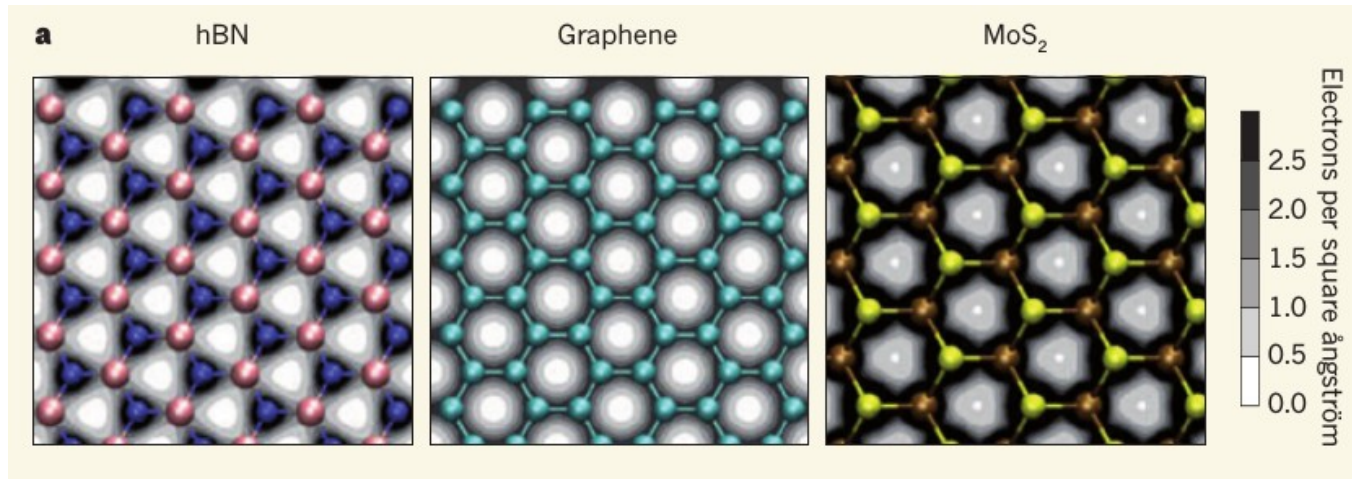
Phonon-photon mapping
PRL **117**, 097402 (2016)

Intervalley scattering
PRB **10**, 262 (2016)

Direct vs indirect bandgaps

- 2D crystals

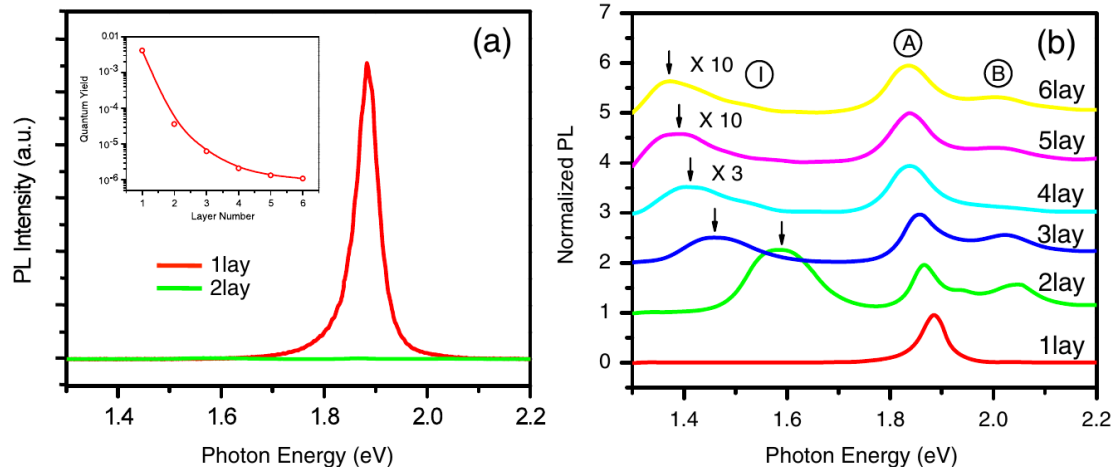
Geim, Nature 499, 419 (2013)



- Monolayer = direct bandgap

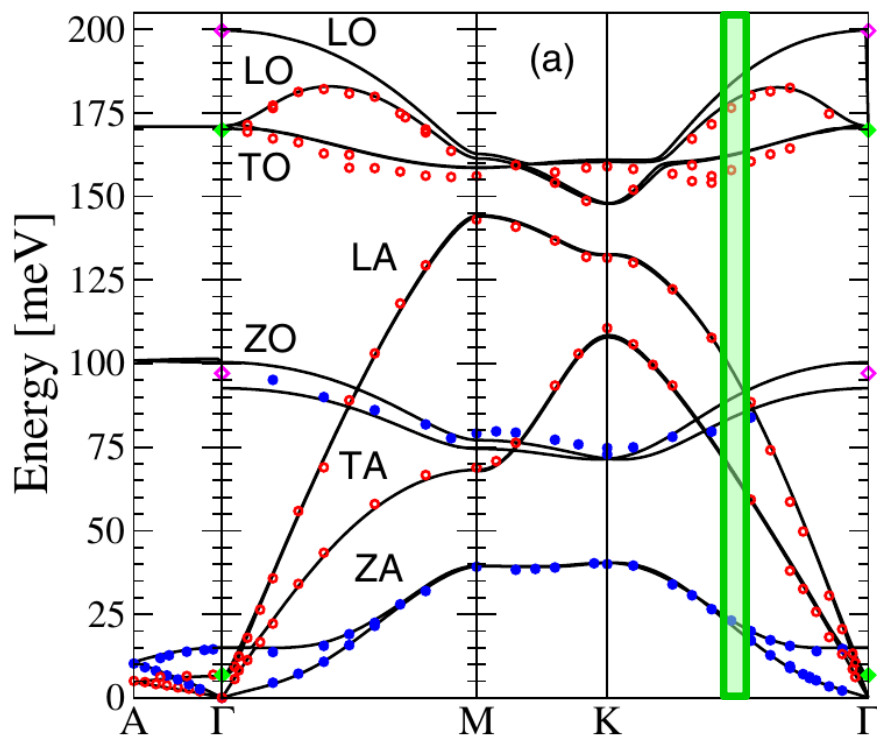
Mak, PRL 105, 136805 (2010)

MoS₂

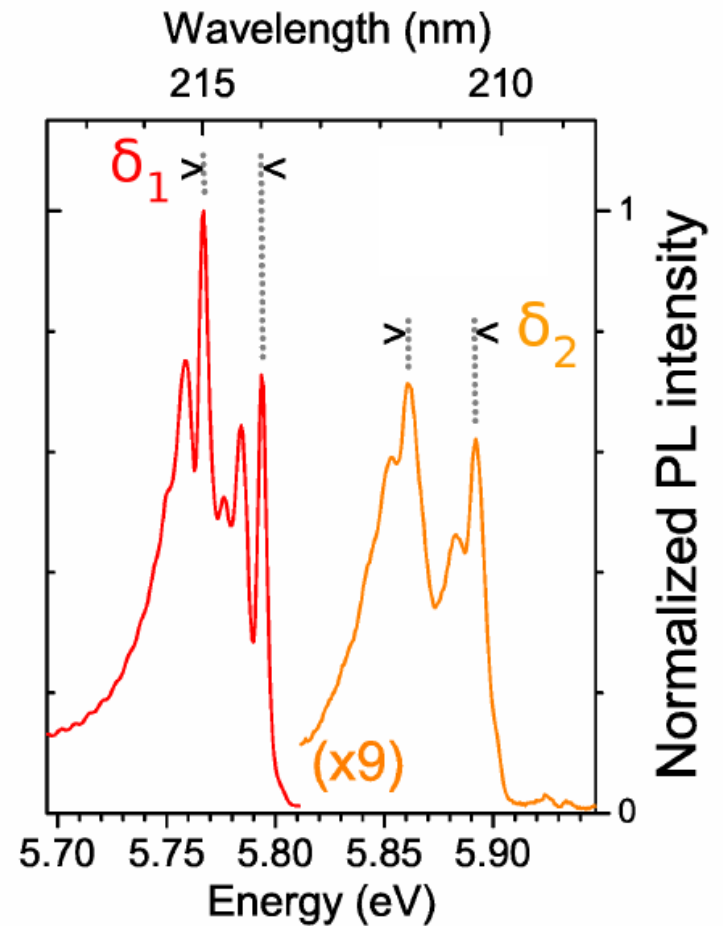


Phonon group velocity & multiplet visibility

Phonon band-structure



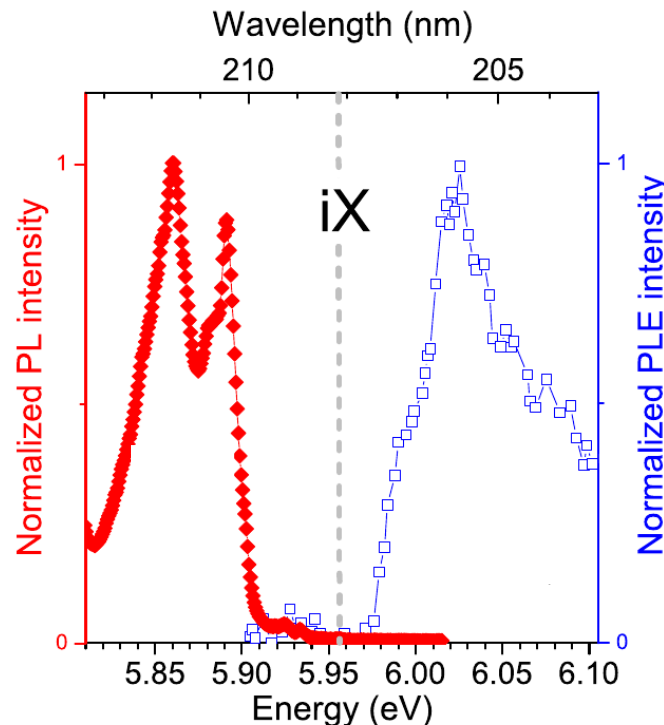
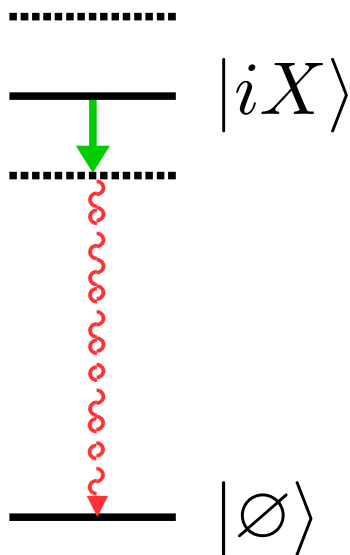
Serrano, PRL 98, 095503 (2007)



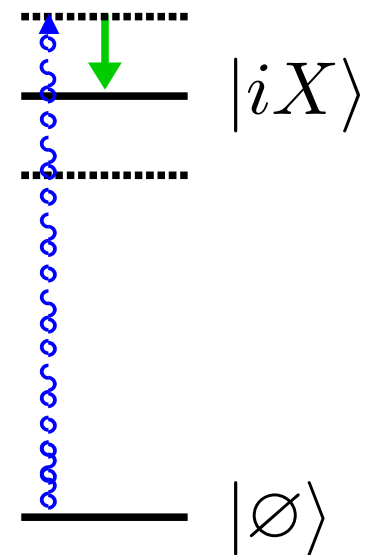
Mirror symmetry between emission and absorption

- Phonon-assisted **recombination** = **red-shifted** by phonon energy
- Phonon-assisted **absorption** = **blue-shifted** by phonon energy

Phonon-assisted recombination

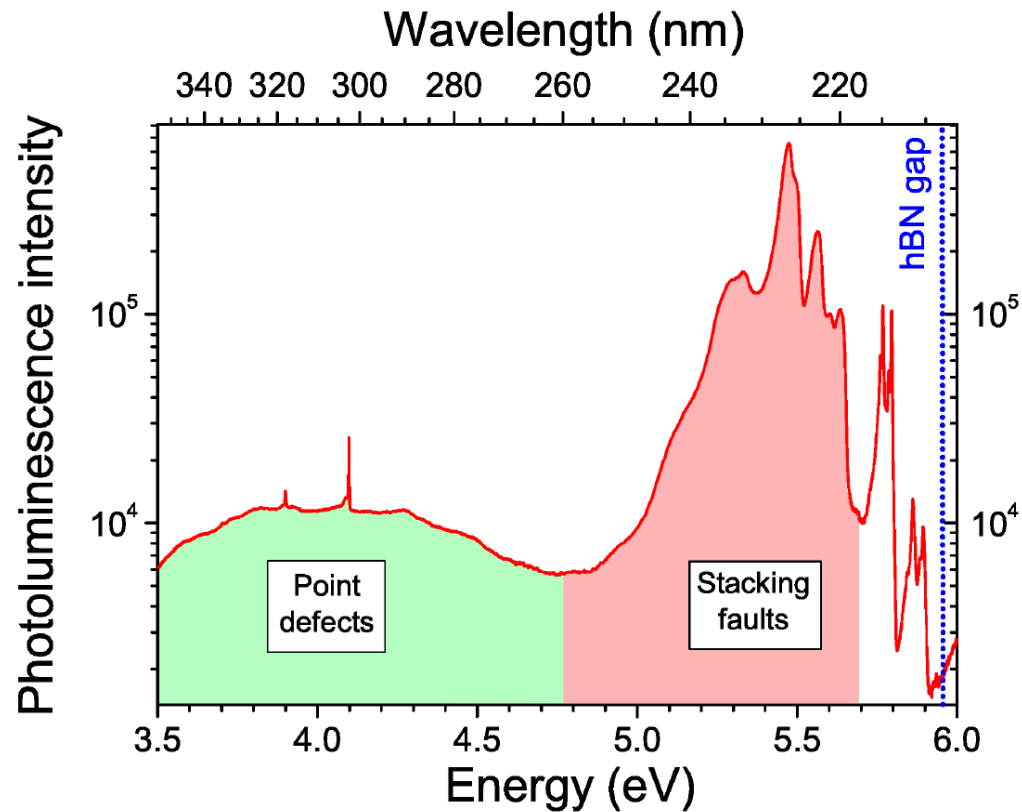


Phonon-assisted absorption



PLE from [Museum, pss RRL 5, 214 \(2011\)](#)

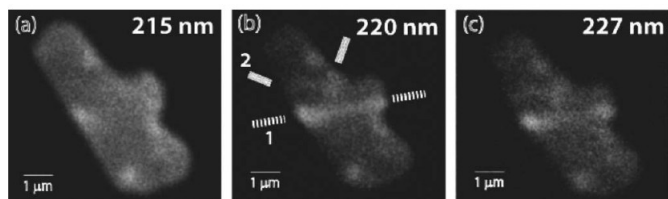
Outline



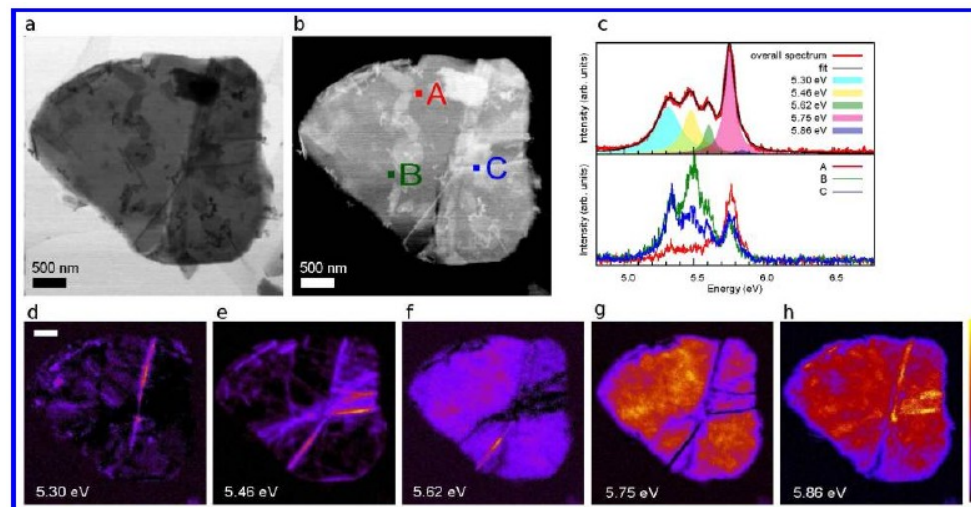
- Phonon replicas (at the band edge)
- Intervalley scattering (stacking faults)
- Phonon-photon mapping (point defects)

Spatially-resolved cathodoluminescence

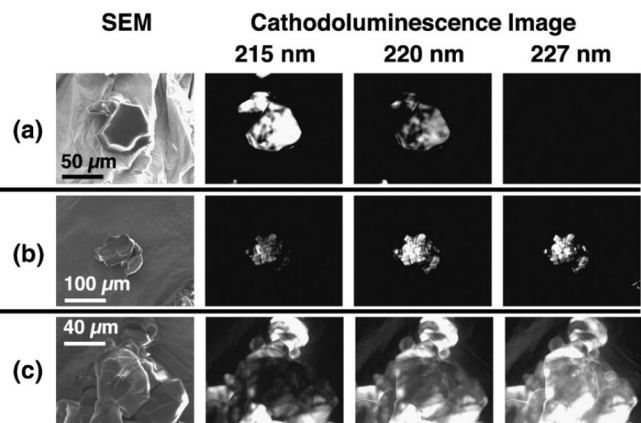
localization at defects of luminescence below 5.7 eV



Jaffrenou, JAP 102, 116102 (2007)

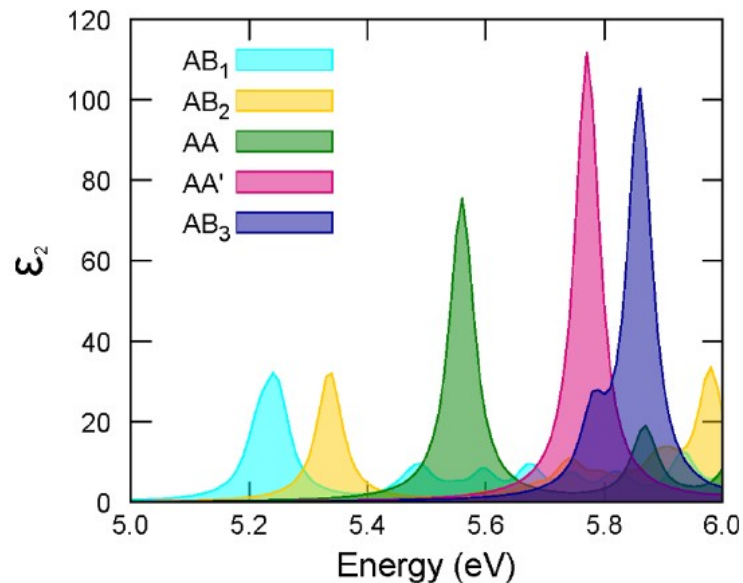
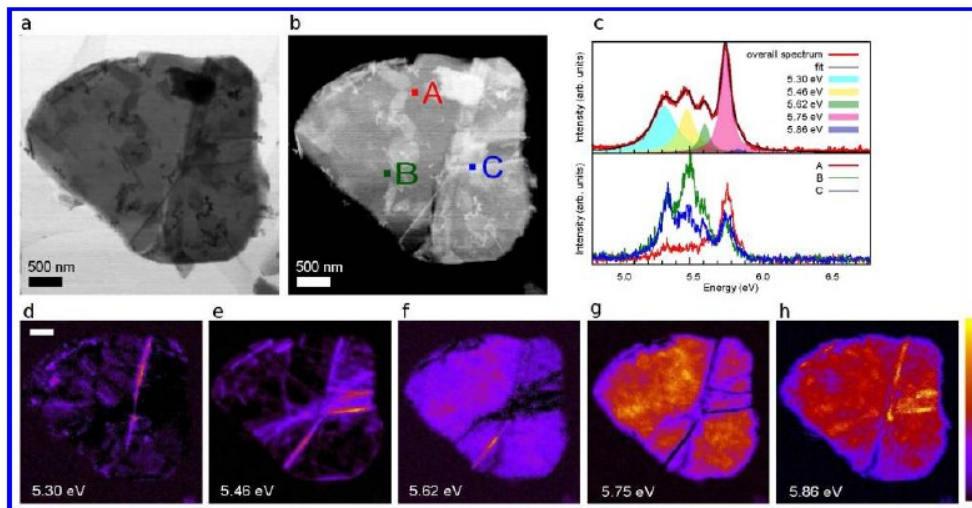


Bourrelier, ACS Photonics 1, 857 (2014)

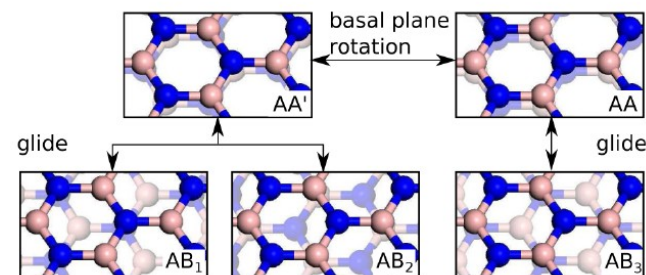
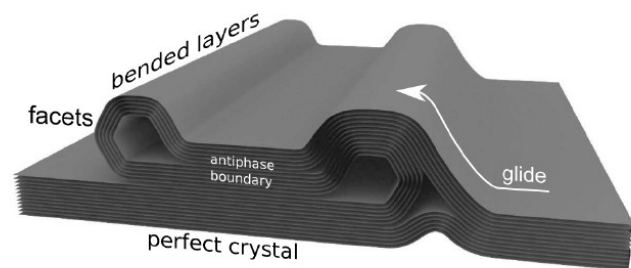


Watanabe, Diam. Rel. Mat. 20 849 (2011)

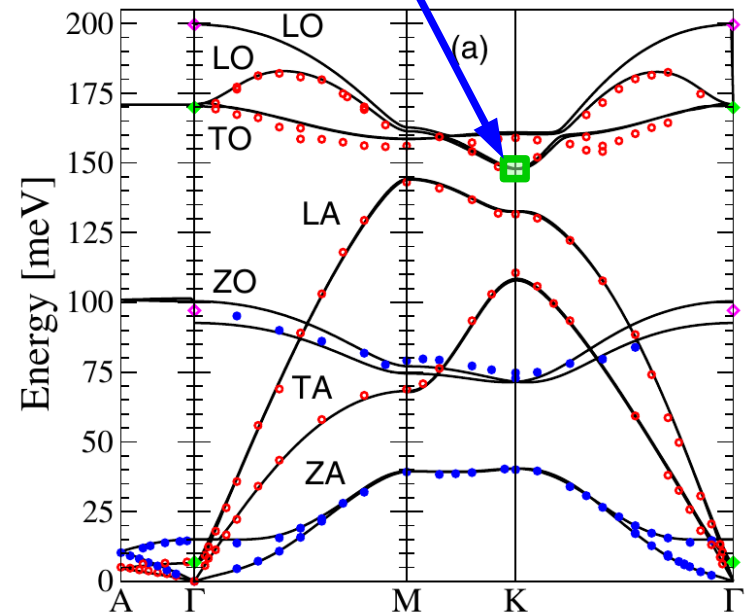
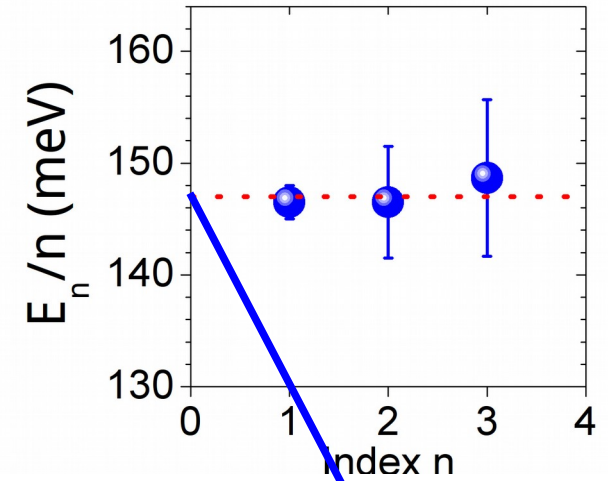
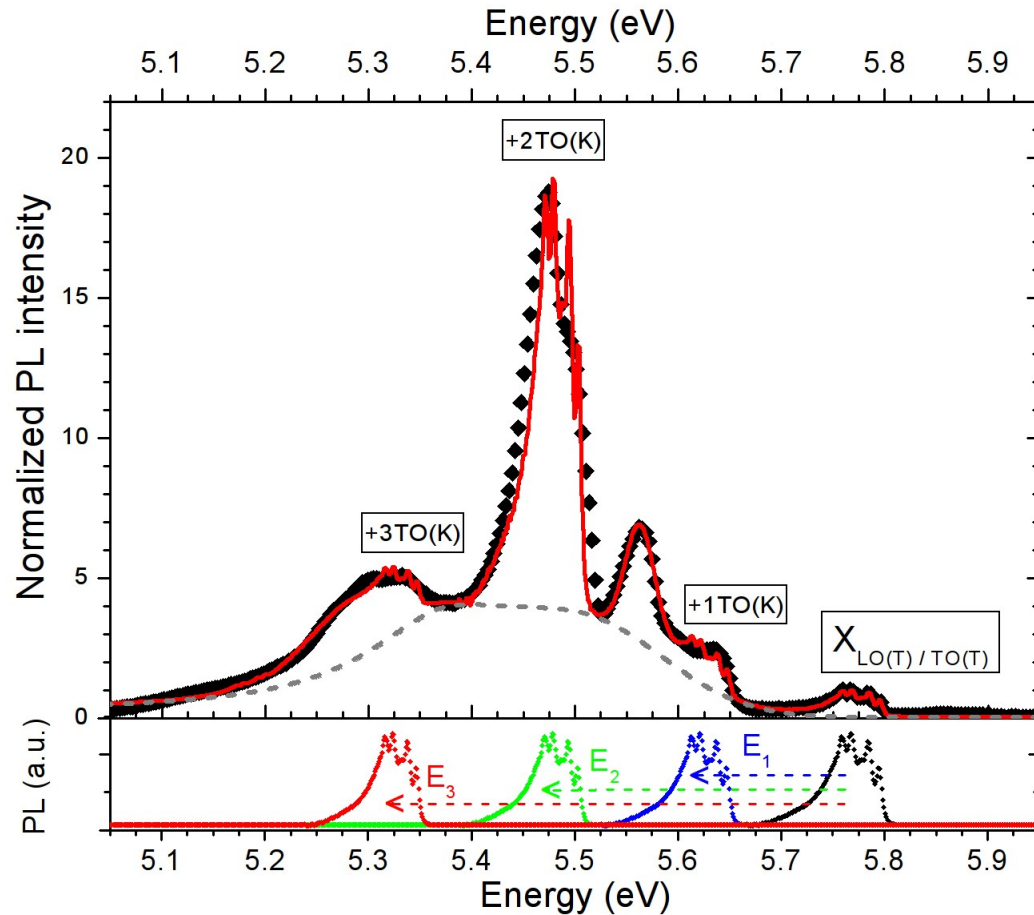
Defect-related emission band



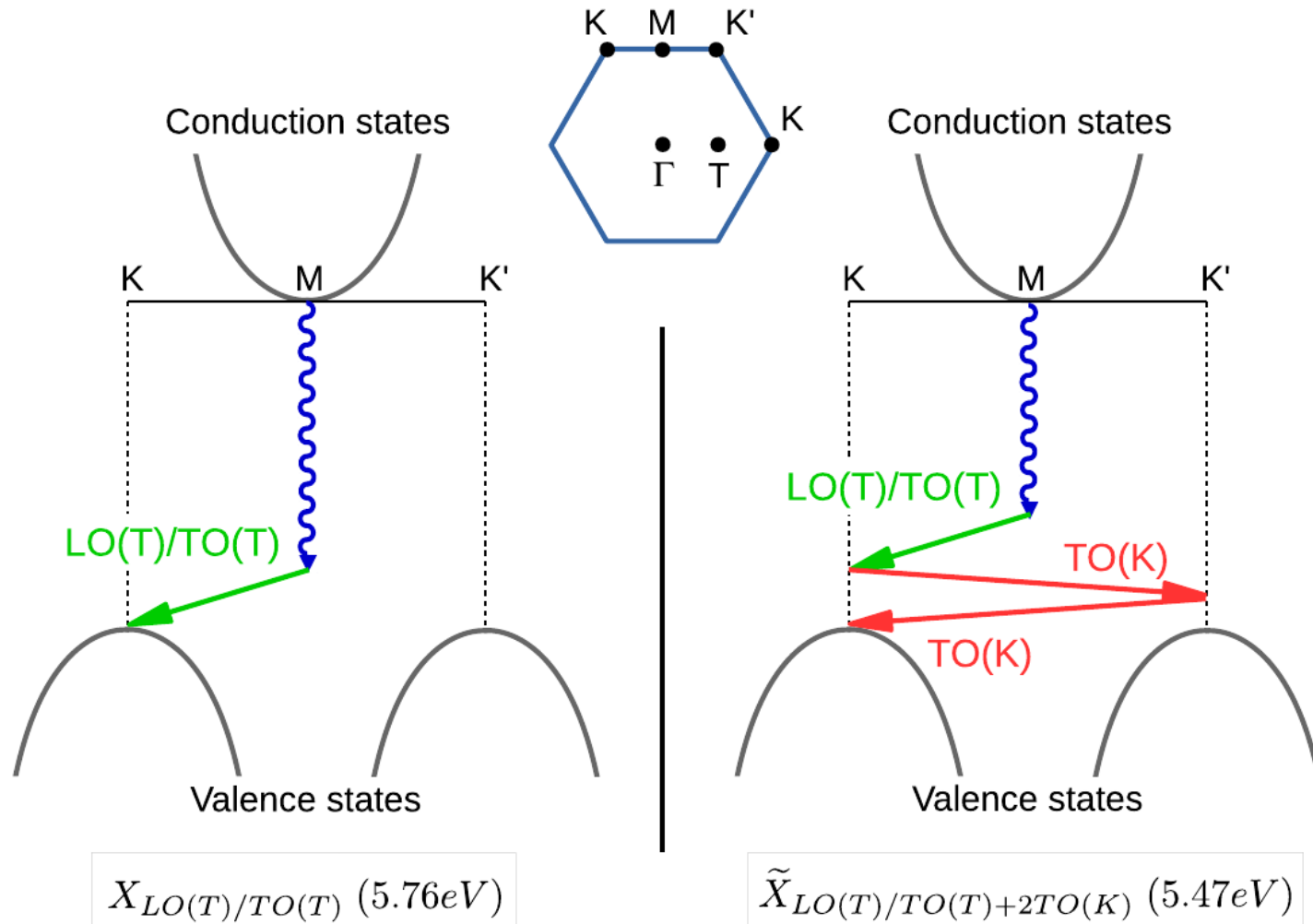
Bourrelier, ACS Photonics 1, 857 (2014)



Phonon replicas...again



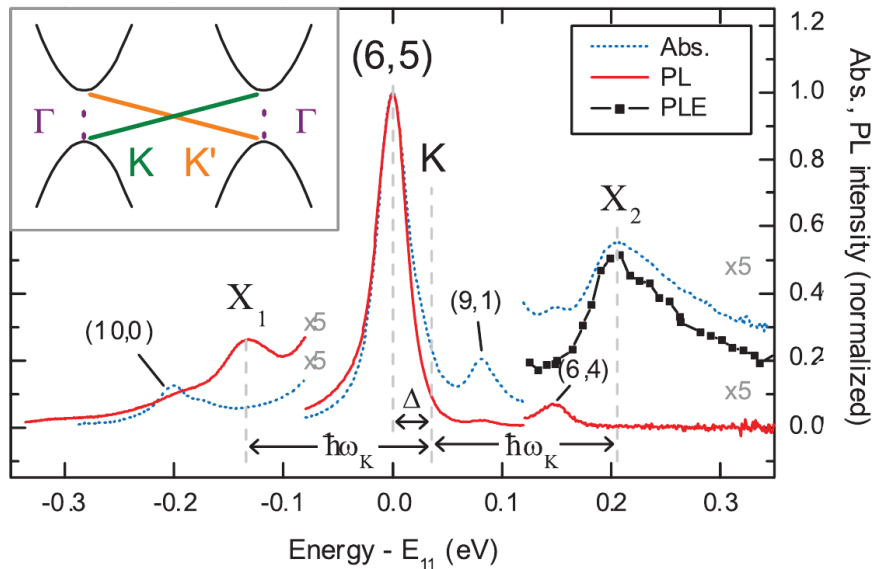
Intervalley scattering



TO(K)-assisted intervalley scattering

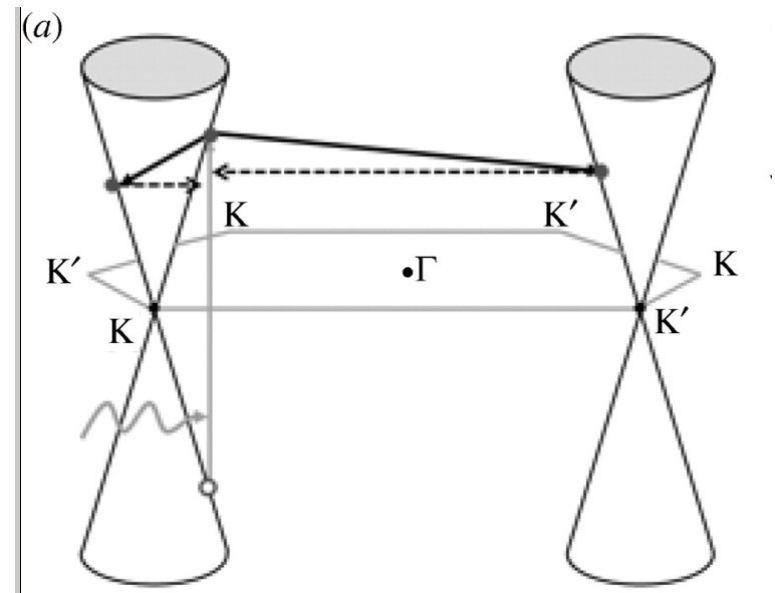
same TO(K) phonon found in two similar systems

Carbon nanotubes
(emission of valley-dark exciton)



Torrens, PRL 101, 157401 (2008)

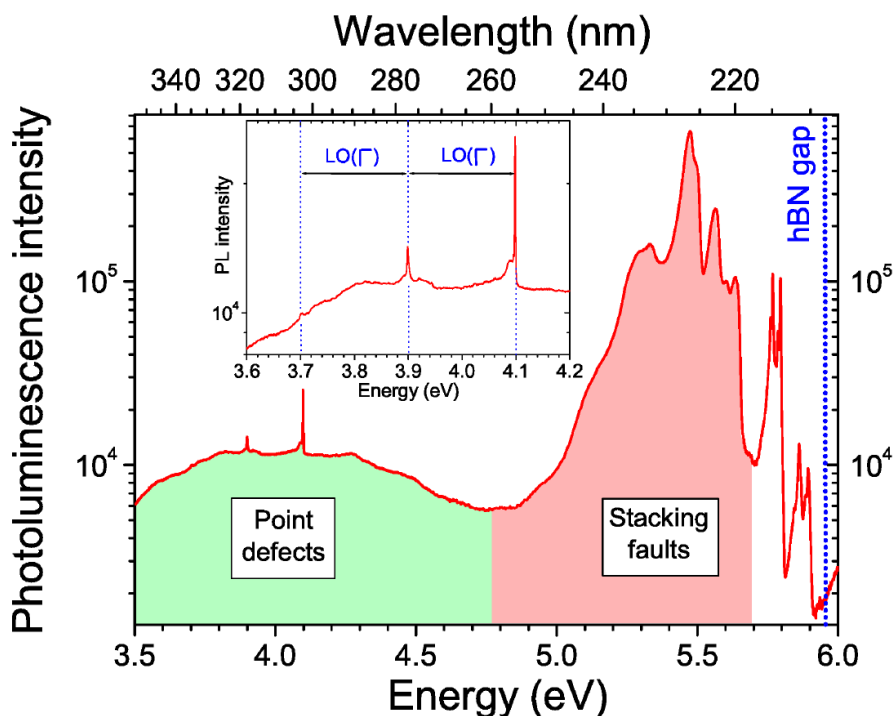
Graphene
(Raman D band)



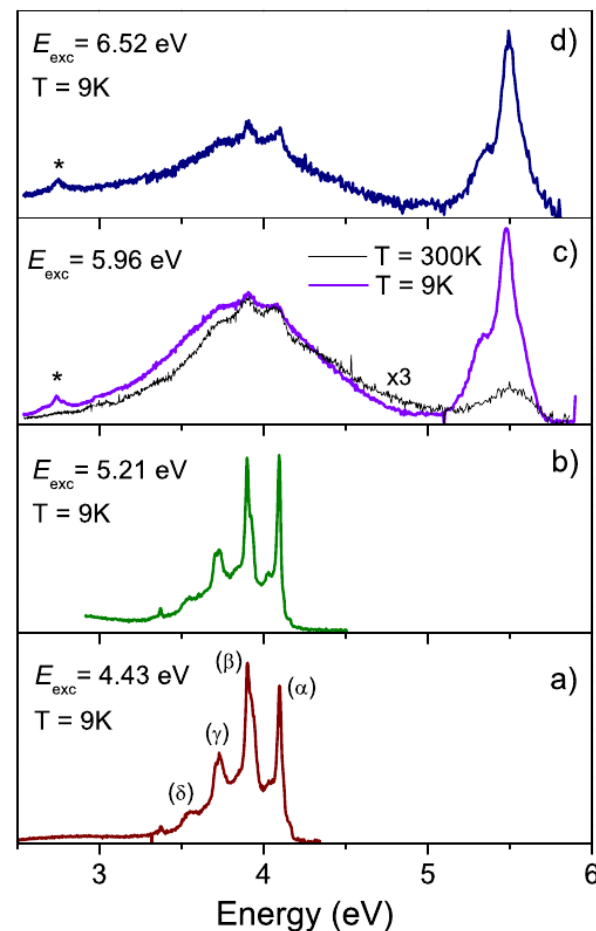
Thomsen, PRL 85, 5214 (2000)

Excitation spectroscopy

above bandgap excitation

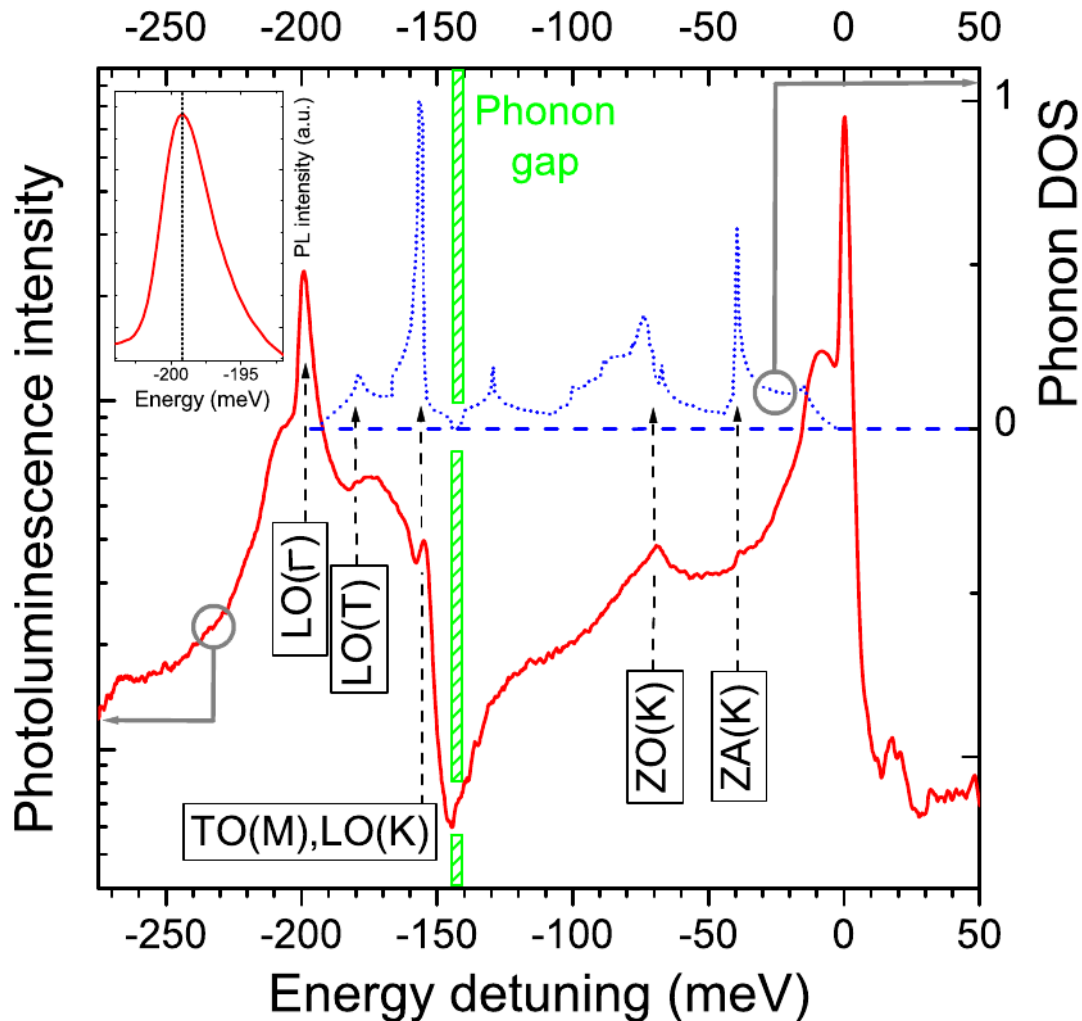


below bandgap excitation



Museur, PRB 78, 155204 (2008)

PL spectrum vs phonon DOS

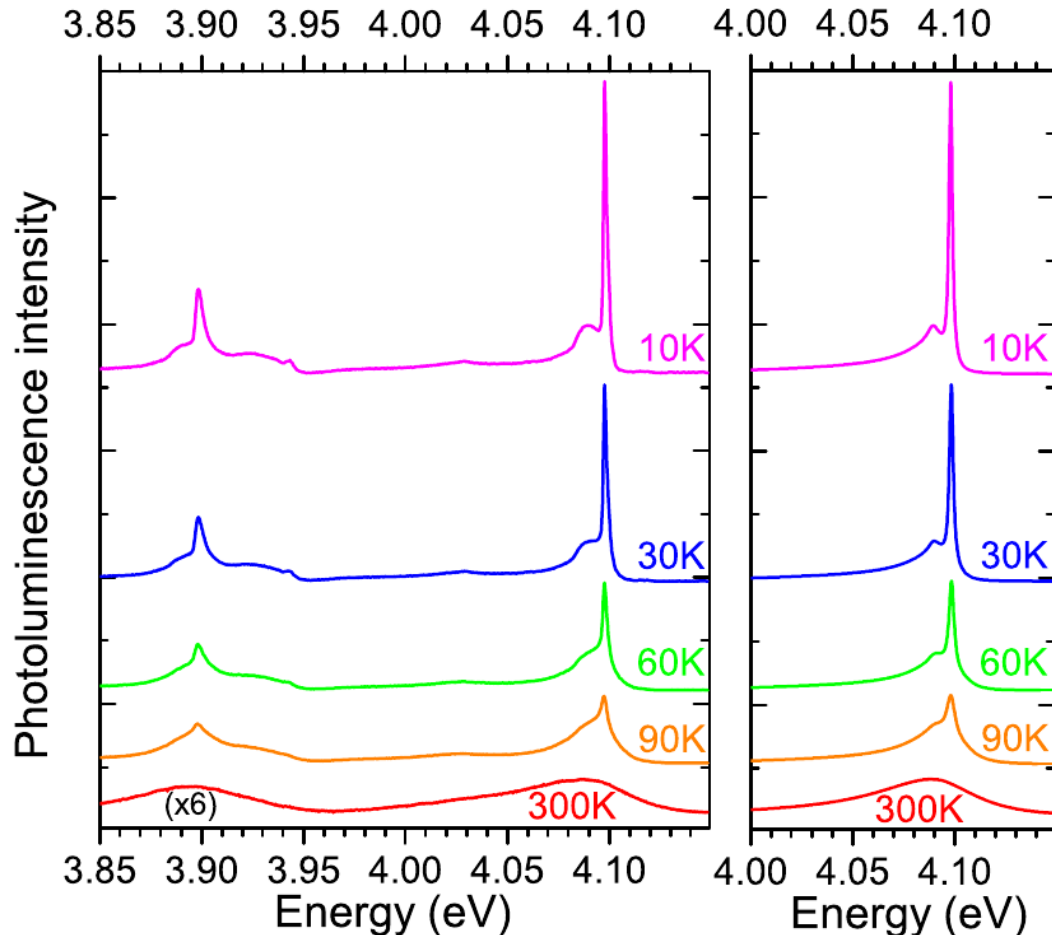


- ◆ excitation @ 4.6 eV
- ◆ no PL signal @ phonon gap
- ◆ observation of **phonon DOS extrema** in PL spectrum
- ◆ one-phonon processes dominant at 10K

Acoustic phonon sidebands

experiments

theory



- ◆ non-perturbative calculations of LA phonon sidebands
- ◆ excellent agreement from 10K to room temperature
- ◆ deformation potential $D \sim 11$ eV
- ◆ defect size ~ 2 Å

White graphite

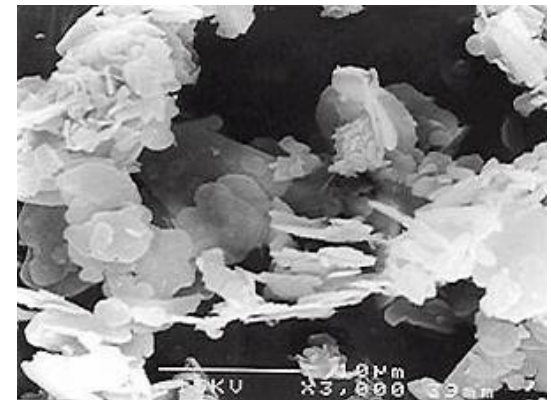
an old story ...

a versatile material displaying :

- ◆ chemical inertness
- ◆ low dielectric constant
- ◆ thermal stability

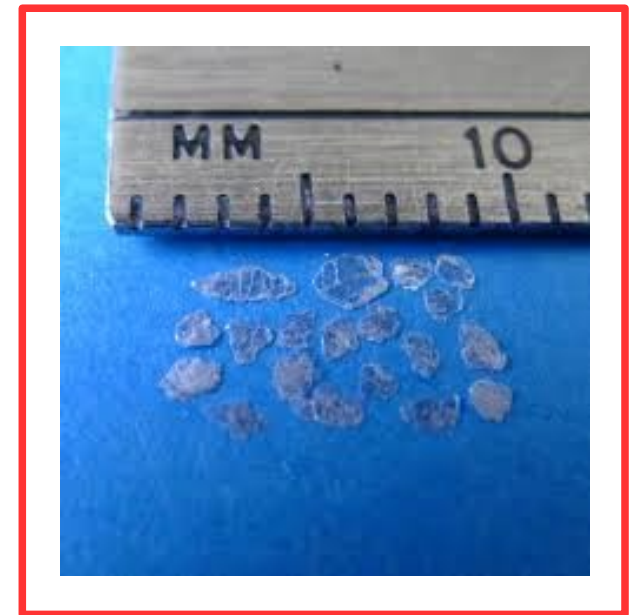
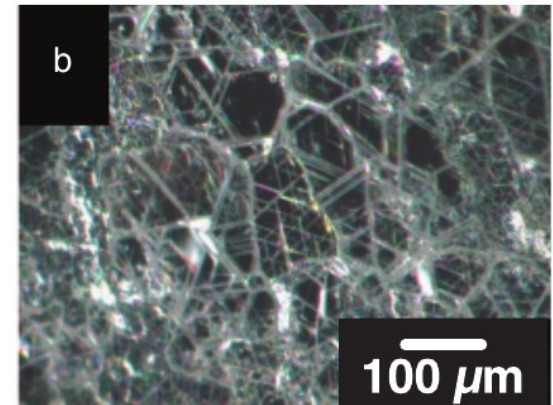
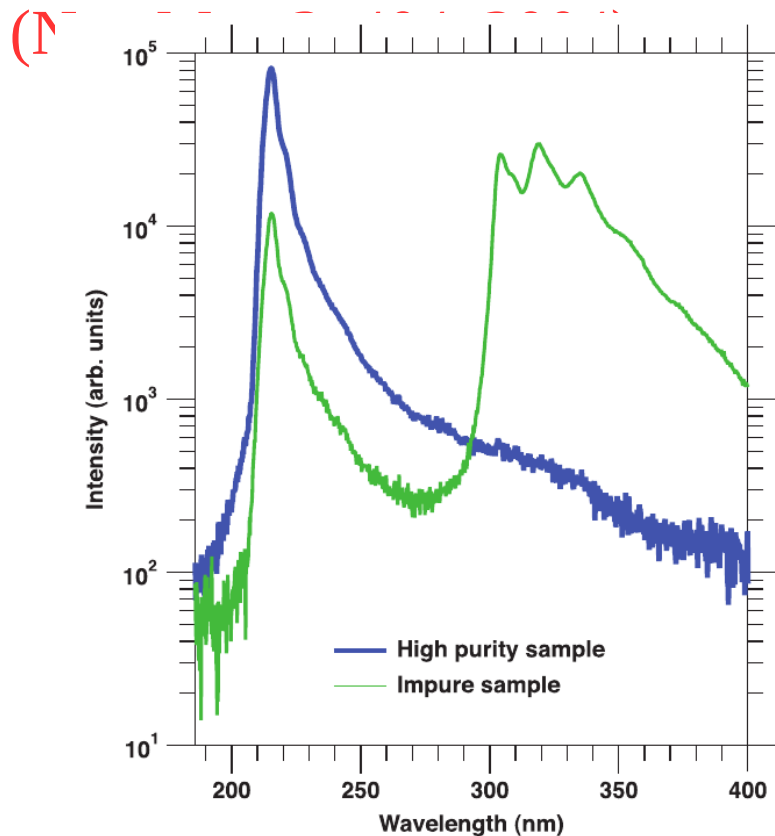
widely used as :

- ◆ solid lubricant
- ◆ thermal coating
- ◆ additive in plastics, ceramics
- ◆ cosmetic powder



High-quality monocrystals

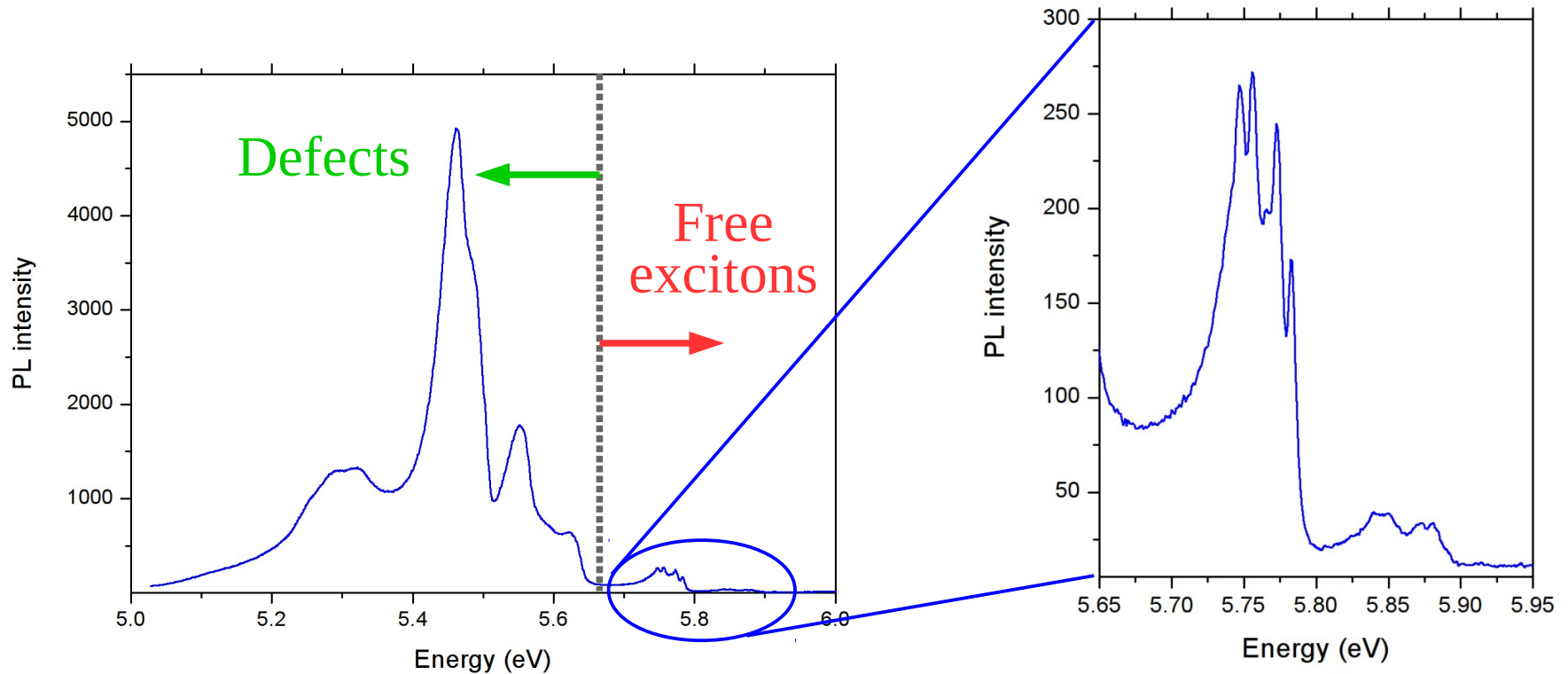
2004-breakthrough by Watanabe & Taniguchi



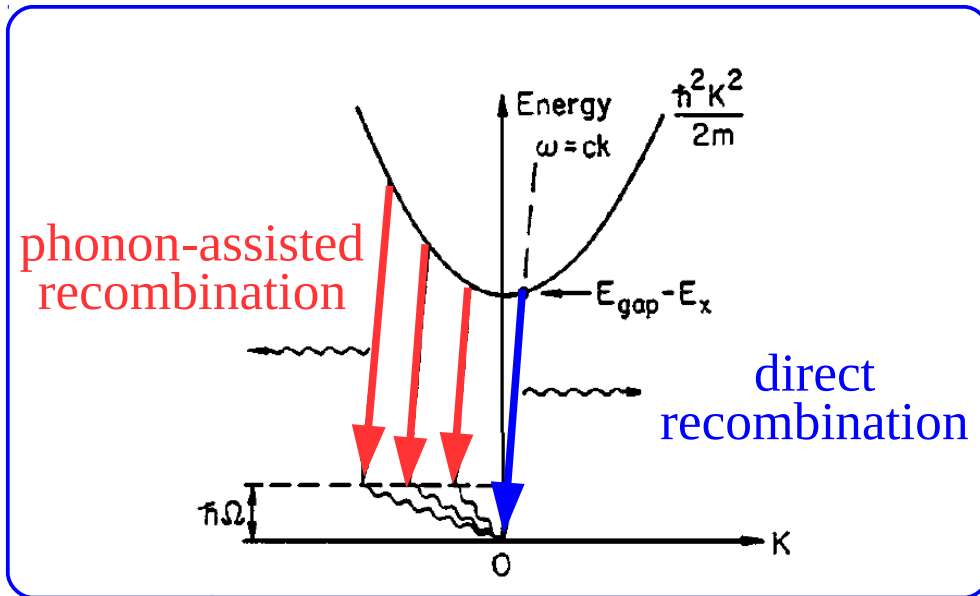
Watanabe, *Int. J. Appl. Ceram. Technol.* 8, 977 (2011)

Photoluminescence spectrum

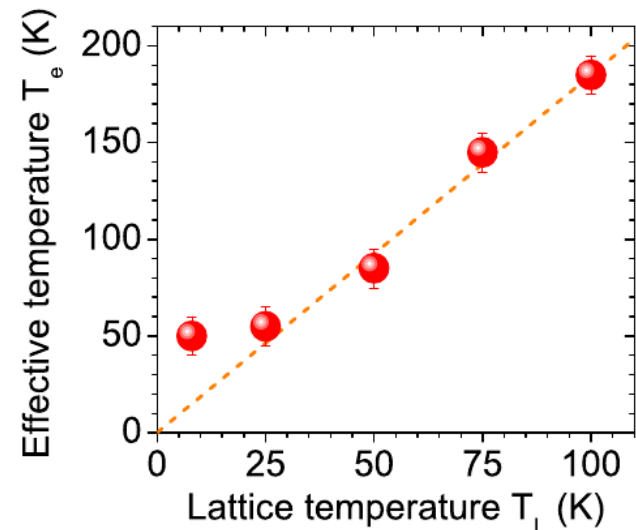
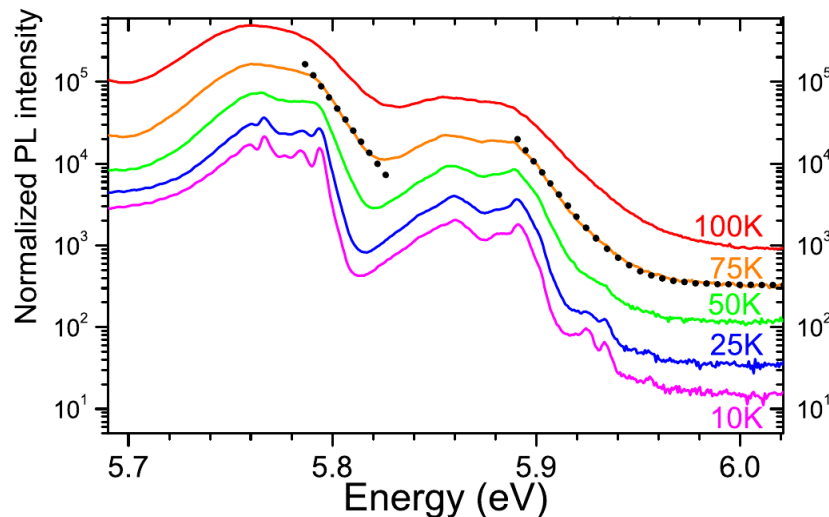
- hBN sample from HQ Graphene (www.hqgraphene.com)
- PL spectroscopy at 10K under laser excitation @ 6.3 eV



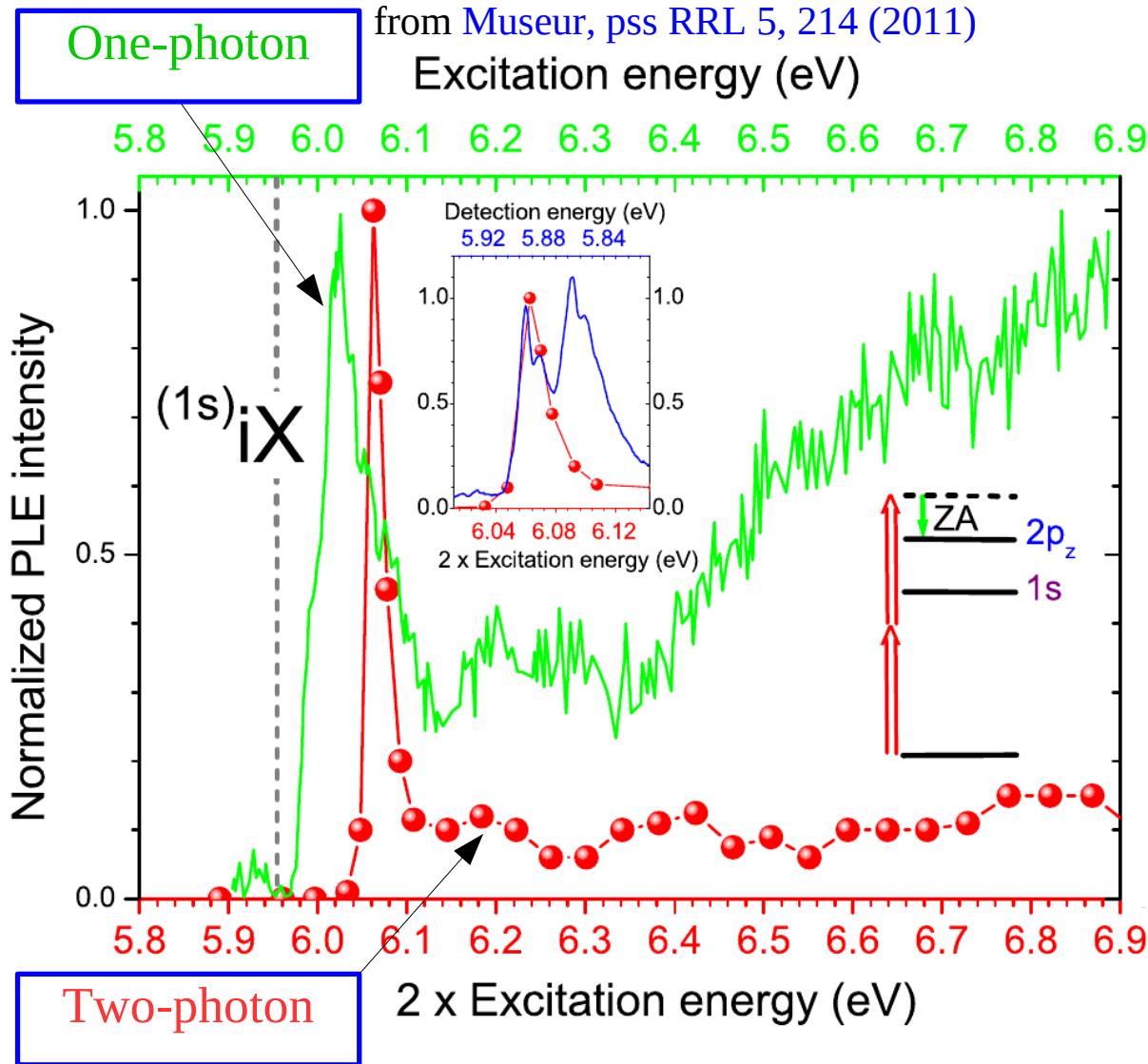
Monitoring the thermalization of high-K excitons



- direct recombination probes excitons at $K \sim 0$
- thermal distribution of high-K excitons **only monitored in phonon replicas**



Two-photon excitation spectroscopy



- Different PLE spectra for one- and two-photon excitations

one-photon

$$\left| \sum_{|int_1\rangle} \langle v|P|int_1\rangle \langle int_1|Q|c\rangle \right|^2$$

two-photon

$$\left| \sum_{|int_1\rangle, |int_2\rangle} \langle v|P|int_1\rangle \langle int_1|P|int_2\rangle \langle int_2|Q|c\rangle \right|^2$$

- Sharp resonance in two-photon PLE
= ZA phonon-assisted absorption of 2p_z-state

Exciton binding energy

- $1s-2p_z$ splitting = 85 meV

Wannier excitons in hBN !!

- For isotropic material, $1s-2p$ splitting = $\frac{3}{4}$ exciton binding energy
- Strong anisotropy of hBN reduces this value

depending on anisotropy factor γ

Gil, pss B 249, 455458 (2012)

- Exciton binding energy = 130 ± 15 meV
- Single-particle gap (or band-to-band energy) = 6.08 eV